

TESLA - COLLABORATION

R & D Issues in the Field of Superconducting Cavities

Feb. 29, 1996, DESY



March 1996, TESLA 96-03

Contents

Agenda	II
<i>P. Schmüser, Uni Hamburg</i>	1
Summary of Workshop on Niobium Properties and Cavity Treatment	
A Quality Control of Niobium	
<i>G. Müller, Wuppertal</i>	6
First Results/Conclusions from Hc ₂ -Measurements on Various Nb-Samples from DESY	
<i>W. Singer, DESY</i>	16
Application of Eddy-Current Method to Nb at BAM	
<i>P. Schmüser, Uni Hamburg</i>	23
First Results on Nb Magnetization Hysteresis Measurements	
B Quench Limitations	
<i>D. Reschke, DESY</i>	27
Thermal Model Calculations	
<i>M. Fouaidy, IPN Orsay</i>	34
High Heat Flux Kapitza Conductance at Cu-HeII Interface and Critical Heat Flux in Saturated HeII	
<i>W.-D. Möller, DESY</i>	44
Quench Limitations vs. RRR - Measured Results	
C Heat Treatment Procedure of Niobium Cavities	
<i>W. Singer, DESY</i>	49
Postpurification of Heraeus Nb for TTF	
<i>A. Matheisen et al, DESY</i>	58
Ti Postpurification at DESY	
<i>H. Kaiser, DESY</i>	66
Creep in TTF Resonators	
D Field Emission	
<i>M. Pekeler, Uni Hamburg</i>	72
Understanding of Q Degradation	
<i>J. Kuzminski, DESY</i>	76
Field Emission Issues in TTF Superconducting RF Cavities	
<i>T. Habermann, Wuppertal</i>	81
DC Field Emission from Naturally Rough Particles	
<i>C. Stolzenburg, DESY</i>	89
Impact of Dark Current on the Performance of 9-cell Cavities	

R&D Meeting, Thursday, Feb. 29, Bldg. 30B, Rm 459

It is the idea to report/discuss about the following subjects and to stimulate further experimental investigations:

A: Quench limitations

1. Review model calculations of quench fields as function of
 - defect size (including defect-free case)
 - wall thickness
 - RRR
 - Kapitza resistance
 Model calculations have been done at Cornell, Wuppertal (finite element) and at Saclay (analytic) - Reschke Safa
2. Experimental verification of Kapitza resistance - Saclay/Orsay
3. Compare measured results of quench limitations vs. RRR - Moeller
4. Experimental evidence of importance of material parameters other than RRR on cavity performance - (discussion)
5. Correlation between Q_0 at low field and max Eacc - (discussion)

B: Ti heat treatment

1. Theoretical diffusion (grain boundary diffusion) of Ti into Nb as function of temperature and time - Singer
2. Experimental data on Ti diffusion into Nb - Matheisen, Safa
3. Temperature and time profile during Ti treatment: experience with cavities and samples. - (Saclay/Desy)
4. Lowering of yield strength by heat treatment - Kaiser, Singer

C: Quality control of Nb

1. First results/conclusion from magnetization measurements - Schmueser
2. First results/conclusions from H_{c2} measurements - Müller
3. Results from eddy current measurements: is this a method to scan Nb sheet material - Singer
4. Material properties of Tokyo Denkai Nb material - (NN)

D: Field emission

1. Correlation of field emission properties with treatment of TTF cavities - Kuzminski
2. Strategy to achieve high gradients without HPP - (discussion)
3. Do we gain permanent improvement after HPP? - (discussion)
4. Understanding of Q degradation after HPP. - Pekeler, NN
5. DC field emission from naturally rough particles - Habermann

Summary of workshop on niobium properties and cavity treatment

P.Schmüser

A) Quality control of niobium

1) First results/conclusions from B_{c2} measurements (G. Müller, Wuppertal).

In the apparatus built at Wuppertal, a niobium sample of $30 \times 10 \times 3 \text{ mm}^3$ size is inserted between two small coils of 8 mm diameter. The first coil produces an a.c. magnetic field of up to 50 Gauss transverse to the surface of the sample, the second coil serves as induction coil. The signal is processed with a lock-in analyzer. The optimum frequency is about 160 Hz, higher frequencies lead to microphonics. There is some stray flux around the sample, so the pick-up coil receives also a signal when the sample is superconductive. The arrangement is positioned inside a superconducting solenoid coil providing a longitudinal field B_0 of up to 8 T. A standard measurement consists in recording the amplitude of the pick-up signal as a function of the field B_0 . When the upper critical field of Nb is exceeded one observes a steep increase in signal amplitude since the field attenuation in normal-conducting Nb is weak. The position of the step determines B_{c2} . For a pure niobium surface one obtains $B_{c2} = 0.27 \text{ T}$. The height of the step is a measure of RRR, large RRR values (high conductivity Nb) give a small step.

Two Heraeus samples show this nicely, sample (a) with 770°C heat treatment and $100 \mu\text{m}$ chemical polishing, sample (b) with 1400°C heat treatment (titanium getter) and $200 \mu\text{m}$ chemical polishing. In a Wah Chang sample (c) the transition starts at the same field but is wider, indicating some surface damage. The Wuppertal 'reference sample' (d) from old Kawecki material has a wide transition above 0.4 T which implies surface contamination.

Using a very small a.c. field of 50 mG the technique is extremely sensitive to thin surface layers. The data show clearly that after a 1400°C heat treatment with titanium getter a NbTi surface layer is present which needs at least $200 \mu\text{m}$ of BCP to be removed. A chemical polishing of $200 \mu\text{m}$ appears also recommendable for the new heat treatment (1 hour at 1400°C , 3 hours at 1250°C) but the B_{c2} data are not yet conclusive.

2) Eddy current check of niobium at BAM (W. Singer, DESY).

The Bundesanstalt für Materialforschung in Berlin has developed a high-resolution scanning head which is capable of resolving defects in the few $100 \mu\text{m}$ range. The eddy-current penetration depth depends on the conductivity of the sample and on frequency. Voids and scratches of at least $100 \mu\text{m}$ can be detected in a surface layer up to $300 \mu\text{m}$ deep. For a larger depth up to 3 mm the minimum defect size is $500 \mu\text{m}$. In cell 5 of cavity D6 a large defect was found. Scanning of entire niobium sheets takes very long with the present setup.

3) First results on Nb magnetization hysteresis (P. Schmüser, Uni Hamburg).

Following a design at KEK an apparatus was built at DESY for measuring the magnetic hysteresis of $9 \times 9 \text{ mm}^2$ samples from the Nb sheets used for cavity production. The basic idea is that pure niobium should have no flux pinning and hence follow a reversible magnetization curve while the observation of a magnetic hysteresis is a proof of magnetic flux pinning. Pinning centers (lattice defects or impurities) at the surface can be expected to increase the surface RF resistance. The Japanese data show a large hysteresis after heat treatment with titanium gettering which vanishes after chemical polishing. This is an indication that a NbTi surface layer was formed by the heat treatment with Ti getter. The Heraeus Nb sheets exhibit a large hysteresis loop in the raw material. After heat treatment (1 hour at 1400°C , 3 hours at 1250°C with Ti getter) but without subsequent chemical polishing the enclosed area of the hysteresis loop is reduced by factor of 10. Additional chemistry (50 μm removal) does not change the hysteresis. These results are surprising in view of the KEK results. Investigations on the sensitivity of the DESY setup to NbTi surface layers are needed.

B) Quench limitations

1) Thermal model calculations (D. Reschke, DESY).

At Wuppertal a program has been written to solve the heat equation for a cylindrical disk on a discrete lattice. The mesh size is variable and can be made finer close to a possible hot spot at $r=0$. The heat conductivity of niobium is treated as temperature dependent. Data on $\lambda(T)$ for Nb of different RRR values are used as input. The Kapitza conductance is taken from measurements of Mittag and from Orsay, the uncertainty is estimated to be around 30%. Calculations were done at Wuppertal for 3 Ghz cavities. The calculated quench fields agree with experimental data. At low RRR the heat conductivity scales with the square root of RRR but above $\text{RRR}=300$ there is a weaker dependence of $\lambda(T)$ on RRR. This observation is supported by analytical calculations by H. Safa which are based on a constant average heat conductivity. It appears questionable whether an increase in RRR beyond 500 will improve the cavity performance. It was agreed that thermal calculations should be done for the TESLA 1.3 Ghz cavities.

2) Kapitza conductance at Cu-HeII interface and critical heat flux in saturated superfluid helium (M. Fouaidy, IPN-Orsay)

Precise data were presented for the heat transfer between copper and superfluid helium and on the heat flux in He II.

3) Experimental results on quench limitations (W.-D. Möller, DESY).

In test results from 40 single cell cavities (excluding the KEK cavities) the quench field is found to increase with $\sqrt{\text{RRR}}$ for RRR up to 300 and then to level off. For multicell cavities a clear rise between $\text{RRR}=300$ and 500 is seen. Several KEK single-cell cavities achieve very high quench field at moderate RRR (200-350). Model

calculations show that in case of large defects a significant improvement is expected by increasing RRR while for small defects the improvement is only moderate.

C) Heat treatment procedure of niobium cavities

1) Diffusion of O, C, N and Ti in niobium (W.Singer, DESY).

The elements O, C, N are dissolved in the bulk niobium and have to be removed by a suitable heat treatment. In material with RRR=300 the contamination amounts to around 5 µg oxygen per g Nb (5 weight ppm) and similarly for C and N. Heat treatment at 1400°C for 4 hours reduces the oxygen content to less than 0.1 wt ppm. The diffusion coefficients of O, C, N in Nb depend exponentially on temperature. A 4 hour heat treatment at 1400°C removes 98% of the oxygen, at 1200°C only 78%. The vacuum in the furnace (a few 10⁻⁷ mbar) is insufficient to perform heat treatment without titanium gettering because otherwise the oxygen content in the niobium would be enhanced. A reasonable vapour pressure of Ti requires high temperature, 1400°C being much more favourable than 1200°C. Titanium diffusion in pure Nb is very slow but as soon as a NbTi layer is formed the diffusion coefficient increases with increasing Ti concentration. For 4 hours at 1400°C Ti diffuses to about 100 µm depth but it should be noted that the diffusion occurs mainly at grain boundaries and may be deeper there. Hence 4 hours at 1400°C may be too much.

2) Experimenta data on titanium diffusion into niobium (A. Matheisen, DESY).

The heat treatment cycle I for TESLA cavities involves two pre-heating steps at 550°C and 1100°C for outgassing. Heating the furnace to these temperature levels requires 8 hours each. The oven is cooled down overnight. Then it is heated to 1400°C in 8 hours and stays at 1400°C for 4 hours. With titanium getter the RRR improves from 250-280 to about 550. The new cycle II involves 3 preheating steps (550°C, 1000°C and 1400°C with cooldown overnight in between). Then the furnace is heated up to 1400°C in 4 hours, stays at 1400°C for 1 hour, followed by 3 hours at 1250°C and cooldown. With cycle II the RRR increases somewhat less, to about 490. The preheating steps are needed because of heavy outgassing.

The titanium layer deposited in cycle I was measured by MAN to be about 16 µm thick. X ray analysis at MAN was not sensitive enough to reveal Ti penetration into deeper layers. A measurement at HasyLab which yielded a penetration depth of about 70 µm.

The heat treatment cycle for the TTF cavities should be reexamined. It appears that in the 3-hour period the temperature of 1250°C may be too low for an effective oxygen removal and that 1300°C or 1350°C (but less than 1400°C) might be more appropriate. Also a moderate extension of the time spent at high temperature may be favourable. Calculations and tests measurements are needed.

3) Softening of Nb during heat treatment (H. Kaiser, DESY).

Creep measurements on a heat-treated Nb sample show that the plastic limit is only 5 MPa (5 N/mm²). When a load is applied one observes creep which leads to a lengthening and a certain hardening of the material. Due to this extreme softness the

heat-treated cavity is very sensitive and can be plastically deformed by improper handling and during mounting in the test dewar or in the tuning apparatus. Measures have been taken to avoid this. Another concern is that the cavity might sag in the horizontal cryostat. If it is supported at the end flanges the maximum computed stress of 14 MPa clearly exceeds the plastic limit of 5 MPa. The measured plastic sag is found to follow a logarithmic time dependence. For a support at the end flanges a sag of 0.5 mm is expected in the first year and almost no sag afterwards. In the titanium cylinder the cavity is supported further inside and the expected sag is significantly lower. Hence a center support is not needed. However, extreme care must be exercised during handling and welding to prevent permanent deformation and detuning of the cavity.

D) Field emission

1) Correlation of field emission properties and cavity performance (J. Kusminski, DESY, M. Pekeler, Uni Hamburg).

The Dornier 9-cell cavities exhibited some field emission which could be removed by high power processing. The present limitations seen in D4, D5 and D6 are probably not due to field emission. The removal of emitters by HPP is usually accompanied with a Q degradation (if the initial Q was in the 10^{10} range). The interpretation is that material evaporating from the emitting site is deposited elsewhere on the cavity surface and degrades the surface resistance. Hence HPP may be a viable method for removing field emitters from an already installed cavity but it is not considered a good tool for conditioning the cavity in the preparatory phase. There is general agreement that field emitters should and can be avoided by several high pressure rinsing steps and extremely careful handling. The standard RF test of the TTF cavities is now carried out with an input antenna that is matched to a high Q and does not allow HPP.

An improvement of Q by HPP was only observed when the initial Q was fairly low.

2) Field emission from natural rough particles (T. Habermann, Wuppertal).

The experiment has been designed to check the validity of the "tip-on-tip" model for large field enhancement factors. Field emission from dust particles were studied in a d.c. field. The emitting particles were investigated with a scanning electron microscope and their size, shape geometrical field enhancement factors were determined. By evaporating a gold film these geometrical quantities are modified in a well-defined way. Although there is a considerable spread in the correlation plots the data show clearly that with natural particles field enhancement factors in the range 50-200 can be realized.

3) Impact of dark current on the performance of 9-cell cavities (C. Stolzenburg, DESY).

A program has been written to track the trajectories of field-emitted electrons through the 9-cell cavity. It is obvious that the electrons emitted in a given cell extract energy not only from this cell but also from other cells. Hence, for identical field emission properties, the $Q(E)$ curve of a 9-cell cavity will start to drop at an accelerating field that is roughly 5 MV/m lower than for a single-cell cavity. The $Q(E)$ curves of the Dornier cavities D1 and D2 (without heavy field emission) can be well parametrized by a model in which many small field emitters are assumed with a gaussian distribution of field enhancement factors. The initial tests of these cavities were often dominated by single strong field emitter. Choosing an appropriate β value also the $Q(E)$ curve of such a cavity is well reproduced. It appears that these calculations offer a nice way to parametrize cavity performance.

Hamburg, 29.2.96

160/

I Principle of H_{c2} -Measurement Technique

FIRST RESULTS/CONCLUSIONS

from H_{c2} -MEASUREMENTS

on various Nb-samples from DESY

G. Müller

Univ. WUPPERTAL - CRYOELECTRAGmbH

II Measurement Technique

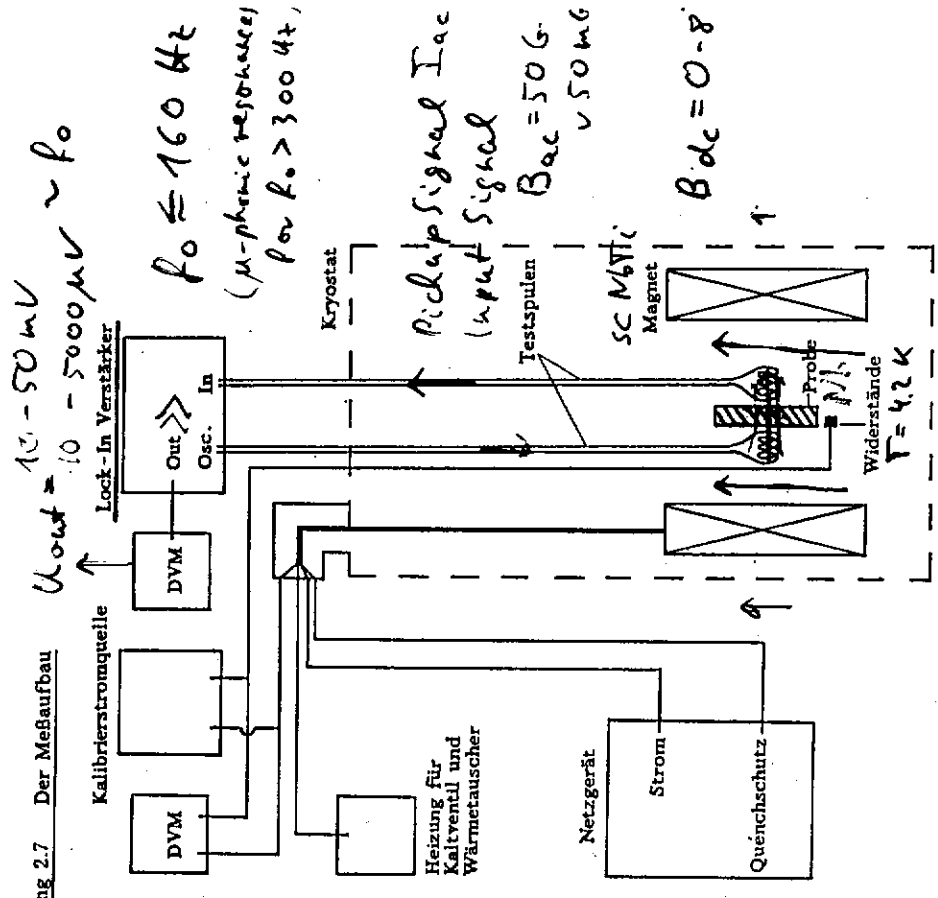
III Experimental Set-up

IV Results

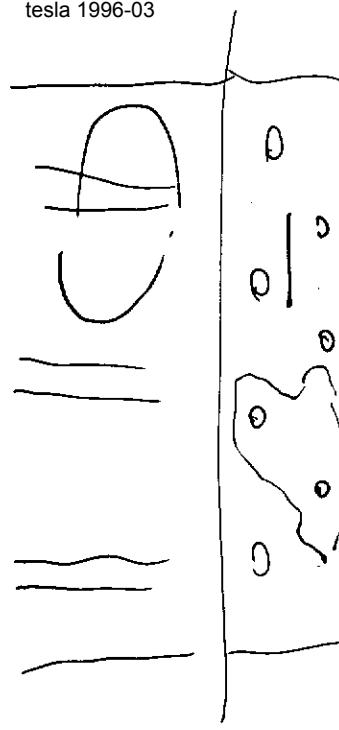
- a) raw Nb from different producers
- b) Nb after Ti-treatments + BCP
- c) Surface Effects at low Test-Field

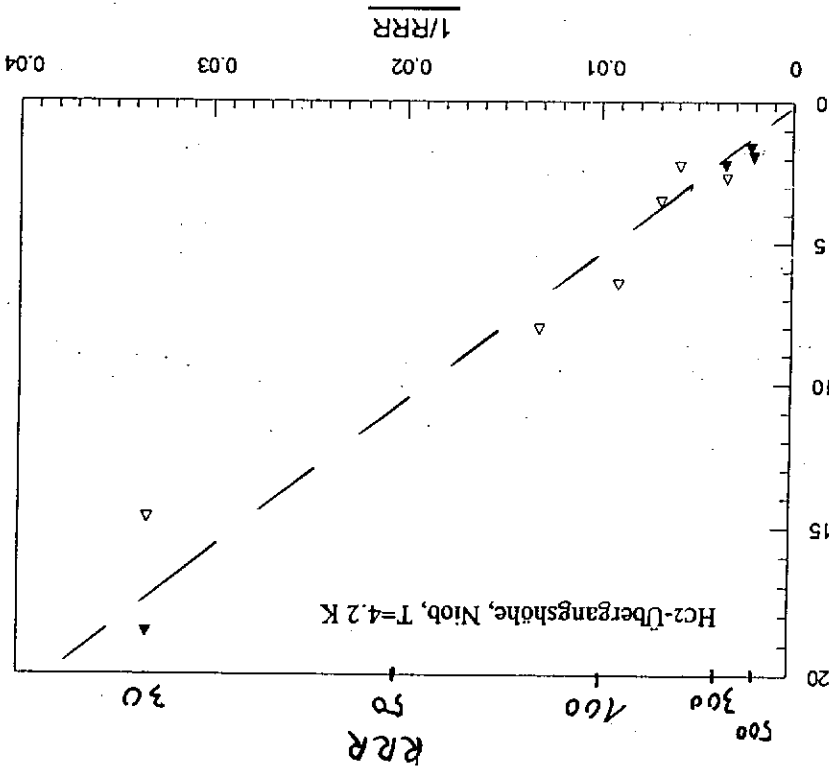
V Conclusions

Abbildung 2.7 Der Meßaufbau



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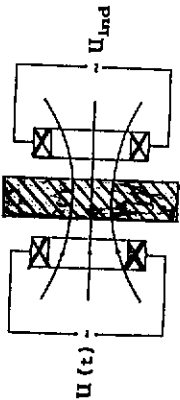


RRR - determination from transition height ΔU_{ac} (for homogeneous samples only!)

a) non-destructive T_c -measurement of SC

Die Abschirmwirkung eines Supraleiters

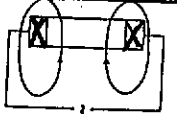
Normalleitende Probe



$U(t)$

U_{ind}

Supraleitende Probe



$U(t)$

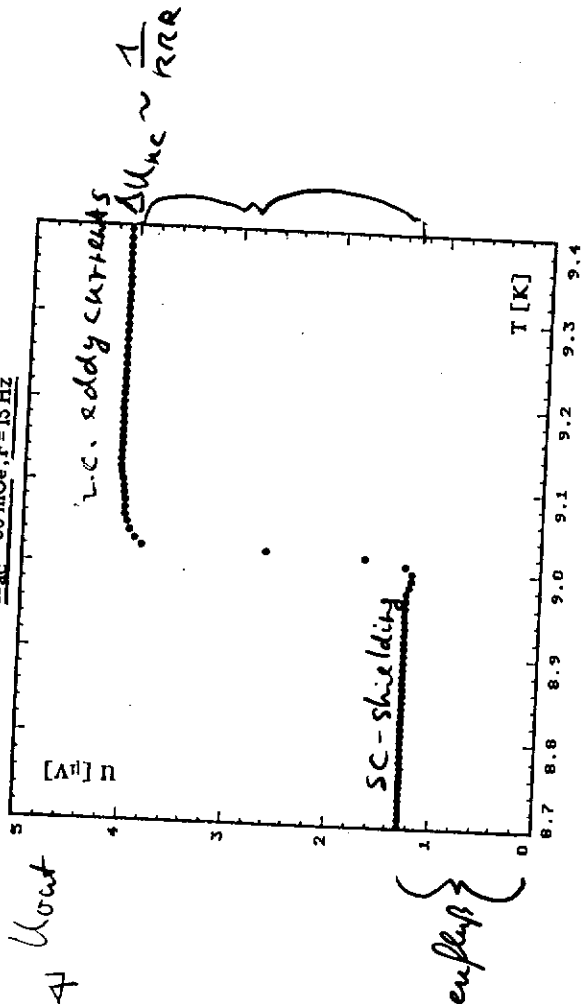
U_{ind}

Quellspule Probe pickup Spule

Quellspule Probe pickup Spule

$B_{dc} = 0$

Induktive T_c -Messung an einer ausgeheizten Niobprobe (Nb!) mit $H_{ac} = 60 \text{ mOe}$, $F = 15 \text{ Hz}$



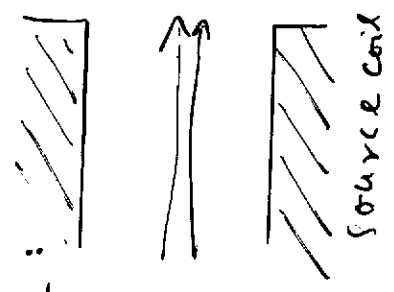
transition width / shape

T_c -homogeneity of SC-sample

Stromfluss

b) non-destructive H_{c2} -measurement of SC
 $T_c = 4.2 K$ $B_{dc} = 0 - 8 T > H_{c2}(Nb)$

- $B_{ac} < B_{c1} \Rightarrow$ Meissner-state - perfect SC shielding
- $B_{c1} < B_{dc} < B_{c2}$



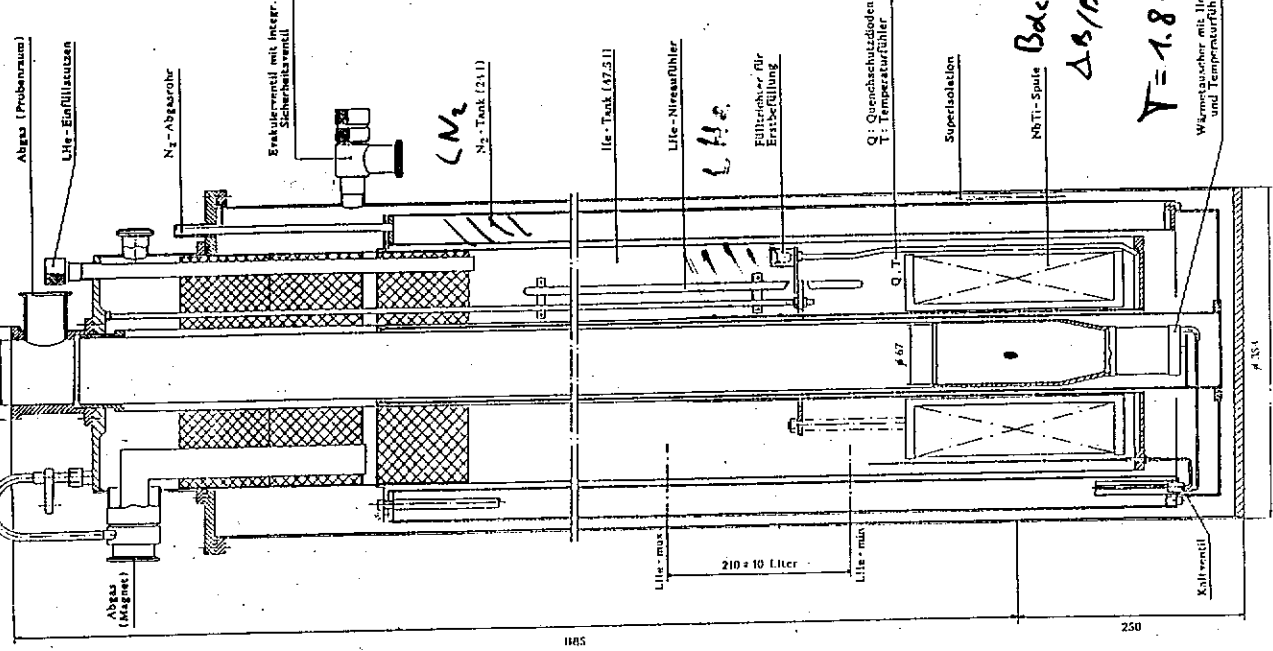
Critical vortex state (Bean-Model) $-\frac{dI_s}{dx} = j_c$
 $B_{ac} = 50 G \Rightarrow x \approx 10 - 1000 \mu m$
 Surface shielding

$x \approx 1000$ $B_{ac} = 50 G \Rightarrow x = 10 - 1000 \mu m$
 $B_{c2} < B_{dc} \Rightarrow$ NC eddy currents bulk shielding

Homogeneous sample \Rightarrow sharp transition ΔB_{c2}
 Coated sample or surface damage \Rightarrow broad transition

$B_{ac} = 50 mG \Rightarrow$ surface layer dominates
 $B_{ac} = 50 G \Rightarrow j_c$ (surface layer) / parallel bulk dominates

II Evaporation Cryostat with NbTi-Magnet
 Der Verdampferkryostat mit supraleitendem 8 T Magnet



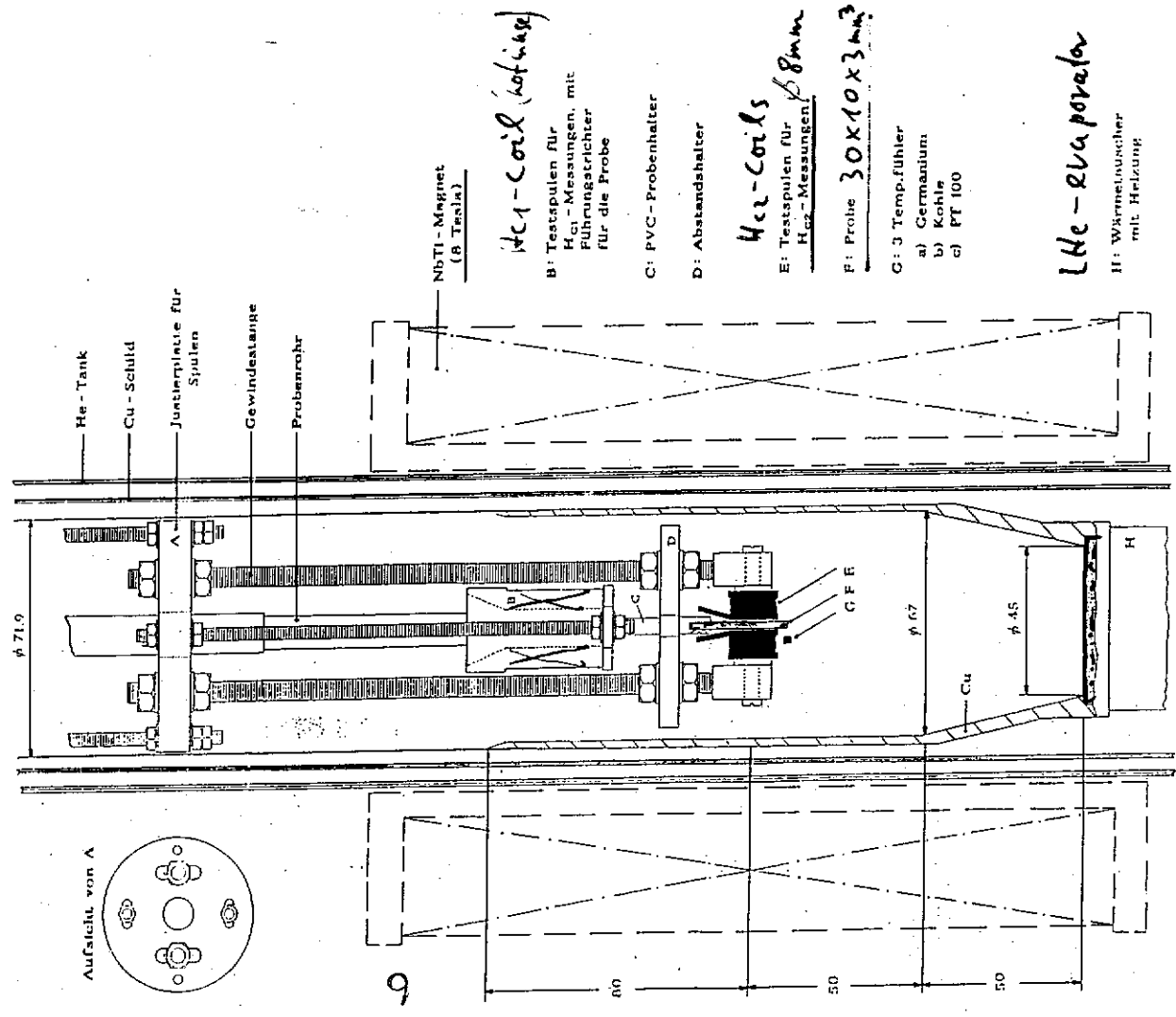
$B_{dc} = 0 - 8.4 T$
 $\Delta B/B < 1\%$
 $T = 1.8 - 3.00 K$

ca. 1.5 m

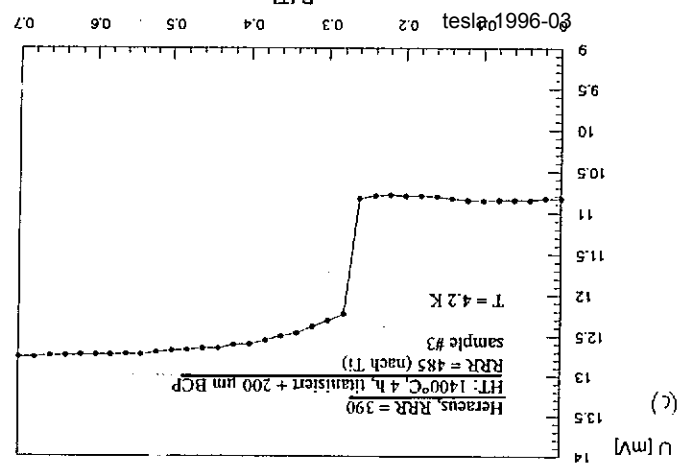
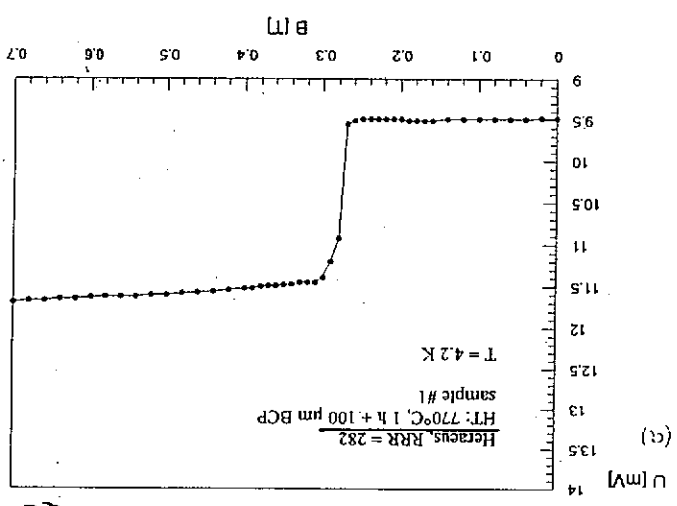
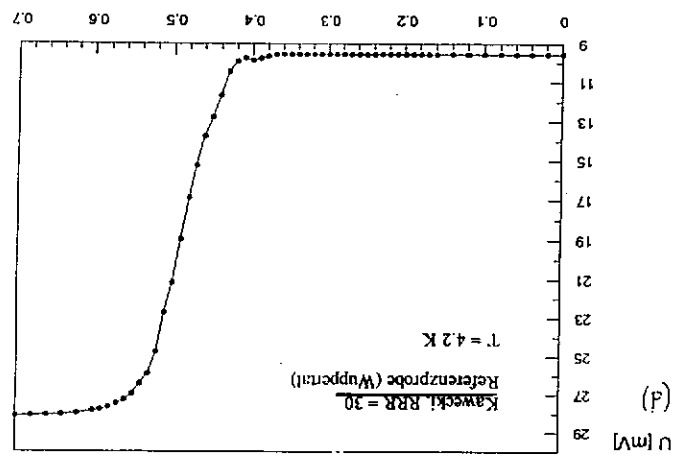
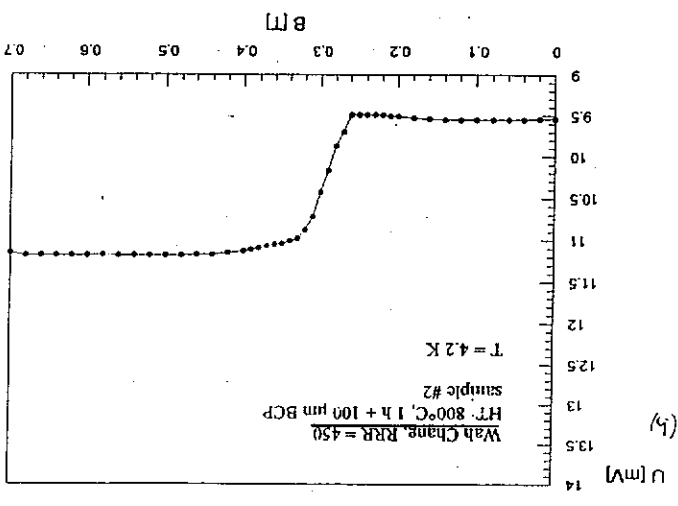
net bore $\phi = 67 mm$

Yest-Insert for quick sample exchange

Abbildung 2.5
Der Kryostateinsatz für induktive H_{c2} -Messungen



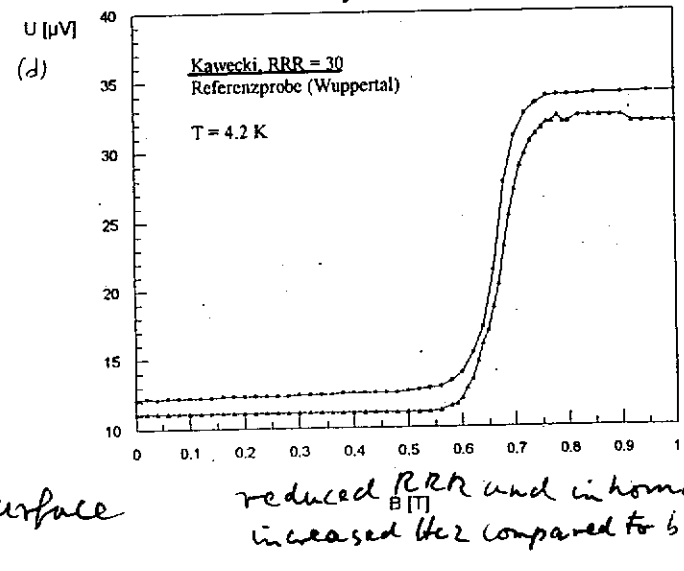
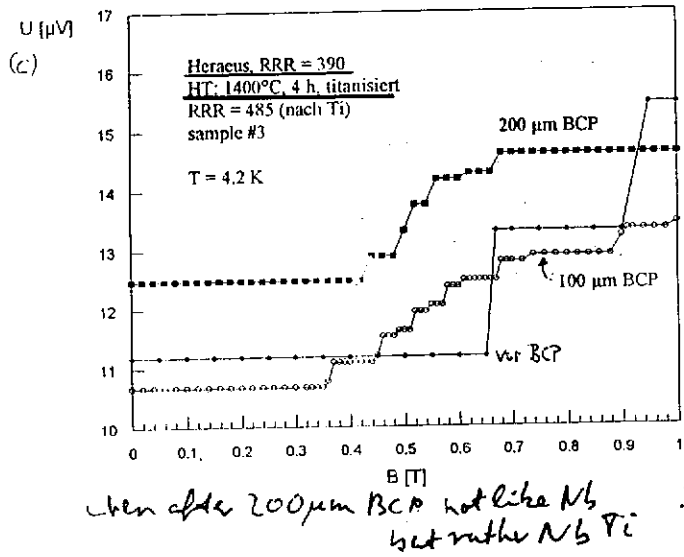
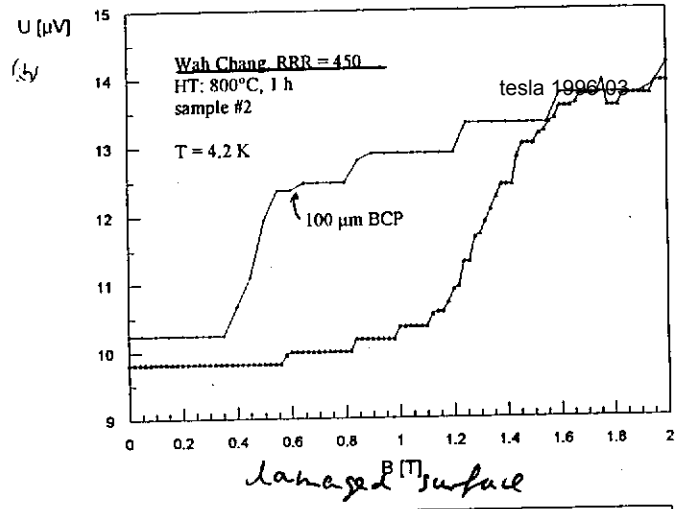
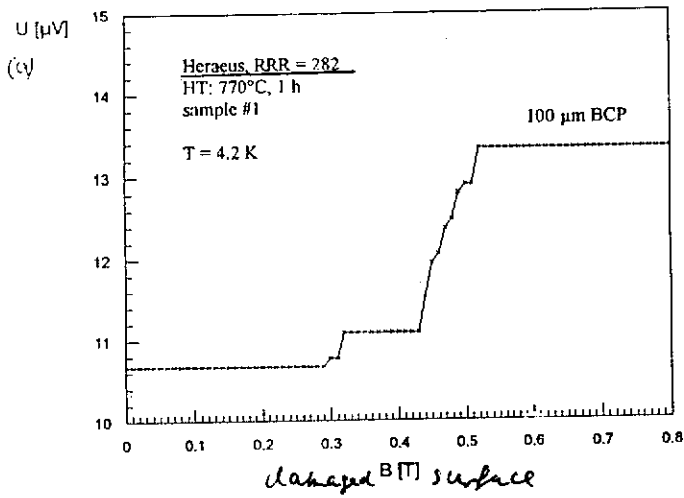
$B_{ac} = 50 G$



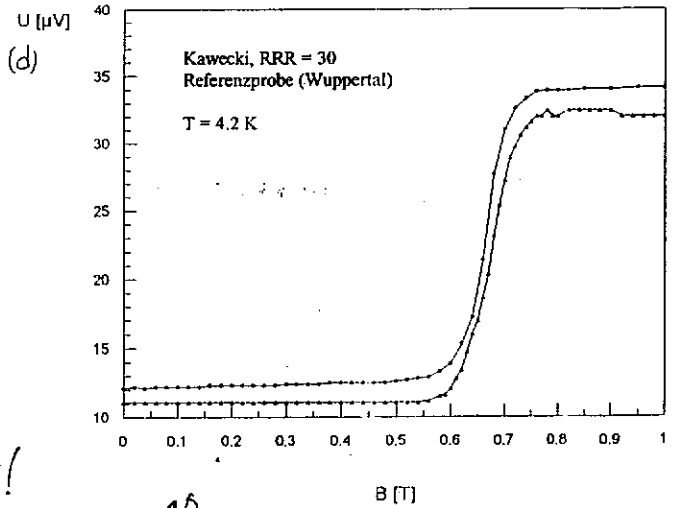
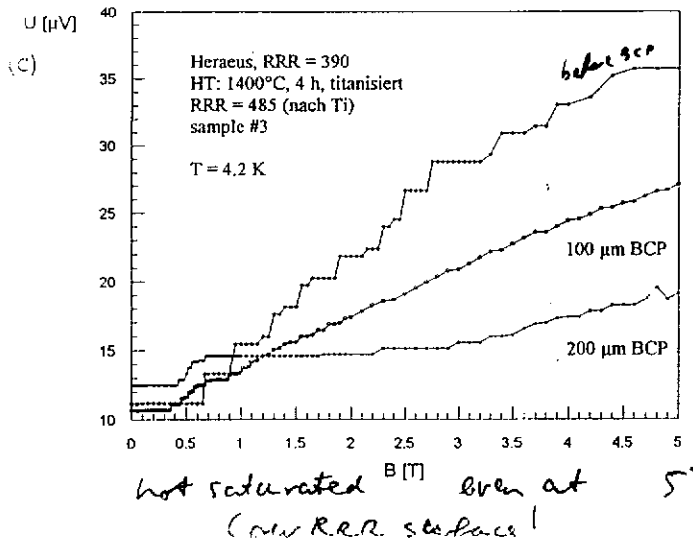
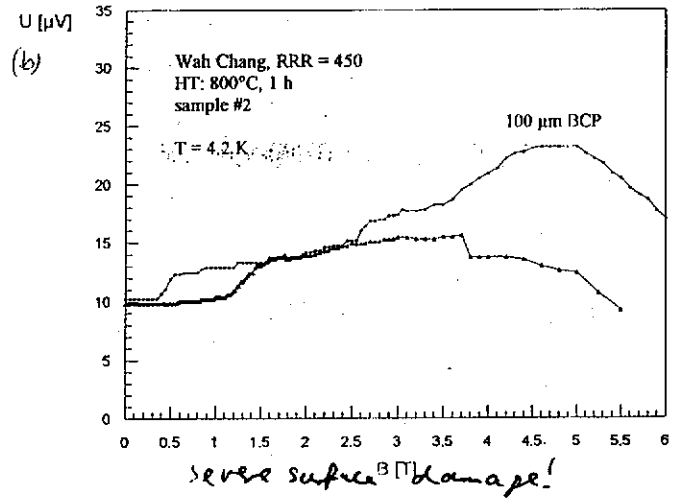
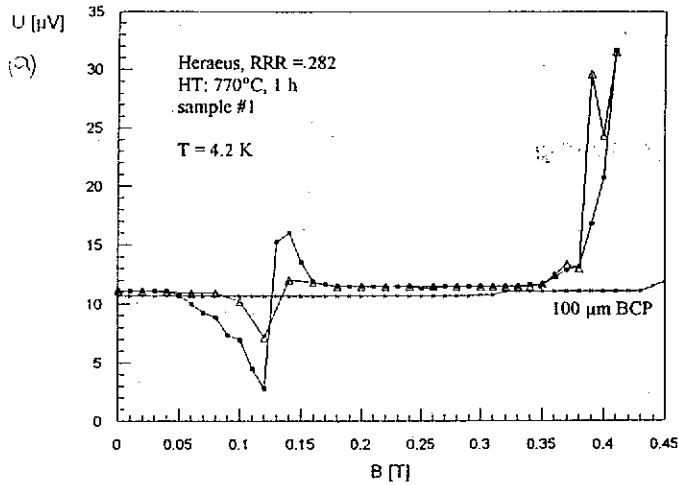
Wuppertal

Back

Konofsky

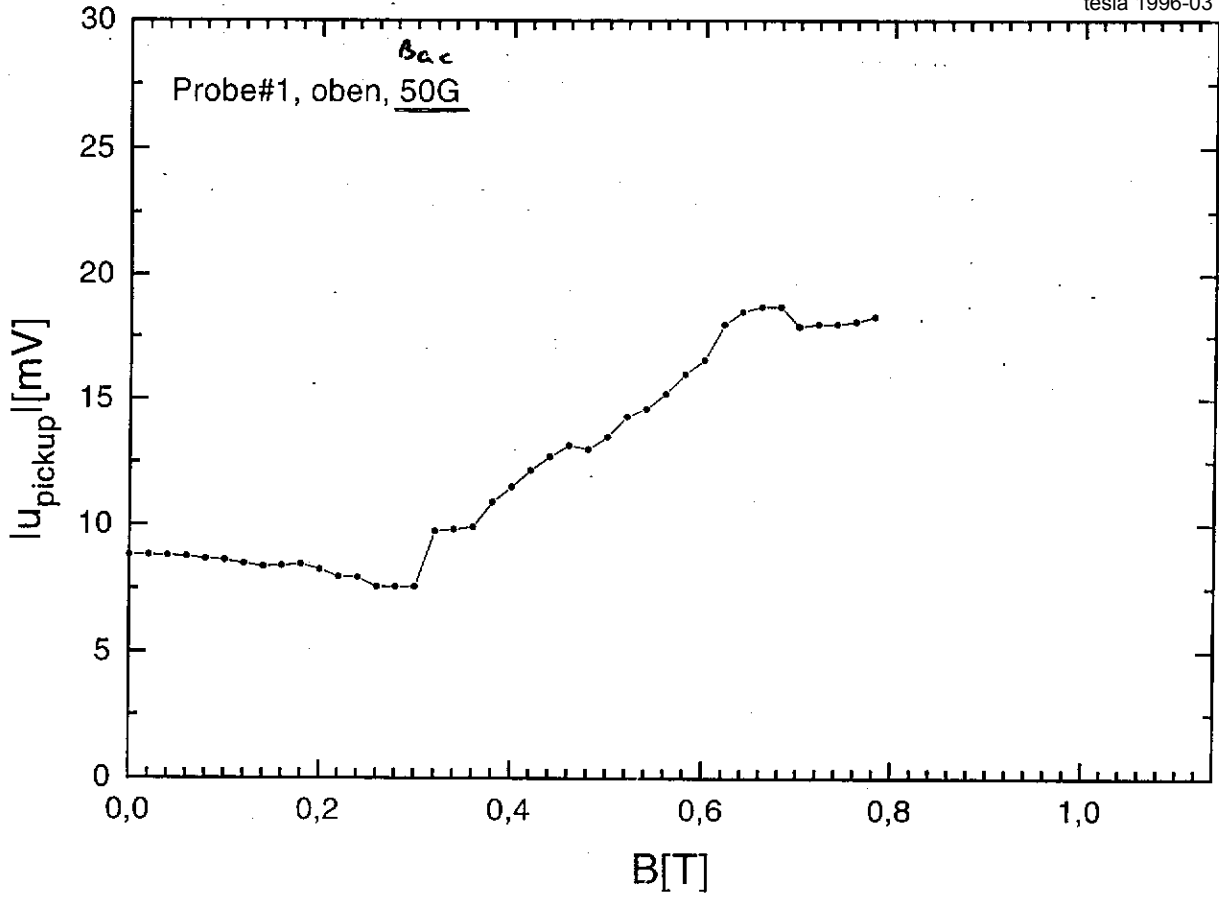


$B_{ac} = 50 mG$



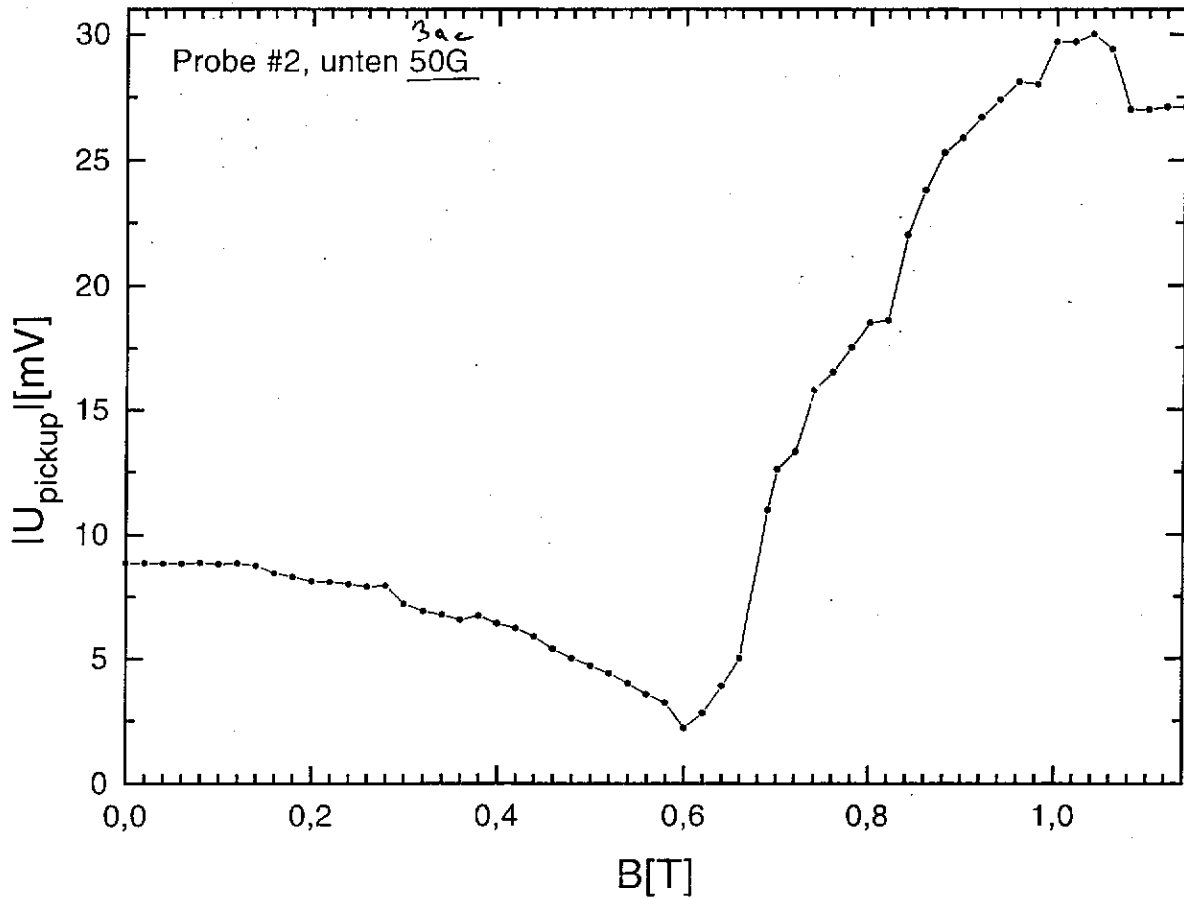
$T_i = 4V = 1900^\circ C 1R, + 1250^\circ C 3R$ $h_0 BCP$

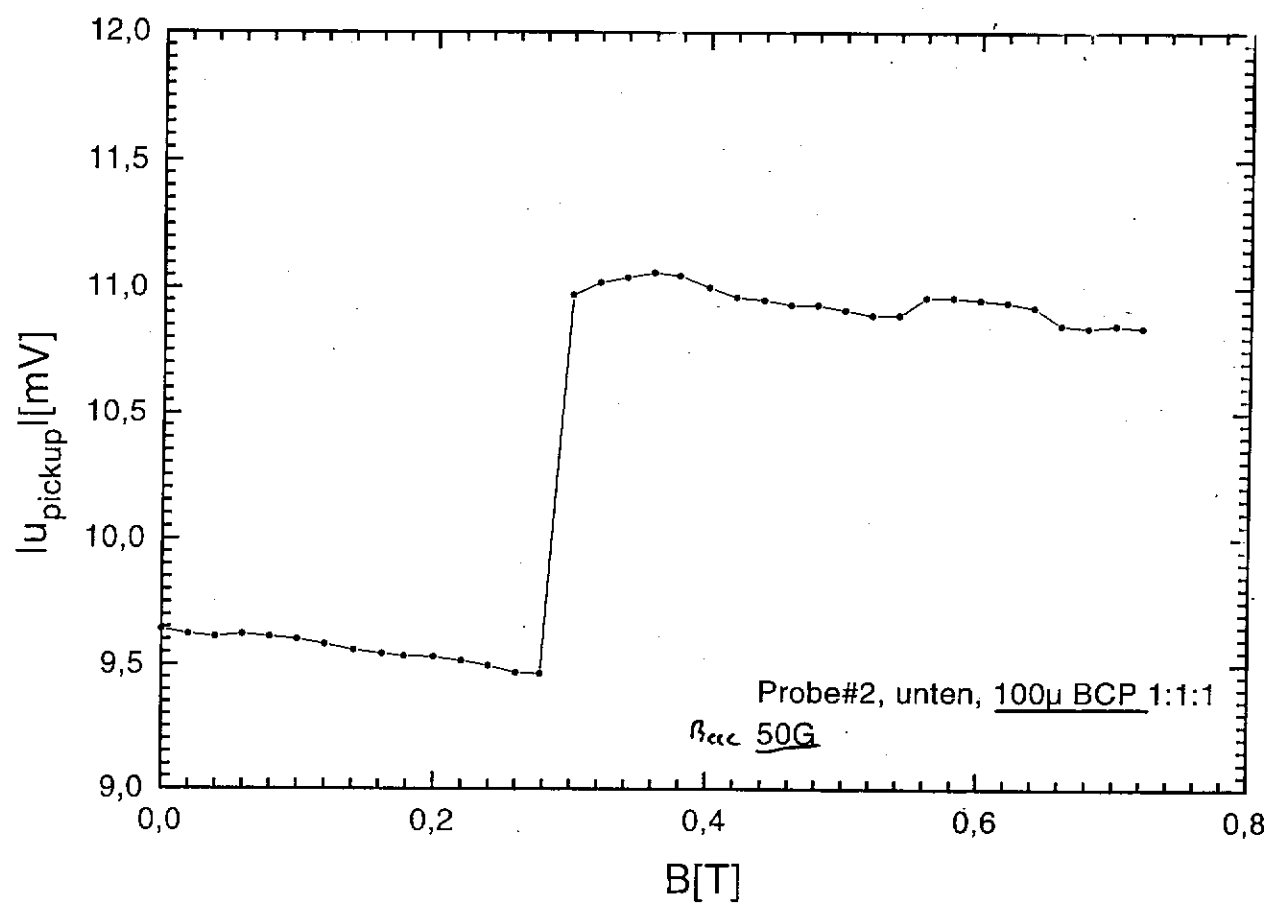
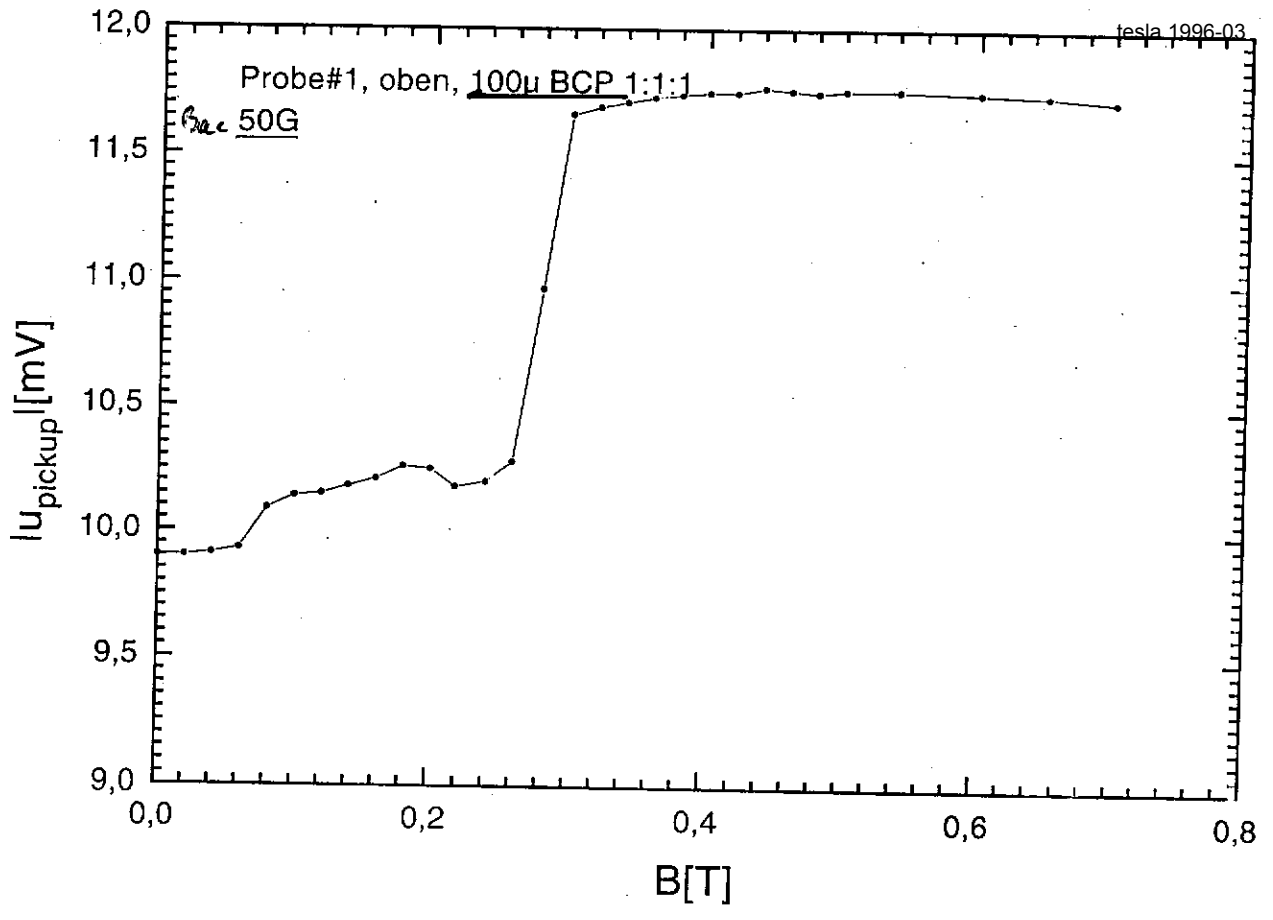
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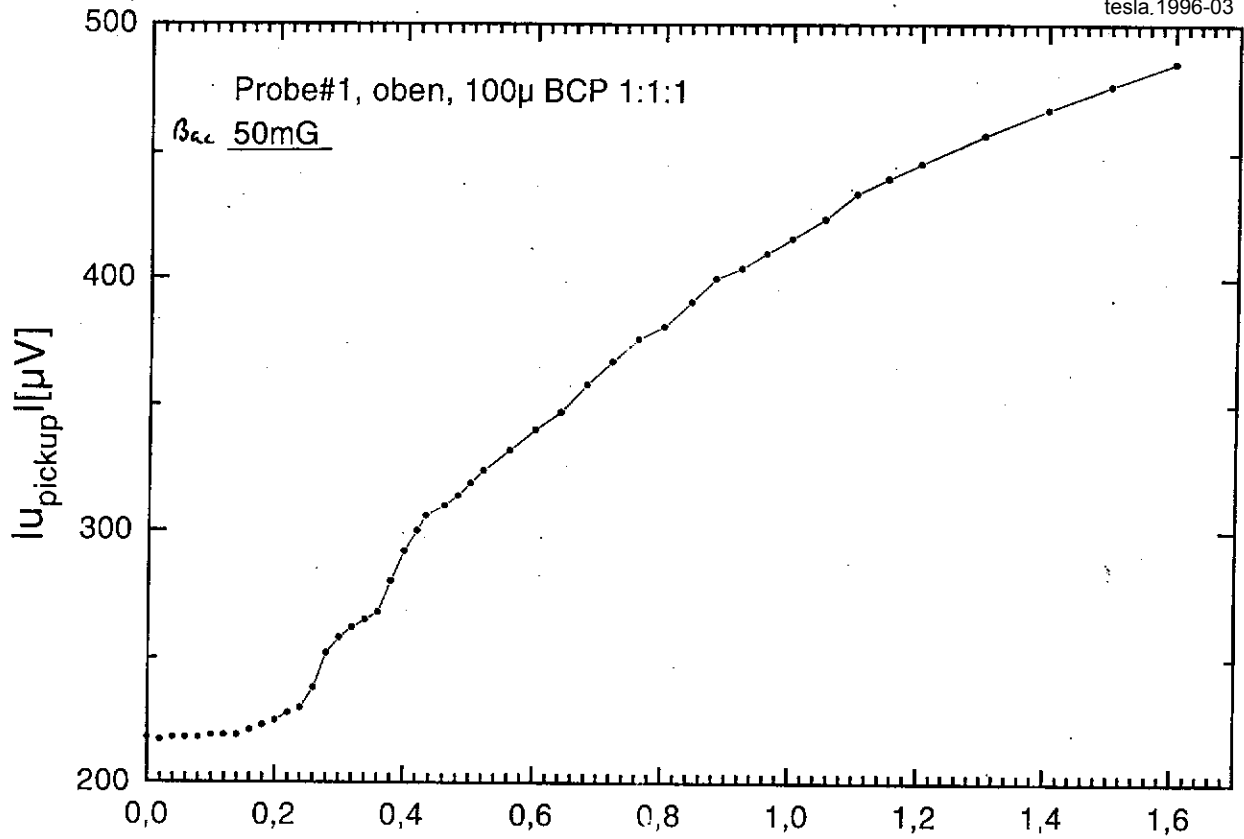


$T_i = 4V = 1900^\circ C 1R + 1100^\circ C 3R$

$h_0 BCP$

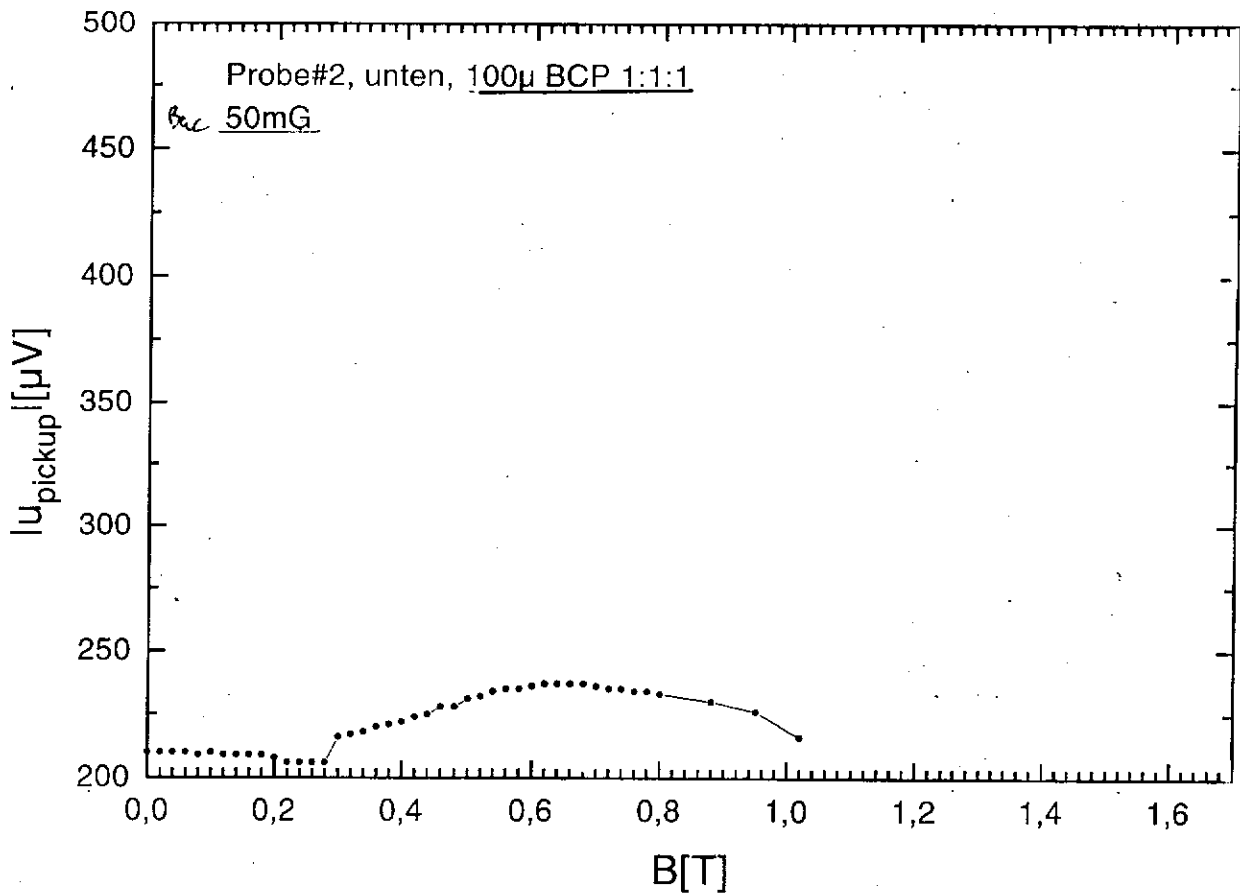


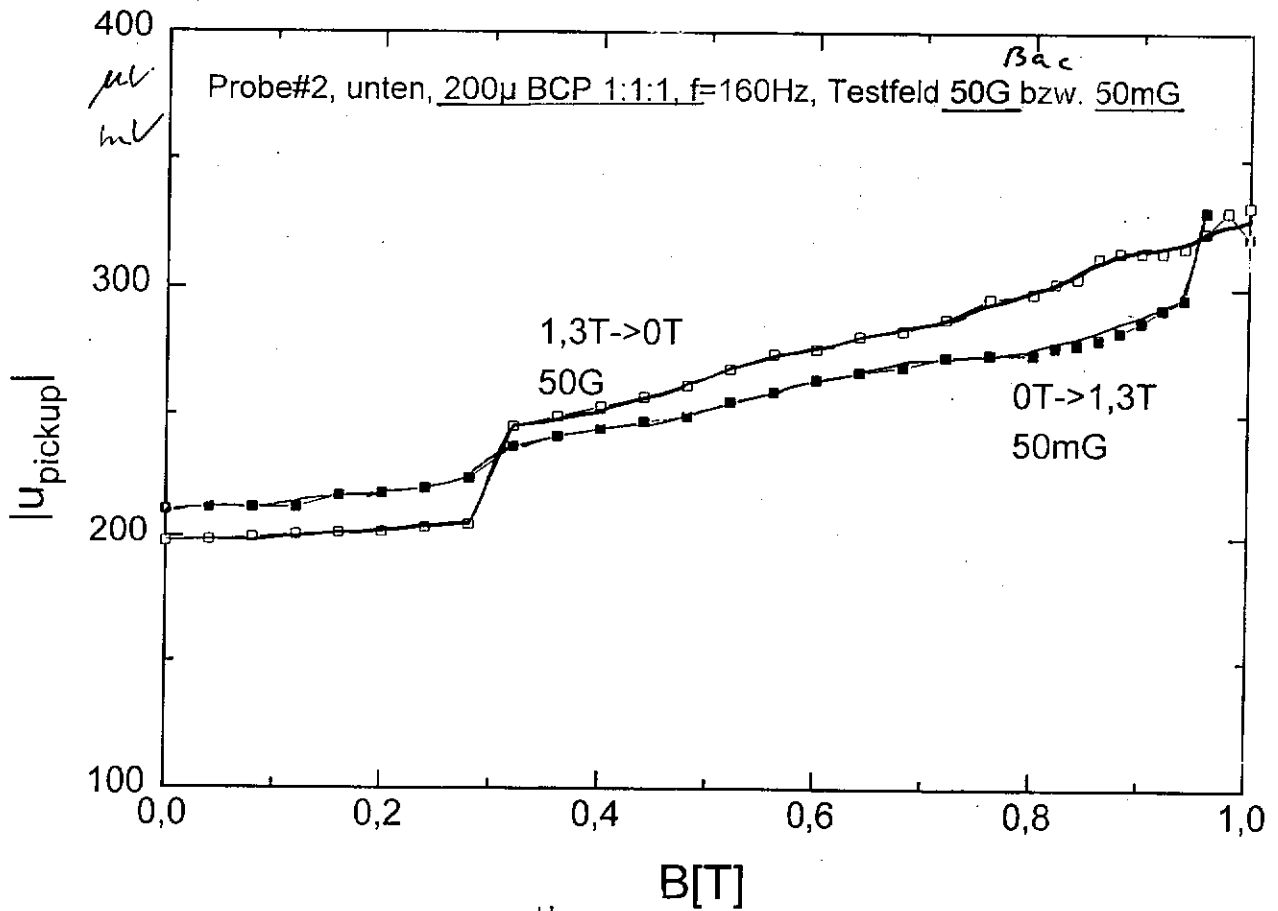
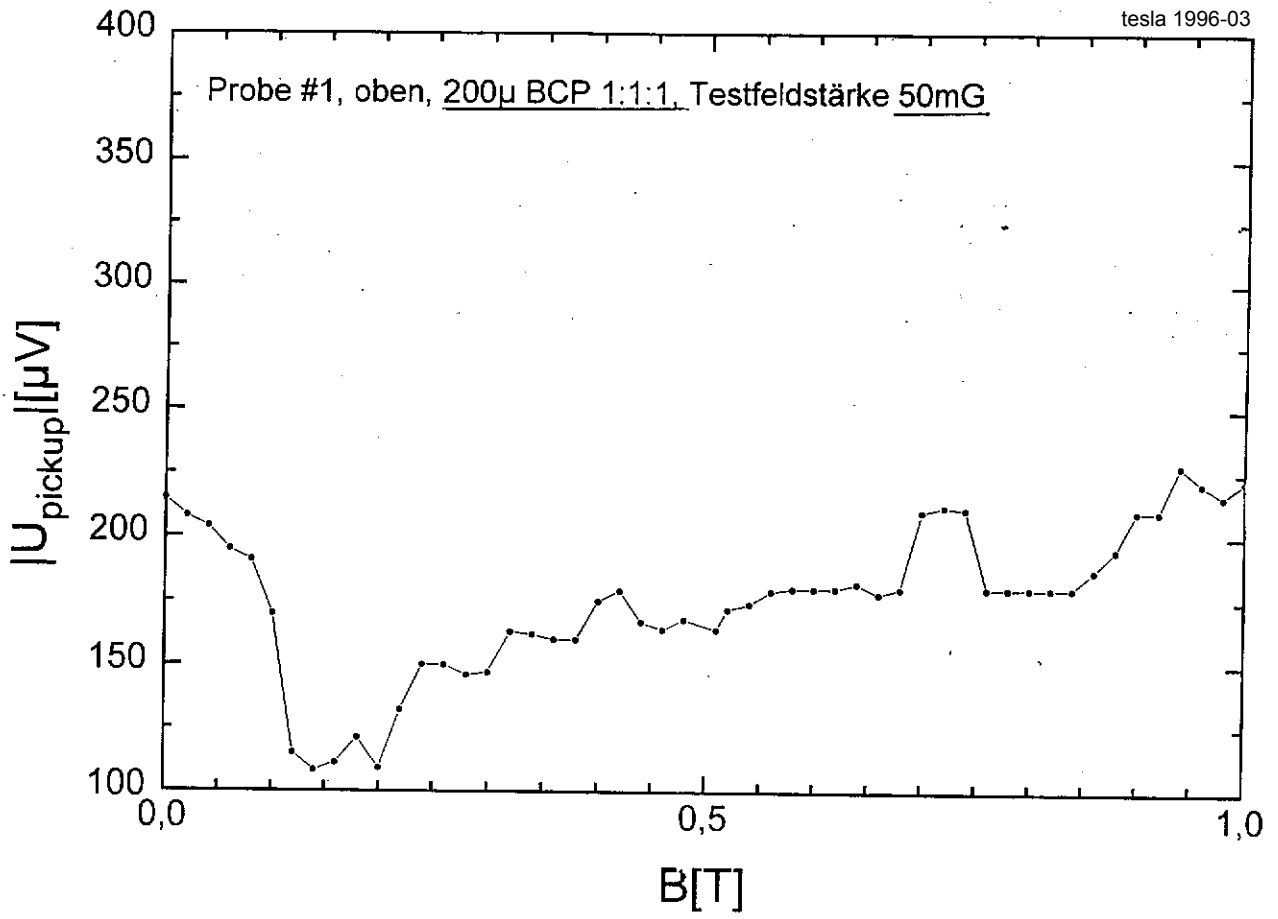


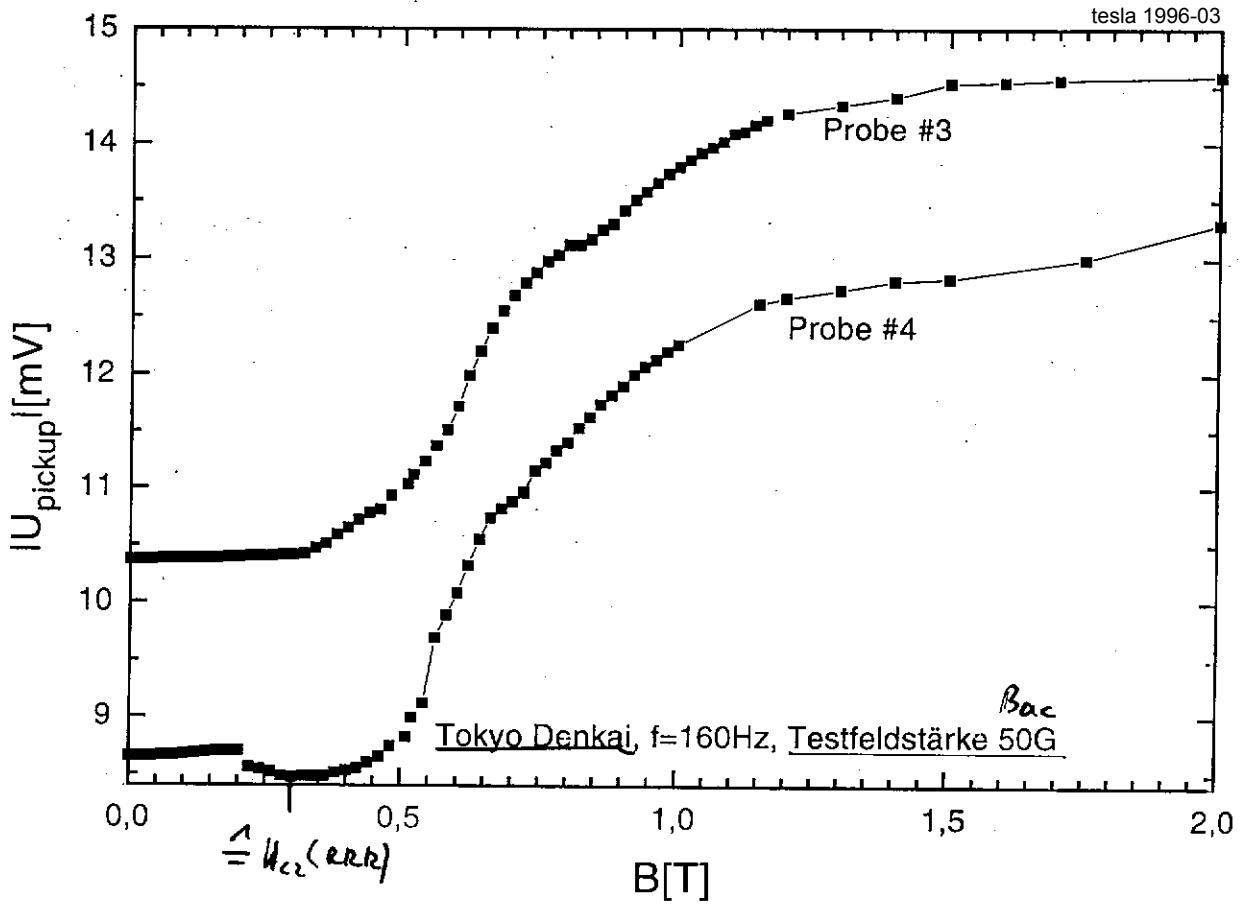


B_{ce} -onset $\hat{=}$ bell where B[T]

but rather in homogeneous, low conductivity surface





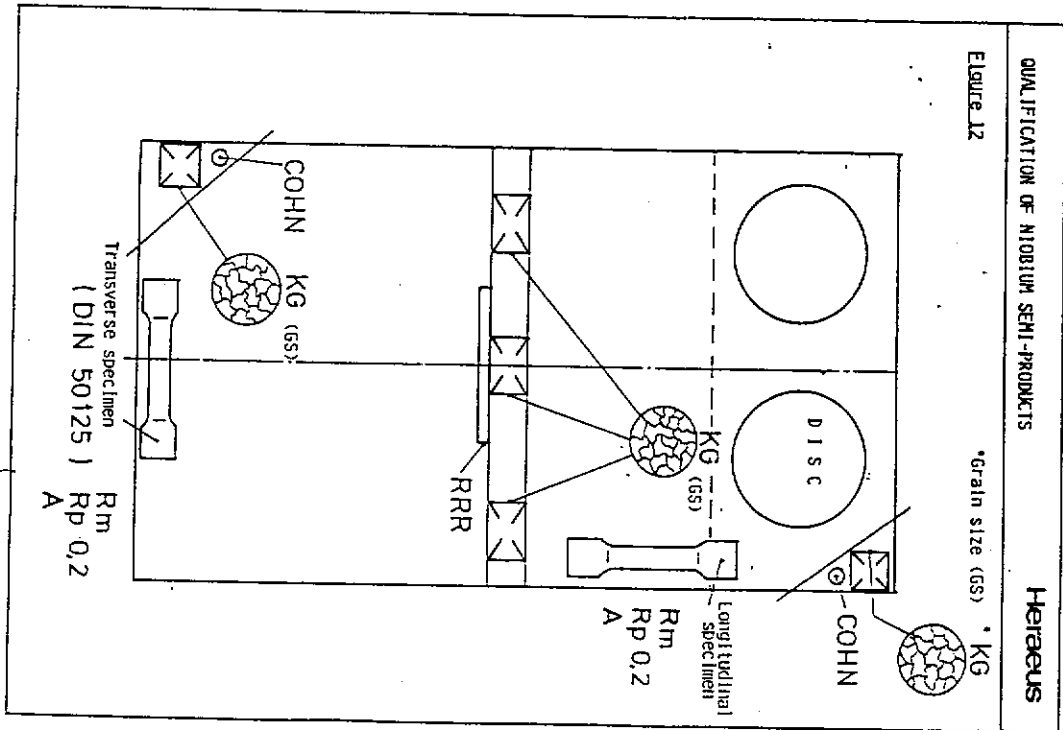


⇒ Very inhomogeneous Nb even in bulk

- ### Conclusions
- The measurement technique is sensitive to surface damage Ti-coatings/residues after polishing and HOMOGENEITY
 - Most raw Nb materials show severe surface damage and even some bulk inhomogeneity
 - Ti-UVTA homogenizes transpires the bulk, but creates a NbTi-like coating at the surface which is at least 100µm - 200µm thick and inhomogeneous
 - Reducing of the Ti-UVTA Temperature is necessary to improve the surface quality
 - The amount of Ti on the Nb samples depends on the position in the furnace, probably
 - Systematic variation of Bac-testfield for given Ba might be instructive for Depth-Profiles of the magnetic properties & homogeneity
- Overall, these measurements are a powerful tool to control the purity and homogeneity of Nb sheets, and to optimize the Ti-UVTA process!

Application of Eddy-Current Method
to Nb at BAM (Berlin)

W. Singer



LEITZ 4734
Made in Germany

Nb sheet properties

Manufacturer	W.C.HERAEUS GmbH	W.C.HERAEUS GmbH	W.C.HERAEUS GmbH	TELEDYNE WAH CHANG
Properties	Cavity -2,-1	Cavity D1...D6	S7-S12,A13-A18	
FFR	407-433	300 -380	278-350	400
Impurities content, %				
Ta	0,037	0,036	0,012	0,02
W	<0,005	<0,005	<0,005	<0,003
Ti	<0,001		<0,002	<0,004
Fe	<0,002		0,002	<0,003
Si	<0,002	<0,002	<0,002	<0,002
Mo	<0,002	<0,002	<0,002	<0,003
Ni		<0,003	<0,002	
Zr		<0,003	<0,002	
H	<0,0005	<0,0005	<0,0005	<0,0003
N	<0,001	<0,001	<0,001	<0,002
O	<0,001-0,03	<0,001	<0,001	<0,004
C		<0,001	<0,001	
Mechanical properties				
Tensile strength, Rm, (N/mm ²)		175 150 -180	152 - 160	157,6 - 161
Yield strength, Rp 0,2 (N/mm ²)		53 60 -97	79 - 81	90,8 - 94,9
Elongation,%		54 38 -70	48 - 68	51 - 52
Hardness, HV10		38 -45	40 - 46	
Grain size, ASTM	6,5-8,5	6 - 8.	5 -8,5	49 7
Recrystallisation heating.				
Temperature, °C	770	770	770 -800	
Time, h	1	1	1 -1,25	
Thickness, mm		2,69.....2,88	2,45.....2,85	2,67.... 2,90
Number of the sheet (2,8*262*262)	40	150	275	120
Delivery data		Feb 94	Jul 94	Jan 95

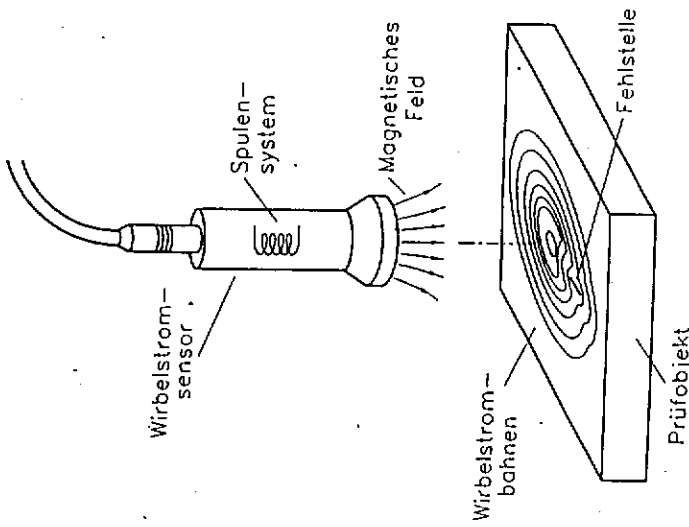


Abb. 1. Prinzip der Wirbelstromprüfung
 Fig. 1. Principle of the eddy current test method

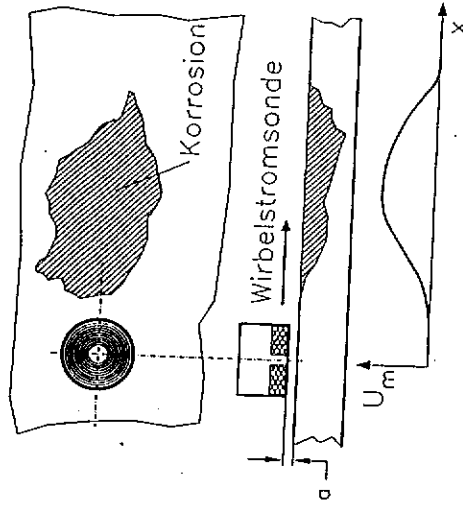


Abb. 3. Schematische Darstellung der Prüfaufgabe
 Fig. 3. Schematic display of the test task

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07

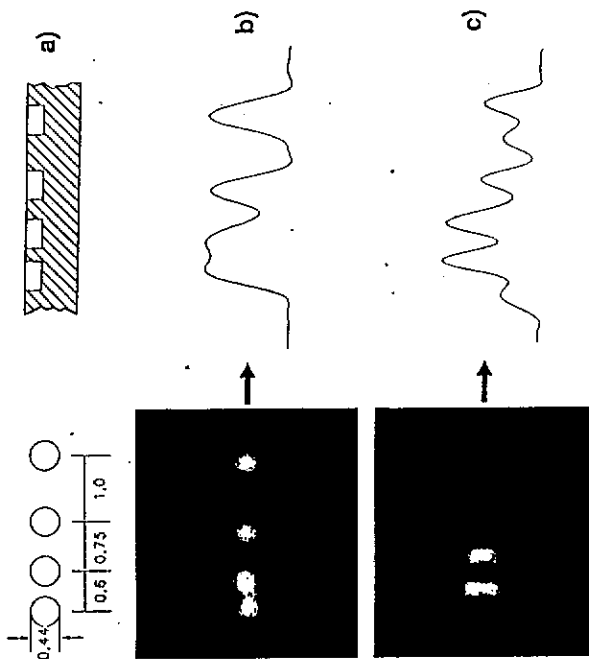
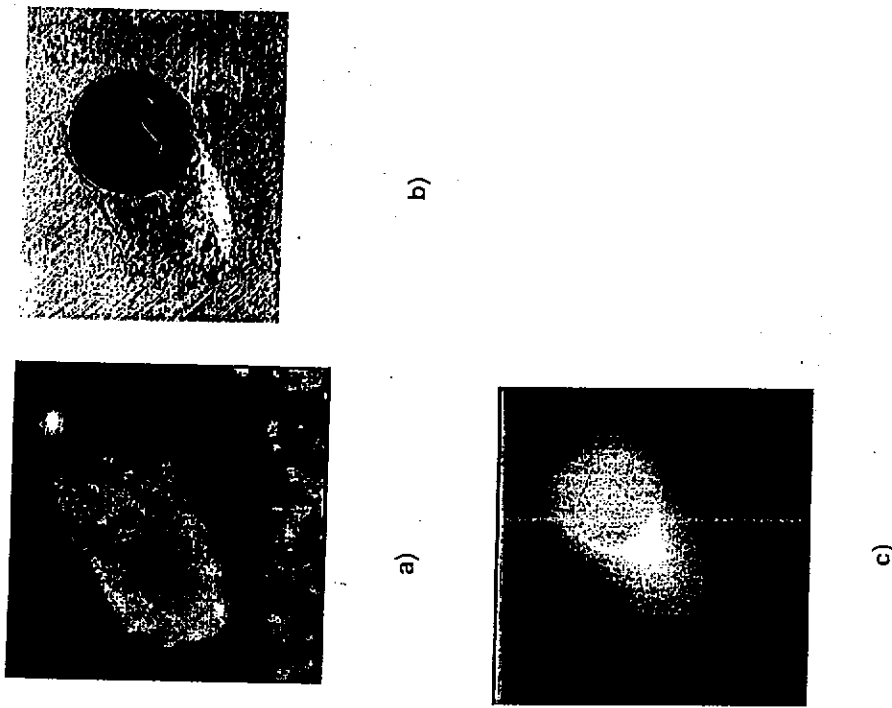


Abb. 8. Überprüfung des lateralen Auflösungsvermögens, a) Anordnung und Abmessungen der Testfehler, b) Prüfergebnis mit der Spezialsonde für Abbildungszwecke, c) handelsübliche Sonde mit sehr hohem lateralem Auflösungsvermögen, Rechts jeweils Amplituden/Ortsverlauf als Schnitt durch die Mitte der Anzeigen in waagrechtlicher Richtung

Fig. 8. Examination of the local resolution power, a) layout and dimensions of the test defects, b) test result with the special probe for imaging purpose, c) customary probe with a very high local resolution power. On the right respectively amplitude versus displacement as a sectional view through the maximum of the indications in horizontal direction

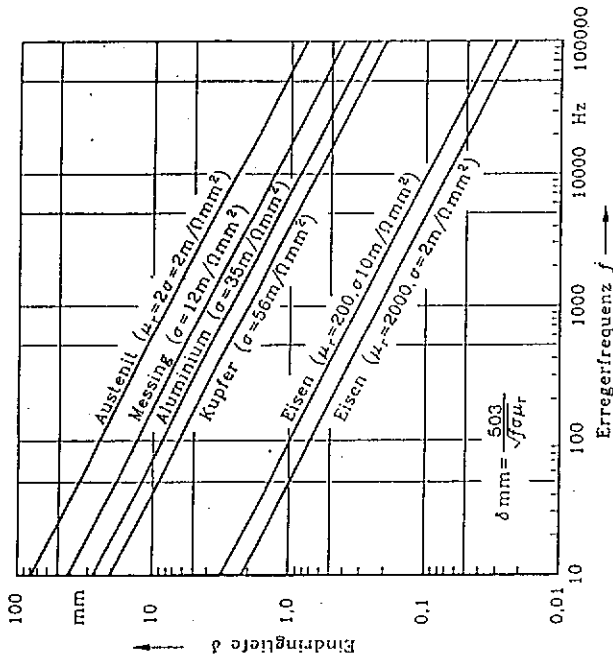
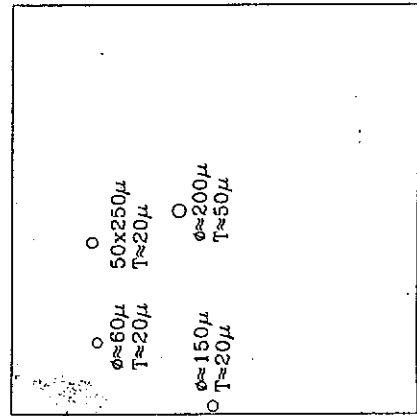
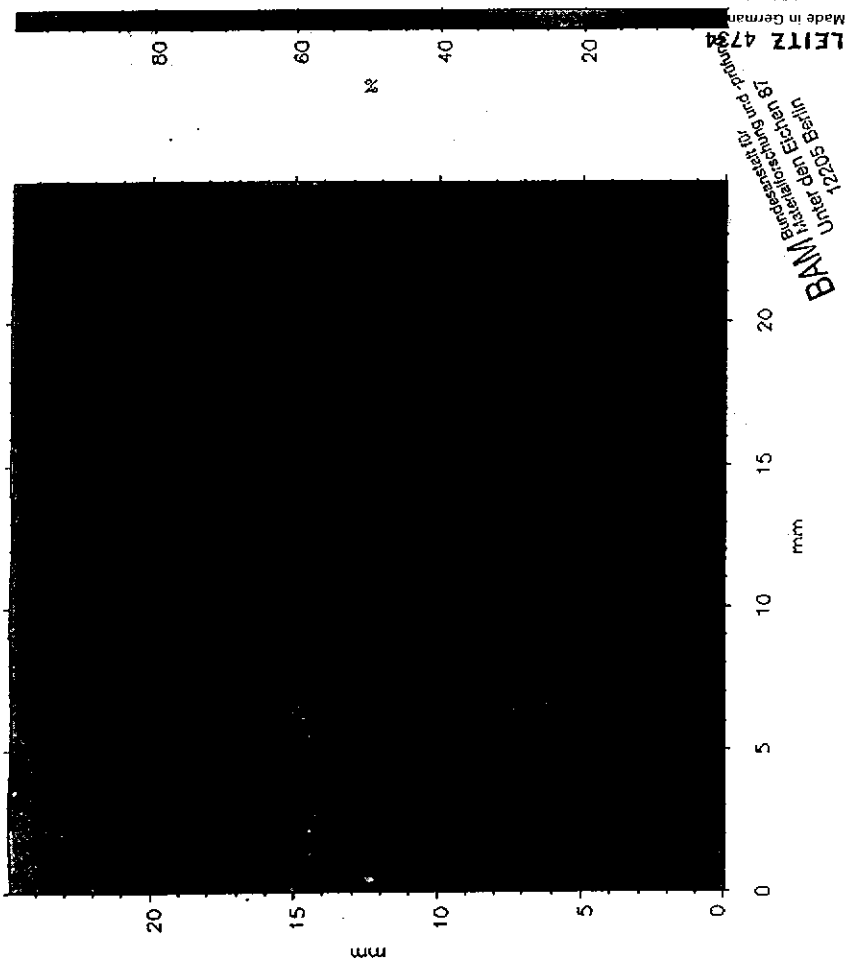
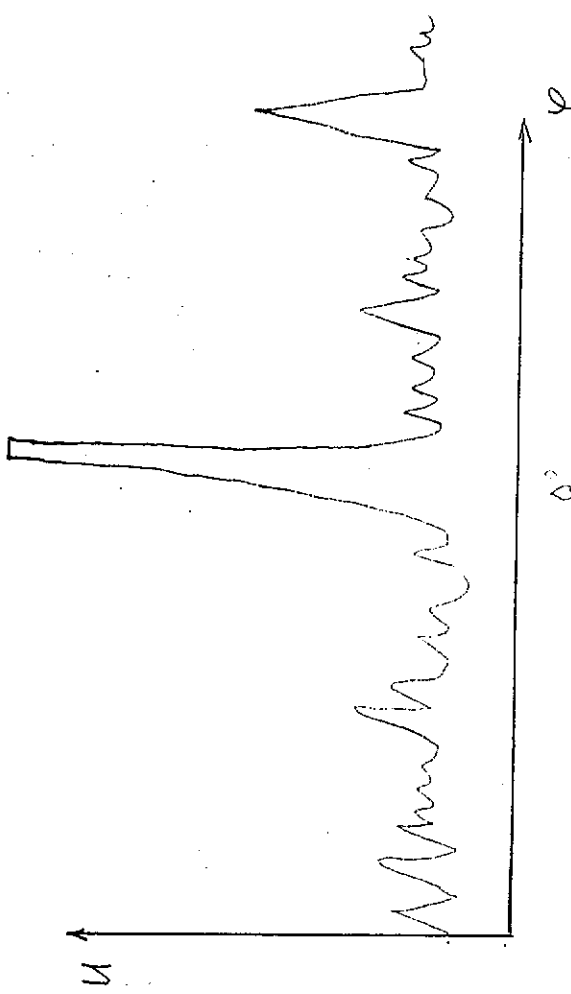


Abb. 2. Nomogramm zur Abschätzung der Eindringtiefe von Wirbelströmen als Funktion der Prüffrequenz für einige ausgesuchte Werkstoffe

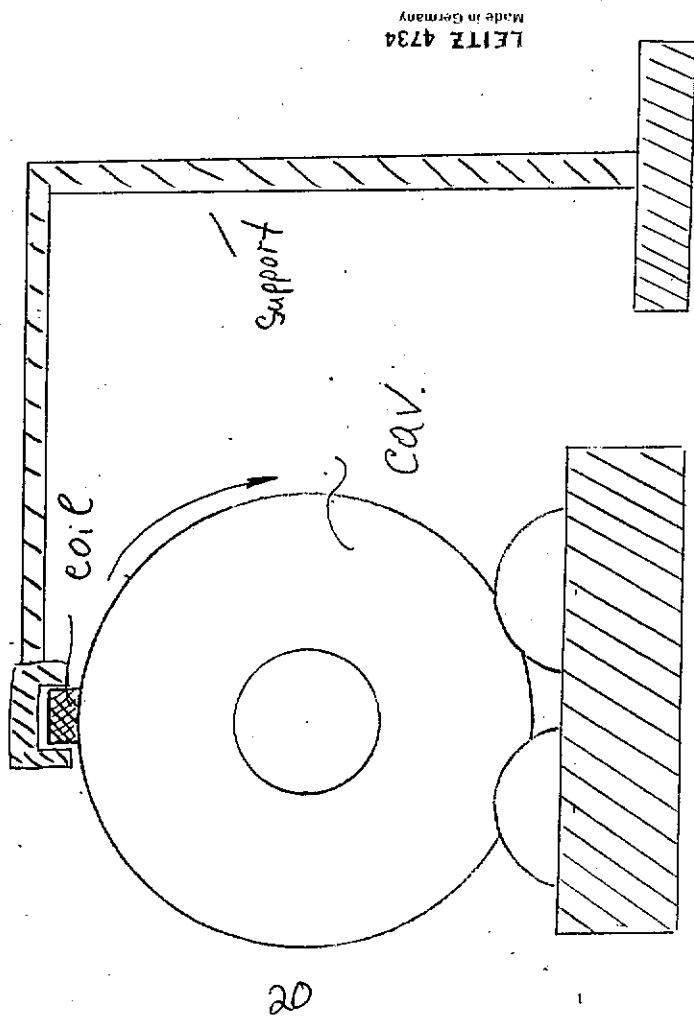
Fig. 2. Nomogramm for the estimation of the eddy-current penetration depth as a function of the test frequency for some materials



$\approx 0,2 - 0,3 \text{ mm}$



DC, cell 5



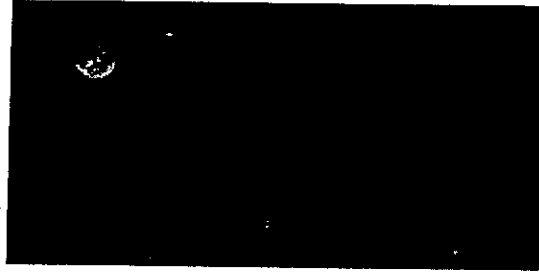
$\delta \approx 2-3 \text{ mm}$

Conclusions

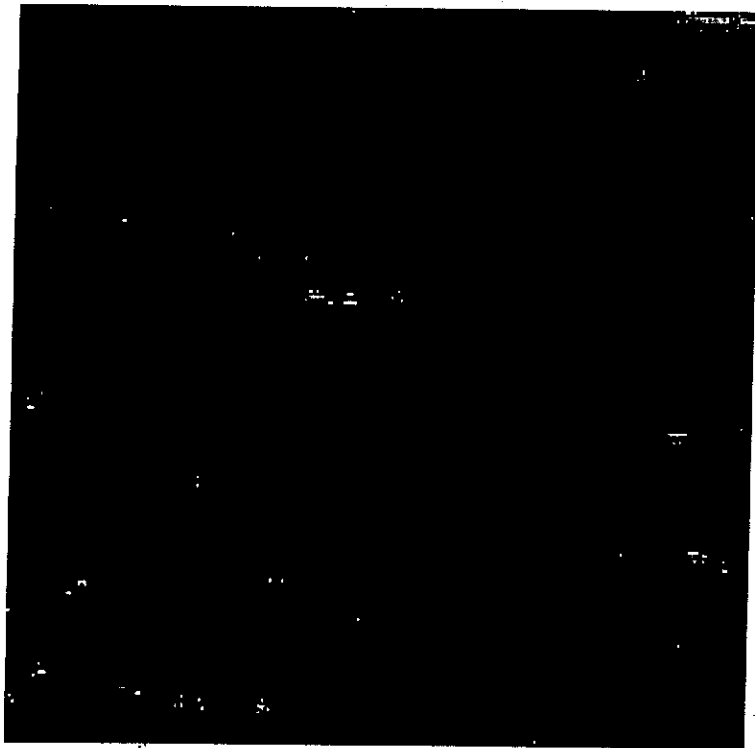
Eddy current inspection of Nb can be used:

1. to detect voids and scratches with minimal size of $100\ \mu\text{m}$ on the surface and inside of the material (depth $0 - 300\ \mu\text{m}$).
2. to detect cracks and inclusions with minimal size of $500\ \mu\text{m}$ inside of the material (depth $0 - 3\ \text{mm}$)

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Sacklochfeld



5mm

Ultraschall 10 MHz, Feldgröße 25 x 25 mm²,
Schrittweite 100 µm

*offensichtlich werden bei dieser Schichtweite
bereits Defekte zu sehen!*

*1.2.1996
B. S. S.*

First results on Nb magnetization hysteresis measurements.

Peter Schmüser

Idea and first experiments:

M. Wake, K. Saito KEK

DESY setup:

mechanics: O. Peters + group

coils: B. Hentschel

electronics

and program: H. Brück, M. Stöfler

design: PS.

Basic idea:

an ideal type II superconductor should exhibit reversible magnetization curve

hysteresis occurs when flux pinning centers are present:

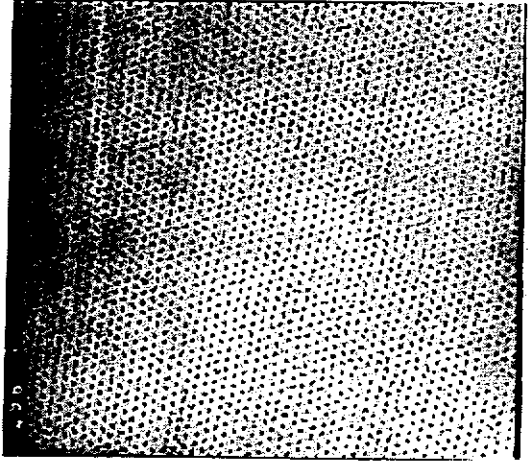
dislocations, foreign material

⇒ possible source for increased surface resistance

Particular concern: formation of NbTi during Ti-gettered heat treatment

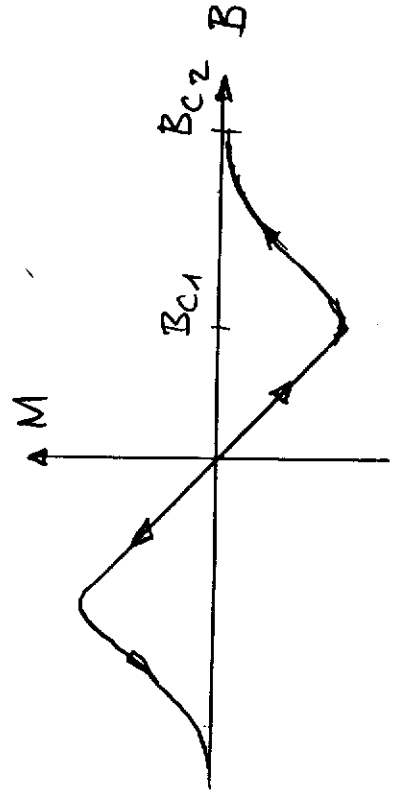
Niobium is a type II superconductor

flux tube lattice in pure Nb



U. Essmann
Stuttgart

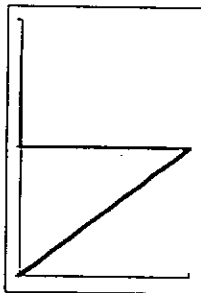
Nb
15400 x



expected magnetization curve for Nb without flux pinning

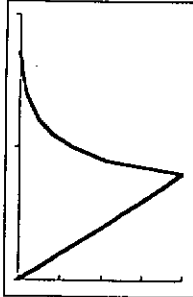
Magnetization Curves

Type I



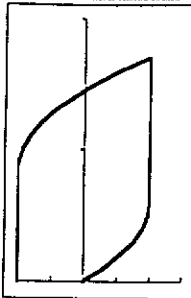
Lead

Clean limit
Type II



perfect niobium

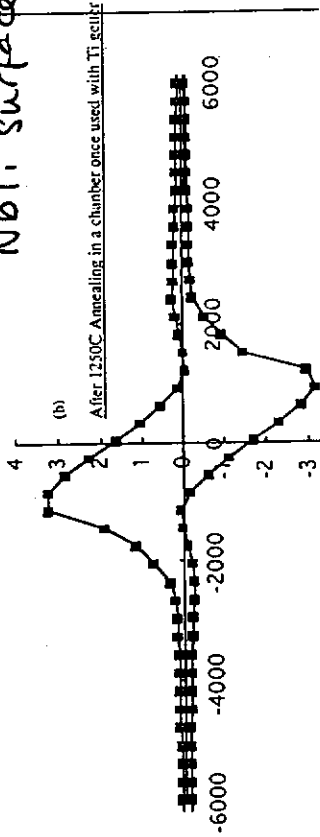
Dirty Limit
type II



NbTi cable

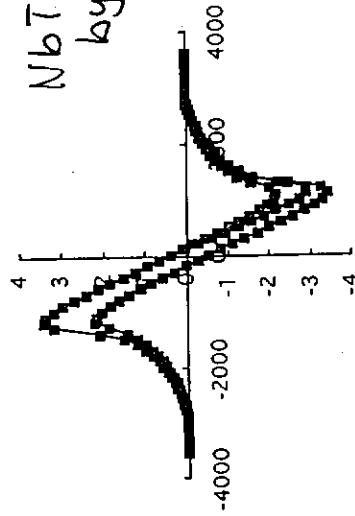
Wake, Saito

NbTi surface layer



(b) After 1250C Annealing in a chamber once used with Ti, reilly

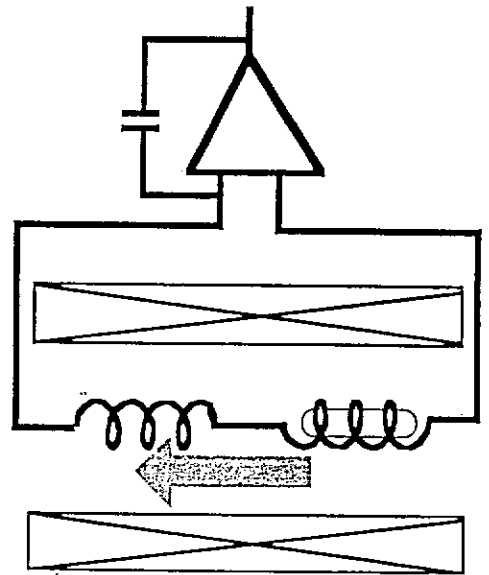
NbTi removed by BCP



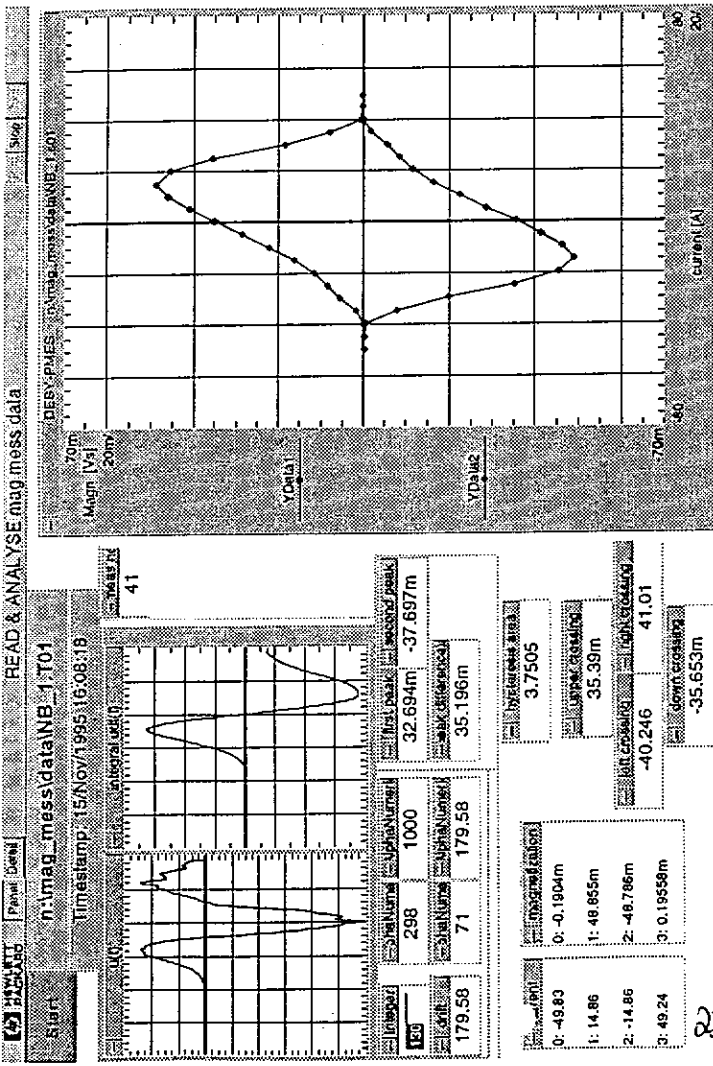
(c) After 2 min CP Nb-Ti in the surface was clearly removed.

Fig. 2 Titanium Migration

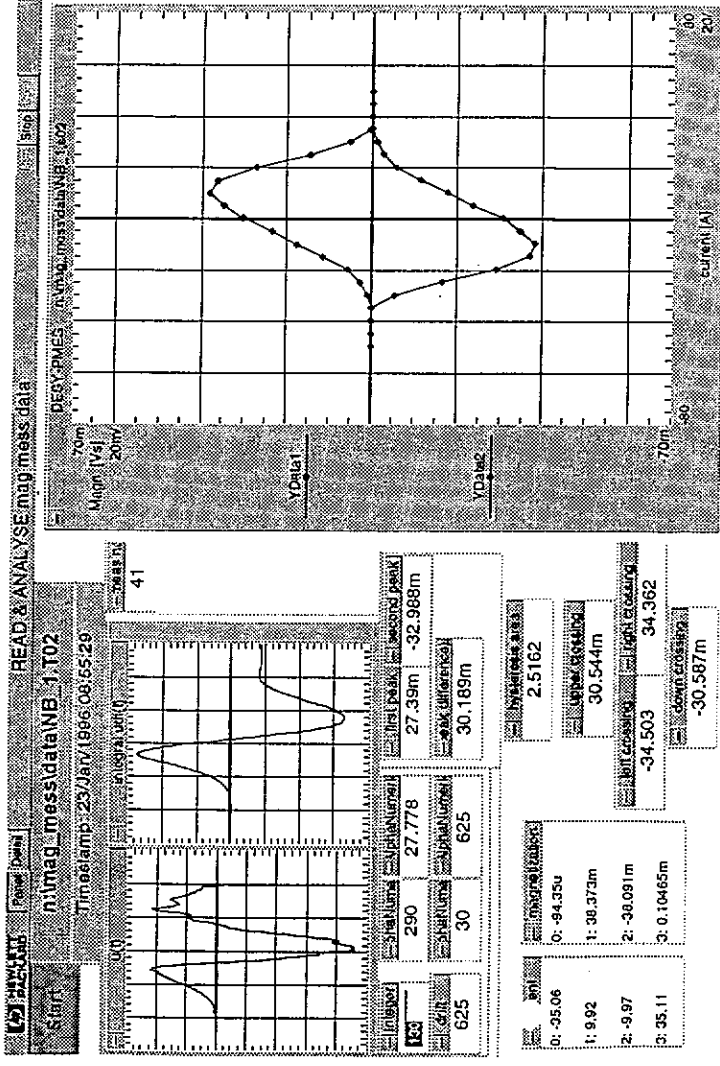
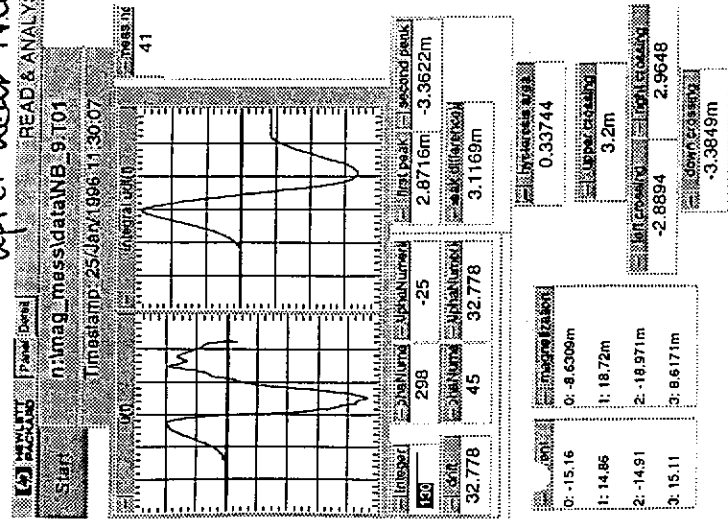
Magnetization Measurement



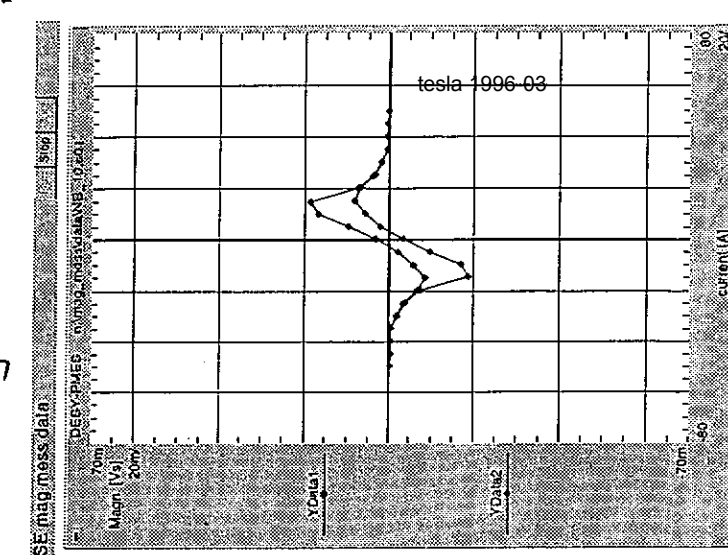
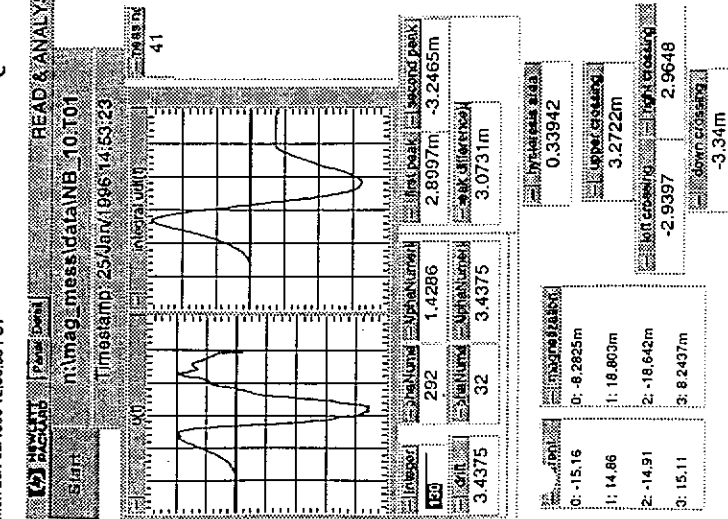
raw material (Heraeus)



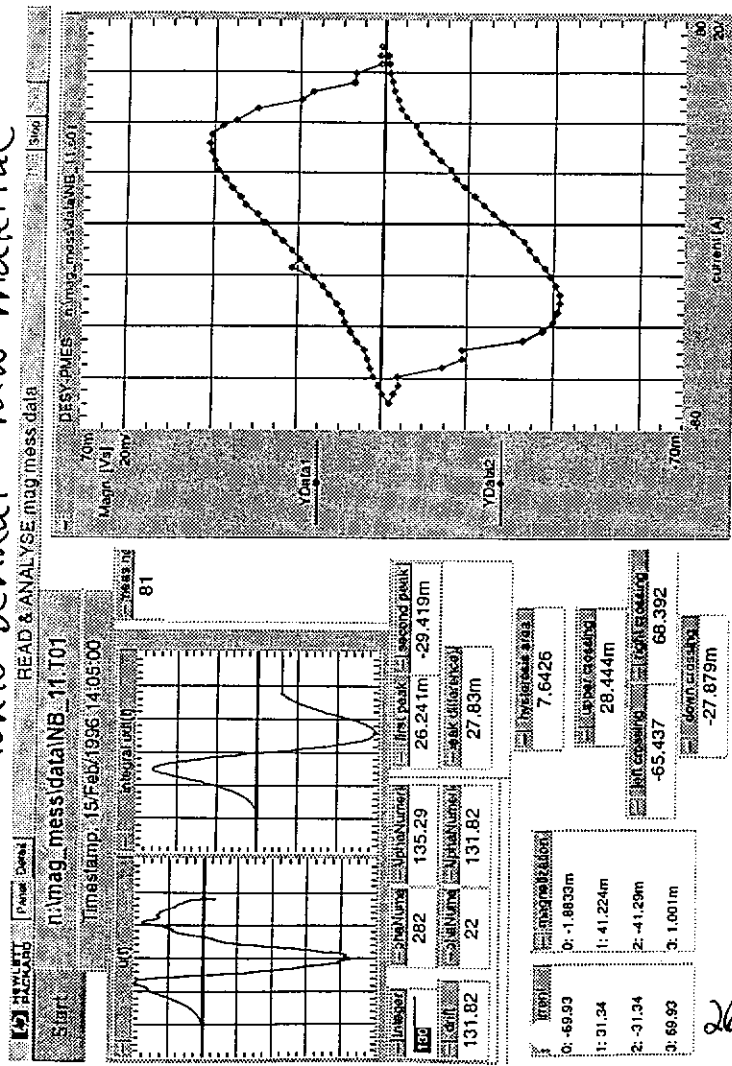
after heat treatment (1h 1400°, 3h 1250°C)



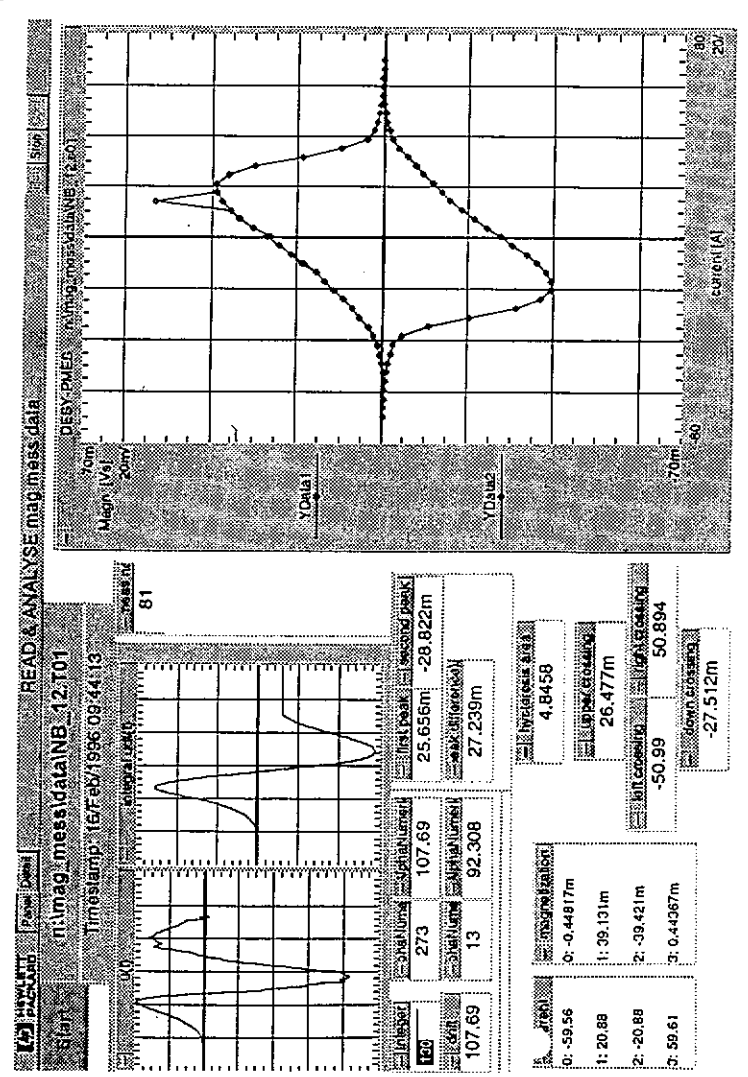
(no chemistry)



UK 10 VENKAI RAW MATERIAL



26



Thermal model calculations

29.2.96 / Detlef Reschke

Hartmut Elias

Walter Müller

Hans-Gerd Kürschner

Ralf W. Rößth

Detlef Reschke

Ansatz

- Equation for the thermal conductance on a lattice:

$$\Delta T(x) + \lambda(x, T)^{-1} \cdot \frac{dq(x, T)}{dt} = 0$$

- Steady state for $\frac{dQ}{dt}$:

$$-\dot{Q}_i = \dot{Q}_1 + \dot{Q}_2 + \dot{Q}_3 + \dot{Q}_4$$

\Rightarrow Power and temperature distribution without time dependence

- Cylinder symmetrical disk with or without defect in the center
 \rightarrow two-dimensional problem

Lattice and boundary conditions

- Lattice of variable size
- Narrow spacing near the defect
- Boundary conditions:

RF-side (z=0):

$$\frac{dQ}{dt} = \frac{dP}{dA} = \frac{1}{2} R_s(x, T) \cdot H_s^2$$

i) $R_s(\omega, T) = R_{BCS}(\omega, T) + R_{res}^{hom} \rightarrow r \neq 0$

ii) $R_s(T) = R_{Def}(T) \rightarrow r = 0$

28

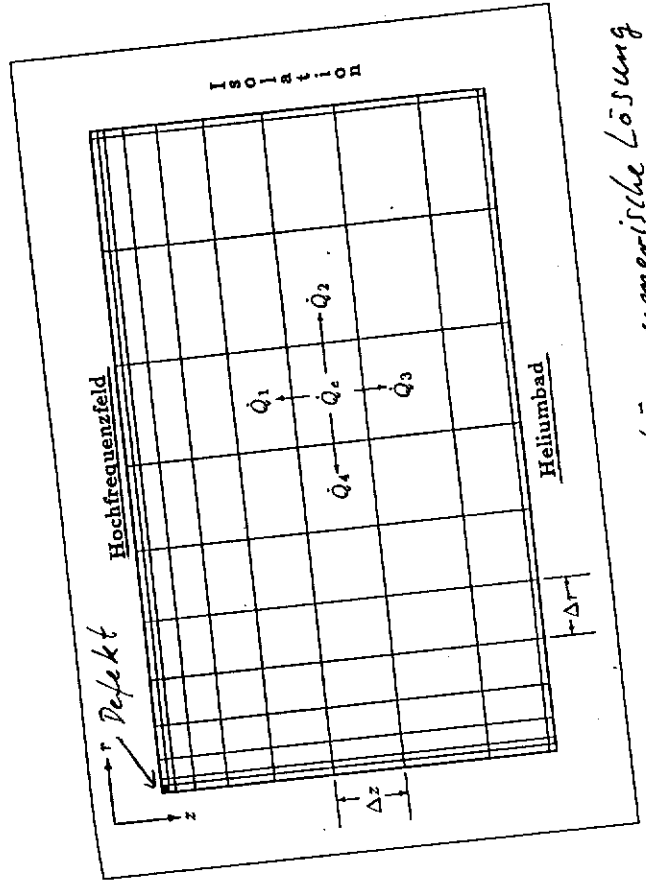
Helium bath (z=z_{max}):

$$\frac{dQ}{dt} = R_k(T_{B1}, \Delta T) \cdot (T_{N6} - T_B)^{-1}$$

T_B = const

Outer boundary (r=r_{max}):

$$\frac{dQ}{dt} = 0$$



Gitteraufteilung für numerische Lösung

Parameter

- Defect size r_D fixed
- Defect surface resistance R_D fixed/calc.
- Homogeneous surface resistance $R_{s, \text{hom}}$ fixed
- Thermal conductivity $\lambda(T)$ calculated
(parametrized measurements)

not only the RRR

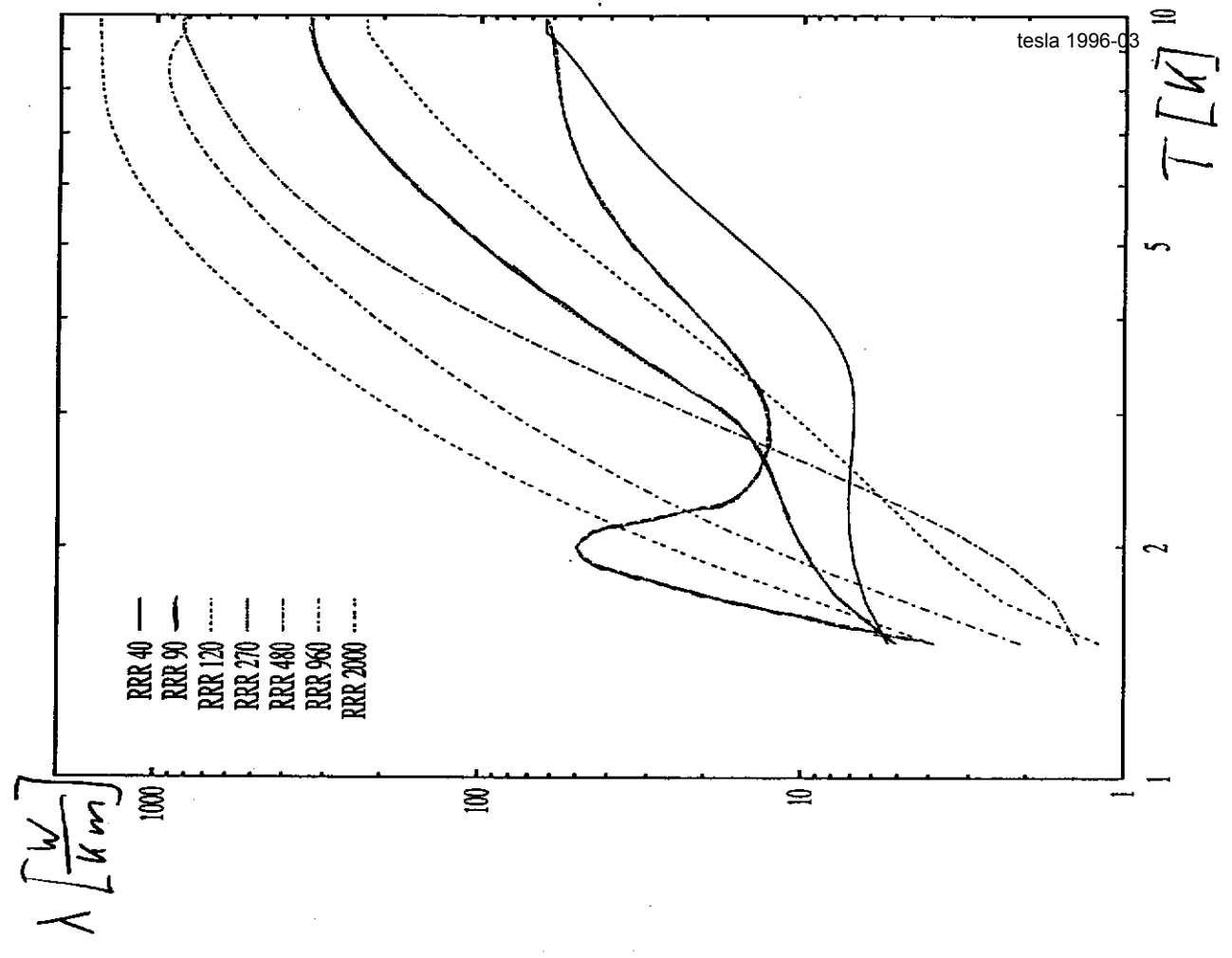
- Kapitza resistance $R_K(T, \Delta T)$ calculated

$$R_K(T, \Delta T) = 200 \cdot F \cdot T_B^{4.65} \left[\frac{\text{K m}^2}{\text{W}} \right]$$

$$F = 1 + \frac{3}{2} \frac{\Delta T}{T_B} + \left(\frac{\Delta T}{T_B} \right)^2 + \frac{1}{4} \left(\frac{\Delta T}{T_B} \right)^3$$

for fixed niobium (Mittag, 1973)

- Bath temperature T_B (1.4K \rightarrow 4.2K) fixed
- Frequency ω (3 GHz) fixed
- Thickness of the disk (cavity wall) (2mm) fixed
- R_s of normal conducting niobium (8 m Ω) fixed
- + some more (numerical, $H_{c,ns}(0), T_c, \dots$)



Two Remarks:

- $\lambda(T) \propto RRR$

Normal conducting, electric conductivity related to superconducting thermal conductivity (Kadanoff - Martin; Wiedemann-Franz)

$$\Rightarrow RRR = c \cdot \lambda(4.2K) \leftarrow \text{One point } \lambda(T)_0$$

with $c \approx 4(-7)$

⊗

- Kapitza resistance

- Material and preparation dependance

→ Mitag and Orsay fit within 30%
(RRR 40, Alred) (RRR 200-300, BCP) (T=1.5K-2.1K)

but:

Saclay data factor of 2 higher?

What is a "calculated" Quench?

- Quench independent of the temperature of the defect

- i) No stable power distribution in the lattice can be achieved

→ (ii) "High" temperatures in the neighbourhood of the defect)

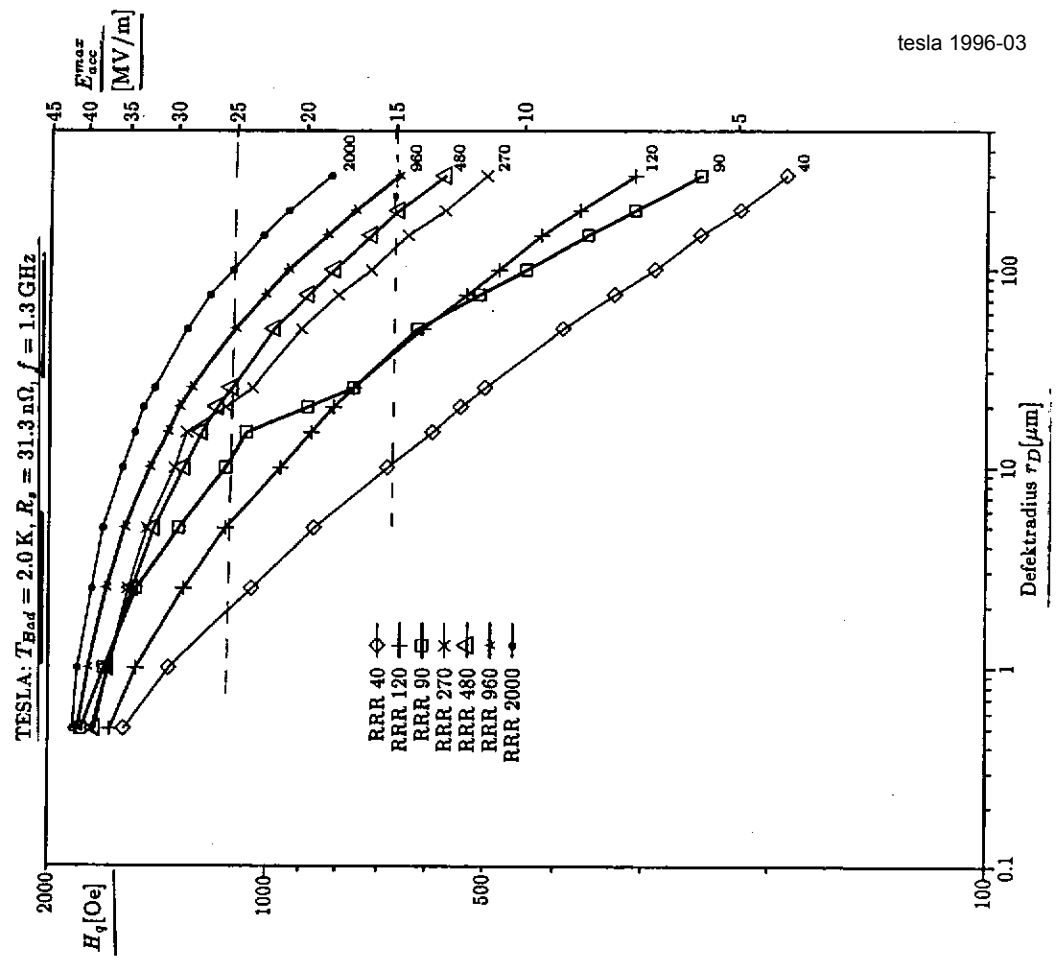
Results

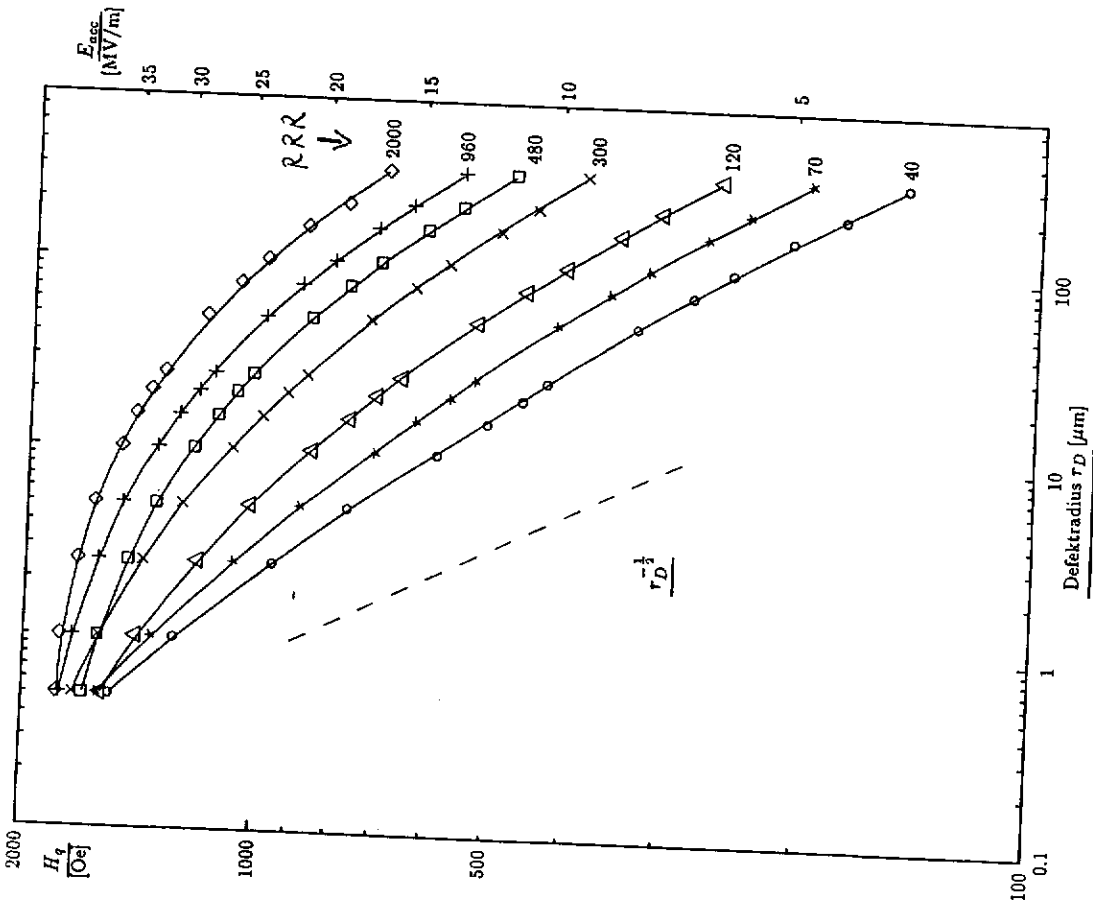
- For a given set of parameters:
 - i) quench field
 - ii) temperature distribution for each step of the RF-field

- Most calculations up to now: \emptyset
 $f_0 = 3.6 \text{ GHz}$
 $d = 2 \text{ mm}$

- One set of calculations for 1.3 GHz
 by H.G. Kirschner
 but: "wrong" thermal conductivity \emptyset

RRR 270: Wahn-Chang / non-fired
 RRR 480: Gired met / non-fired
 RRR 960: Protvino / non-fired
 RRR 2000: Gired met / fired with Ti



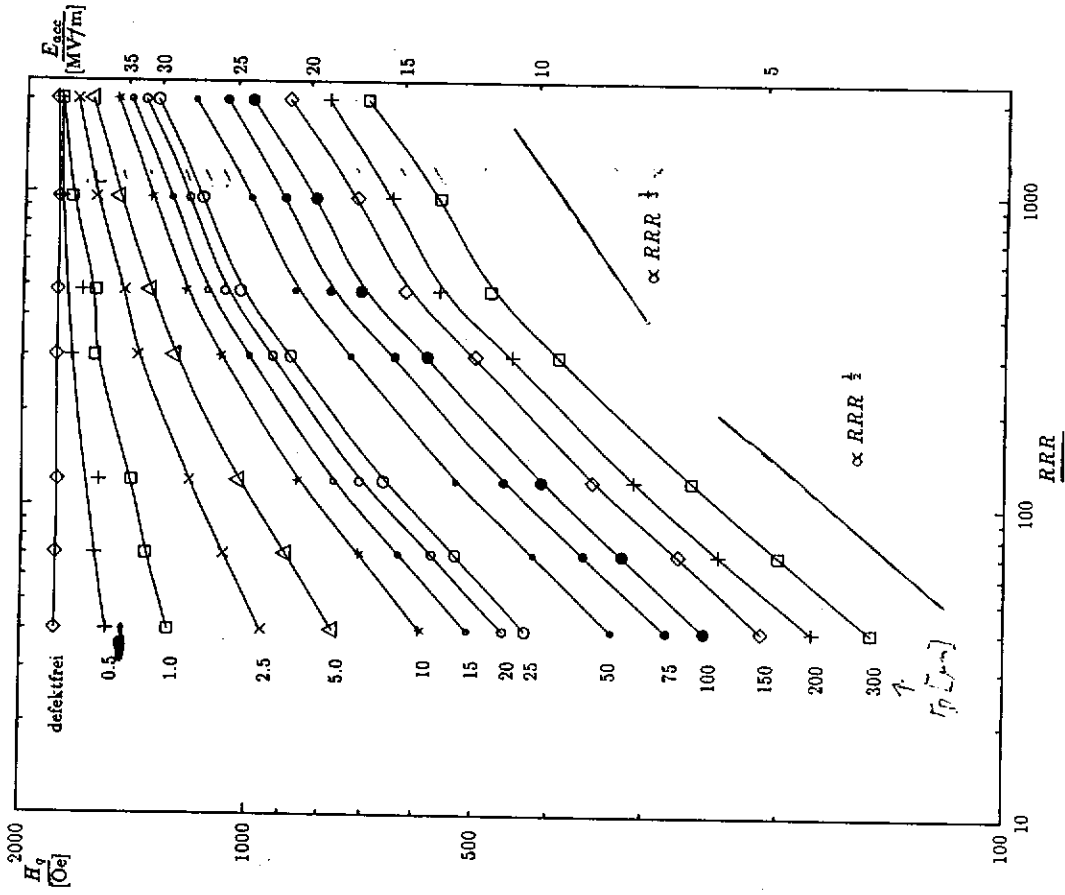


Parameter:

$T_B = 1.4\text{K}$; $D = 2.0\text{mm}$; $R_{hom} = 0\Omega$; $R_{Def} = 8\text{m}\Omega$

$f = 3\text{GHz}$

I(10)



Parameter:

$T_B = 1.4\text{K}$; $D = 2\text{mm}$; $R_{hom} = 0\Omega$; $R_{Def} = 8\text{m}\Omega$

$f = 3\text{GHz}$

I(10)

Summary for quench fields

- The calculated quench fields are in agreement with the experiments.
- Calculations for TESCA-parameters are no problem:
e.g. dependence of the wall thickness

→ but have to be done!

$$\lambda(T)$$

- The higher the ~~BAR~~ and the smaller the defects the benefit of increasing the thermal conductivity becomes less.
(less than $\sim \sqrt{\lambda}$)

- Final remark:

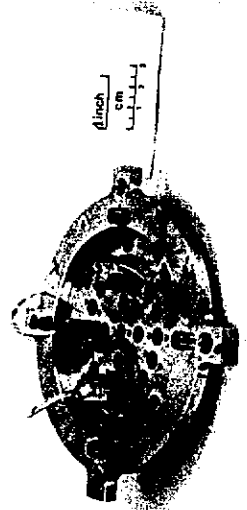
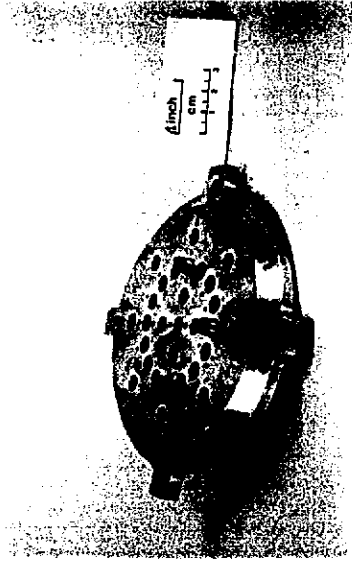
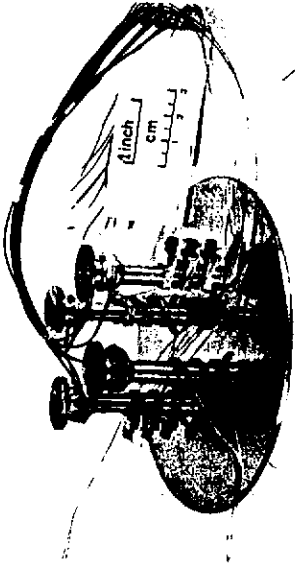
Actoser look shows, that the simple model of a n.c. defect and surrounding homogeneous material cannot explain the experiments of $\Delta T(H_s)$, $\Delta R_s(H_s)$

1

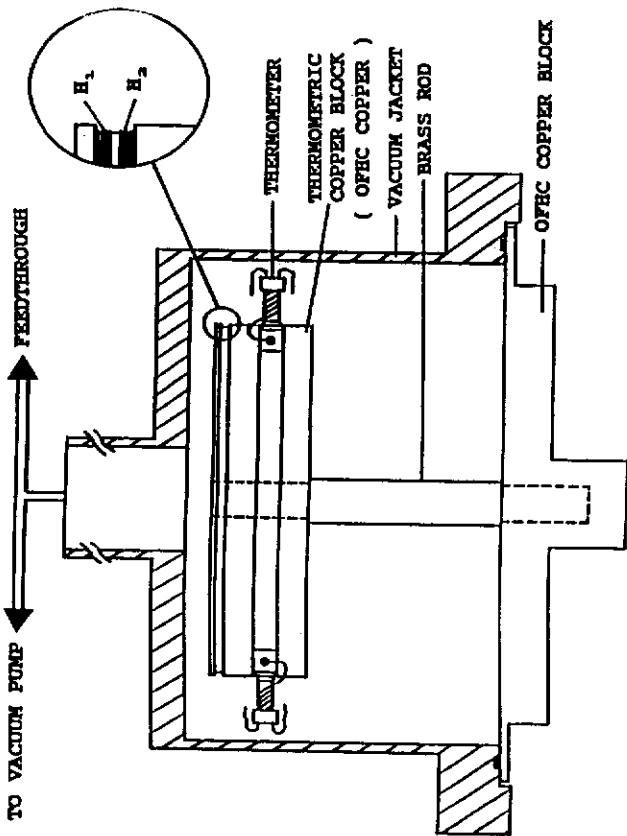
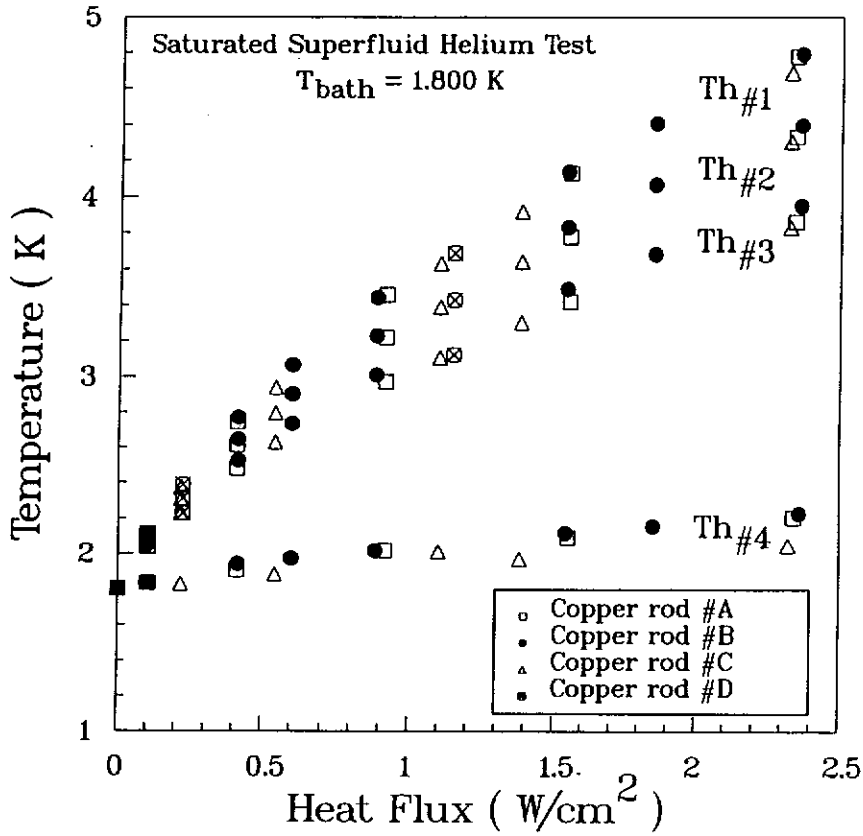
H. FOUAIDY IPN-Orsay

TESLA/TTF R&D Meeting
DESY - HAMBURG Feb. 29, 1996

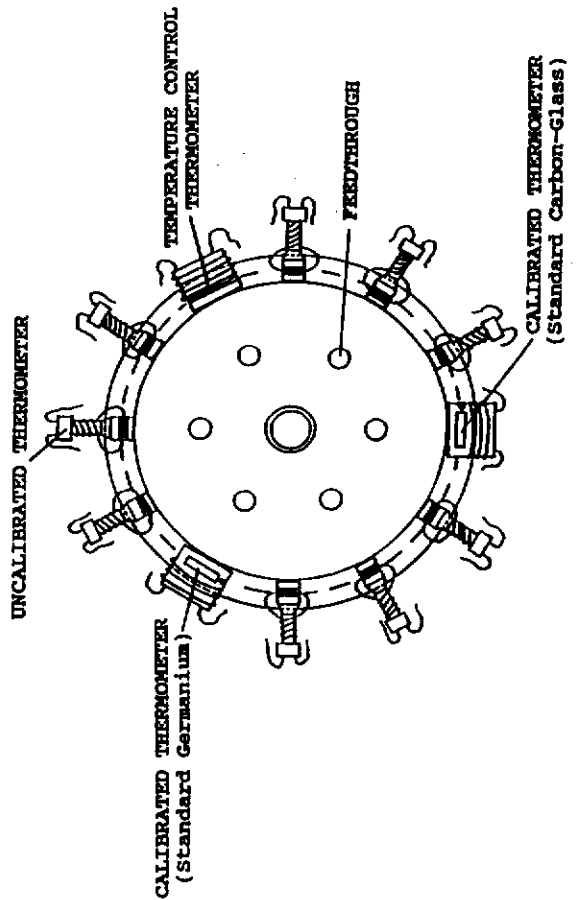
<p>High Heat Flux Kapitza Conductance at Cu-HeII Interface and critical Heat Flux in saturated HeII</p>



**COPPER ROD TEMPERATURE VARIATIONS
VERSUS THE APPLIED HEAT FLUX**
Th#1 z=23.3mm, Th#2 z=15.3mm, Th#3 z=7.3mm, Th#4 z=0
Run of November 1995

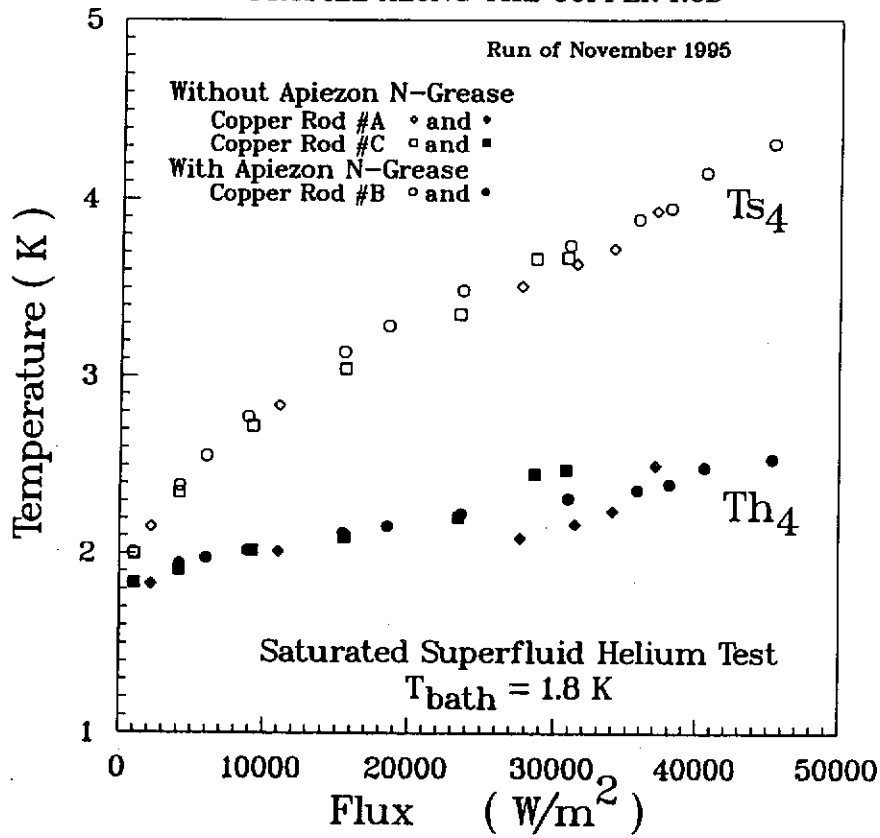


LIQUID HELIUM ($T_{\text{bath}} = 4.2 \text{ K}$)

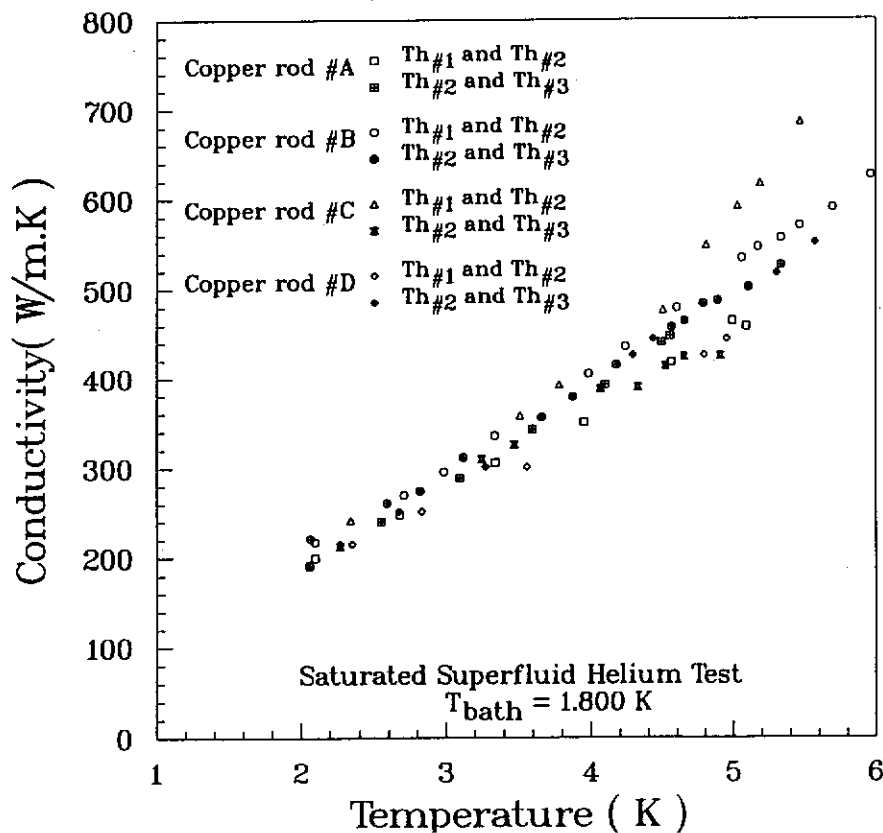


CALIBRATION CELL ($4.2 \text{ K} - 20 \text{ K}$)

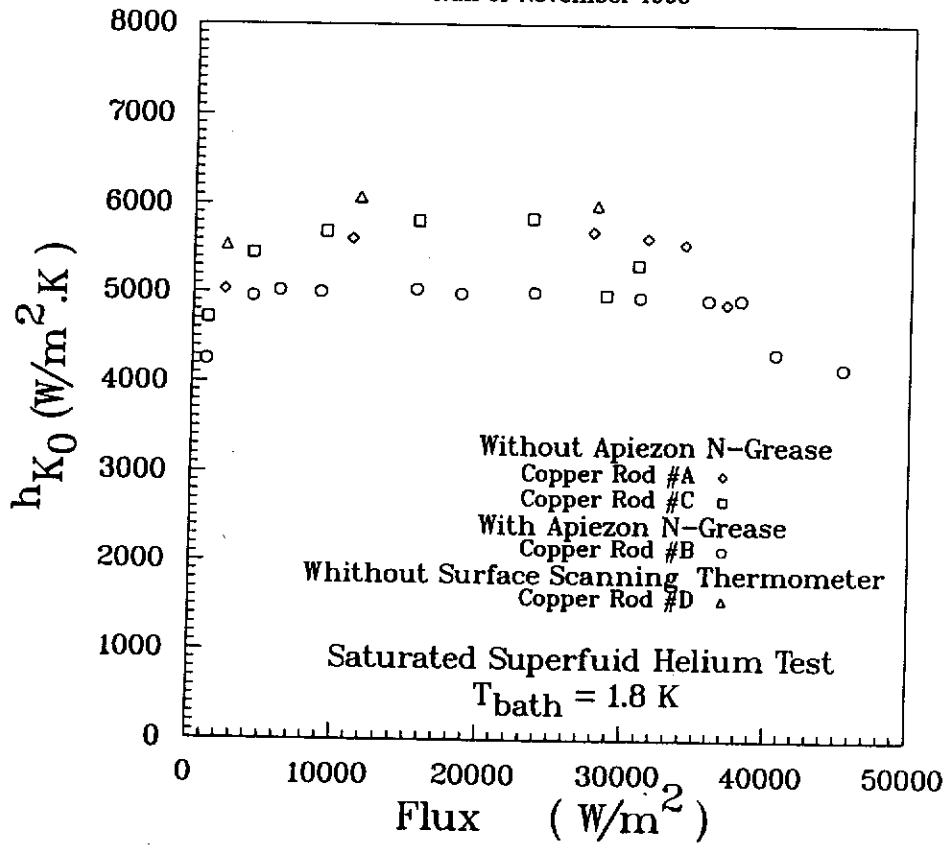
COMPARISON OF THE SURFACE SCANNING THERMOMETER
THERMAL REPOSE WITH THE SURFACE
TEMPERATURE EXTRAPOLED FROM THE TEMPERATURE
PROFILE ALONG THE COPPER ROD



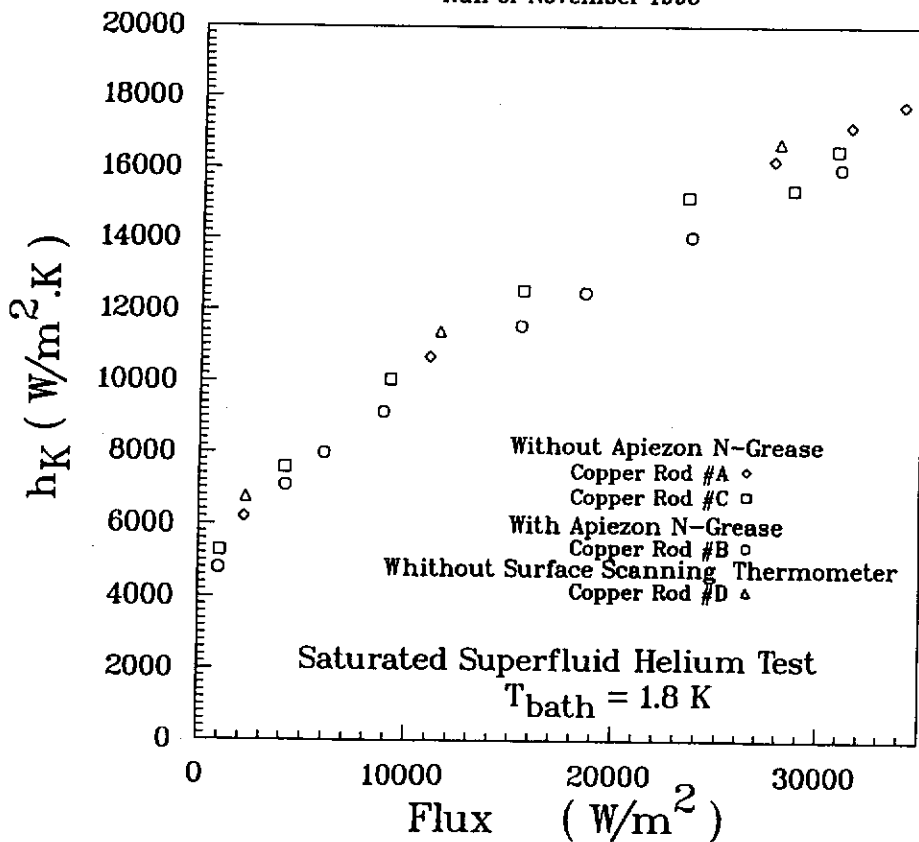
OFHC COPPER RODS
THERMAL CONDUCTIVITY
Experimental cell with four heater-posts
Run of November 1995



LOW HEAT FLUX KAPITZA CONDUCTANCE
AT Cu - HeII INTERFACE FOR THE 4 COPPER RODS
(A, B, C and D)
Run of November 1995



GLOBAL KAPITZA CONDUCTANCE
AT Cu - HeII INTERFACE FOR THE 4 COPPER RODS
(A, B, C and D)
Run of November 1995



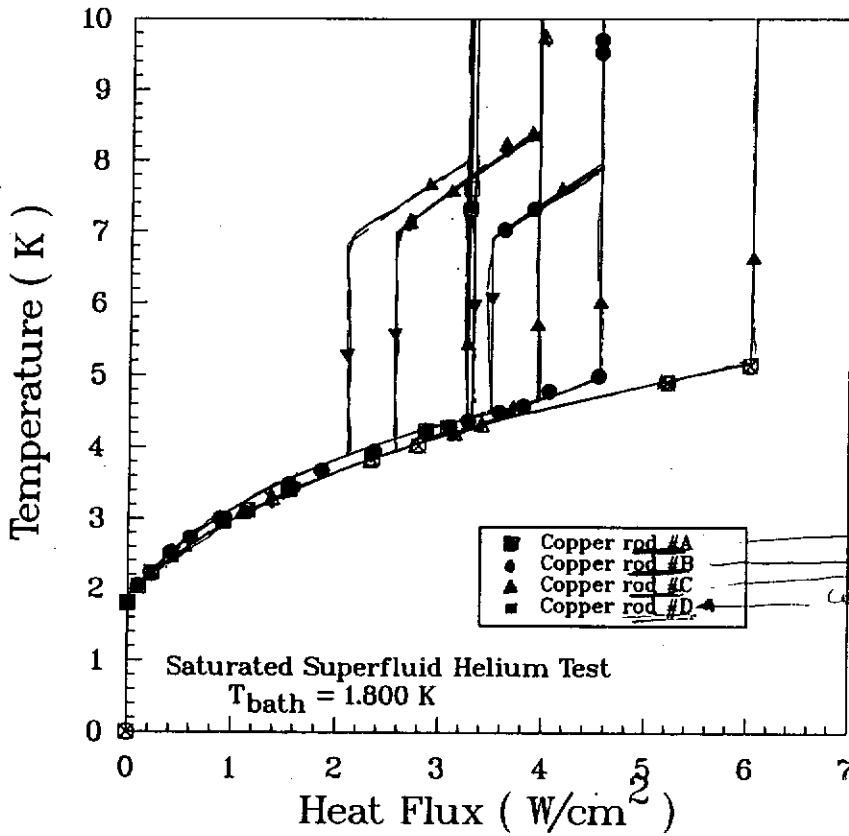
COPPER ROD TEMPERATURE VARIATIONS
VERSUS THE APPLIED HEAT

tesla 1996-03

For the THERMOMETER #3 located at $z = 7.3$ mm

Run of November 1995

*from the HeII
cooled surface.*



Authors	h_0	n	$H_K @ 1.8$ K	Runs
Mittag(1973)	0.0170	3.62	0.143	
Mittag(1973)	0.020	4.65	0.308	
Wilkes(1978)	0.0136	3.99	0.142	
Wilkes(1978)	0.0252	3.90	0.242	
Wilkes(1978)	0.0072	4.41	0.096	
Wilkes(1978)	0.0145	3.96	0.149	
Wilkes(1978)	0.0240	4.30	0.310	
IPN-GECS	0.0883	3.25	0.596	Oct.90 (*)
IPN-GECS	0.0774	3.44	0.585	Dec.90 (*)
IPN-GECS	0.0359	4.28	0.444	Oct.91 (**)

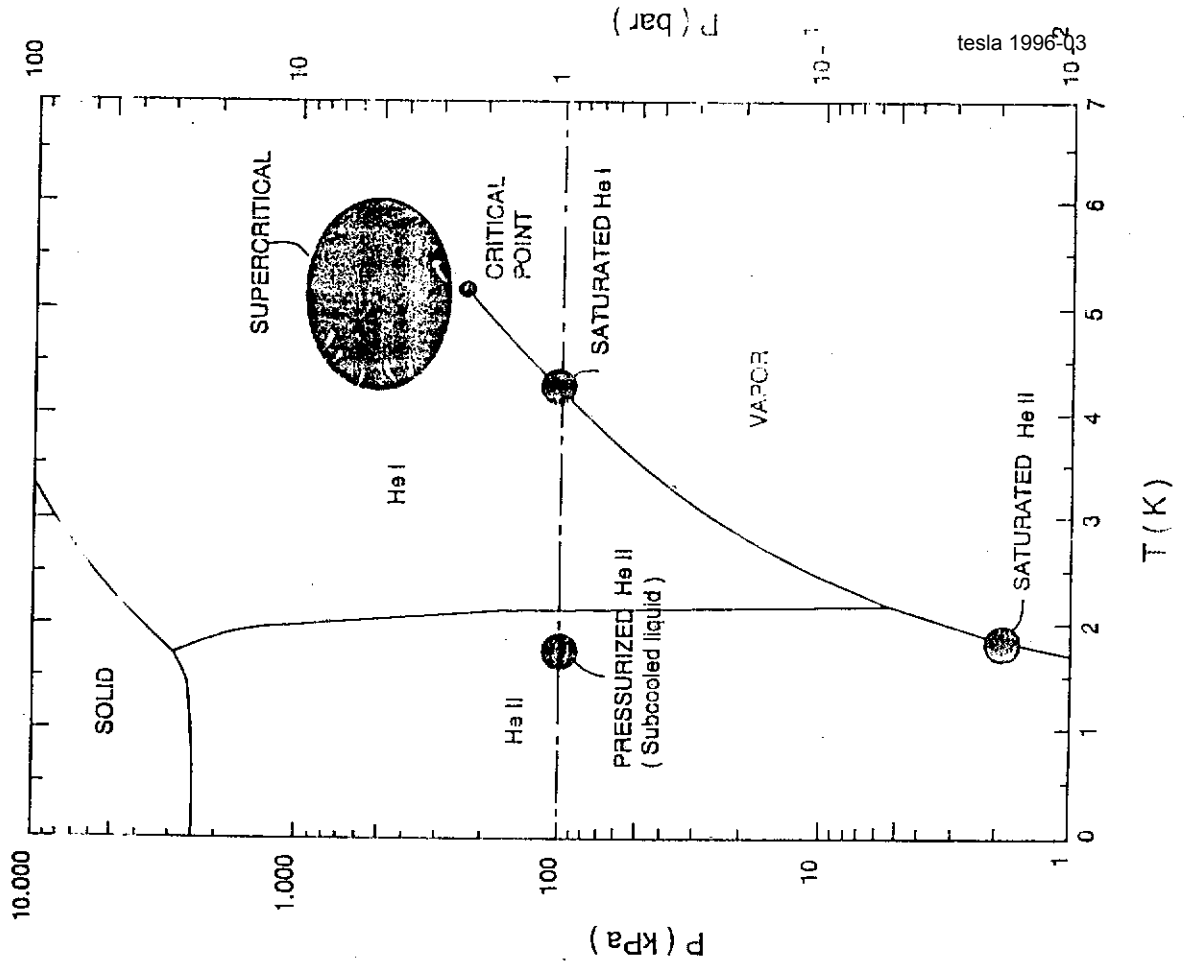
$H_K = h_0 T_{\text{bath}}^n \text{ (W/cm}^2 \cdot \text{K)}$

(*) Standard SRF Surface Chemical Treatment and Long Term (≈ 9 months) stay of the sample under Ambient Atmosphere (Air)

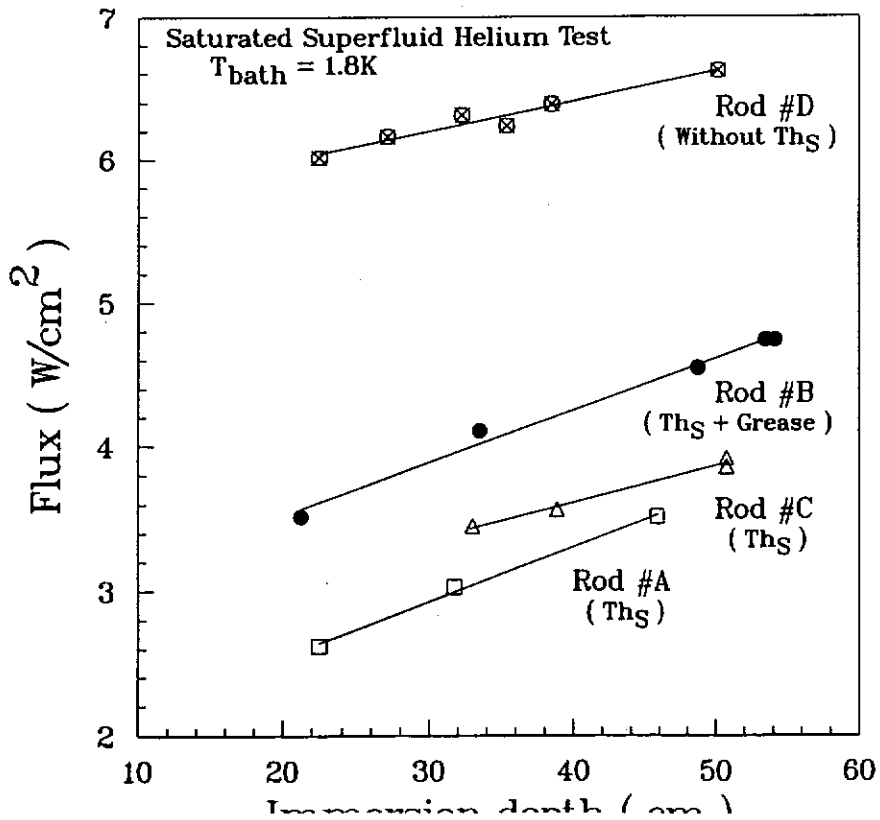
(**) The same sample underwent a new Chemical Treatment in standard way as for item (*) but was kept under helium atmosphere before experimental runs

Table 1 : Experimental Kapitza conductance H_K for niobium samples of different surface treatments

PHASE DIAGRAM OF HELIUM



CRITICAL HEAT FLUX
AT THE TRANSITION TO FILM BOILING
Horizontal heated surface facing downward
Run of November 1995



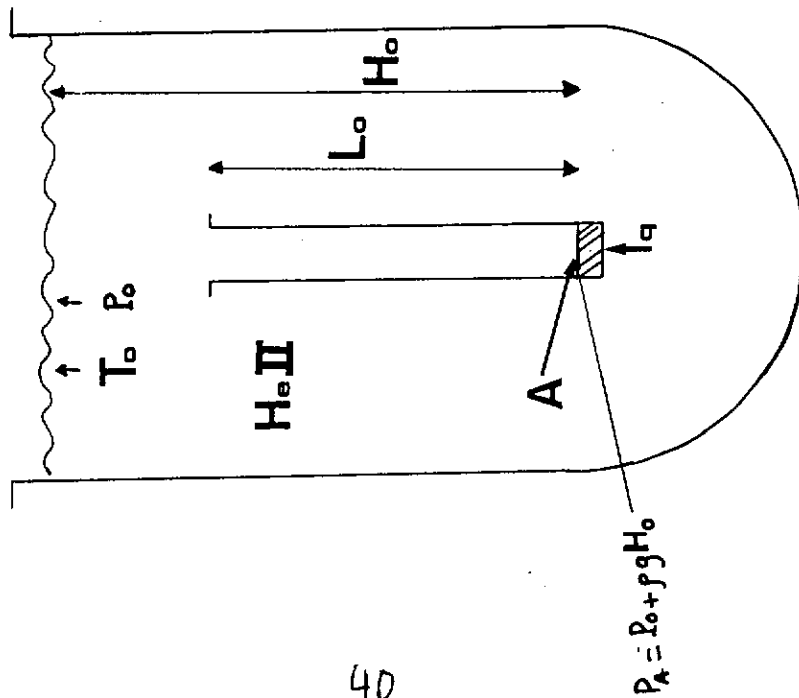


Fig. 2.16a: Transport de chaleur solide-conduit He II - Thermostat : schéma de la configuration expérimentale

Heat transport in HeII confined to a channel.

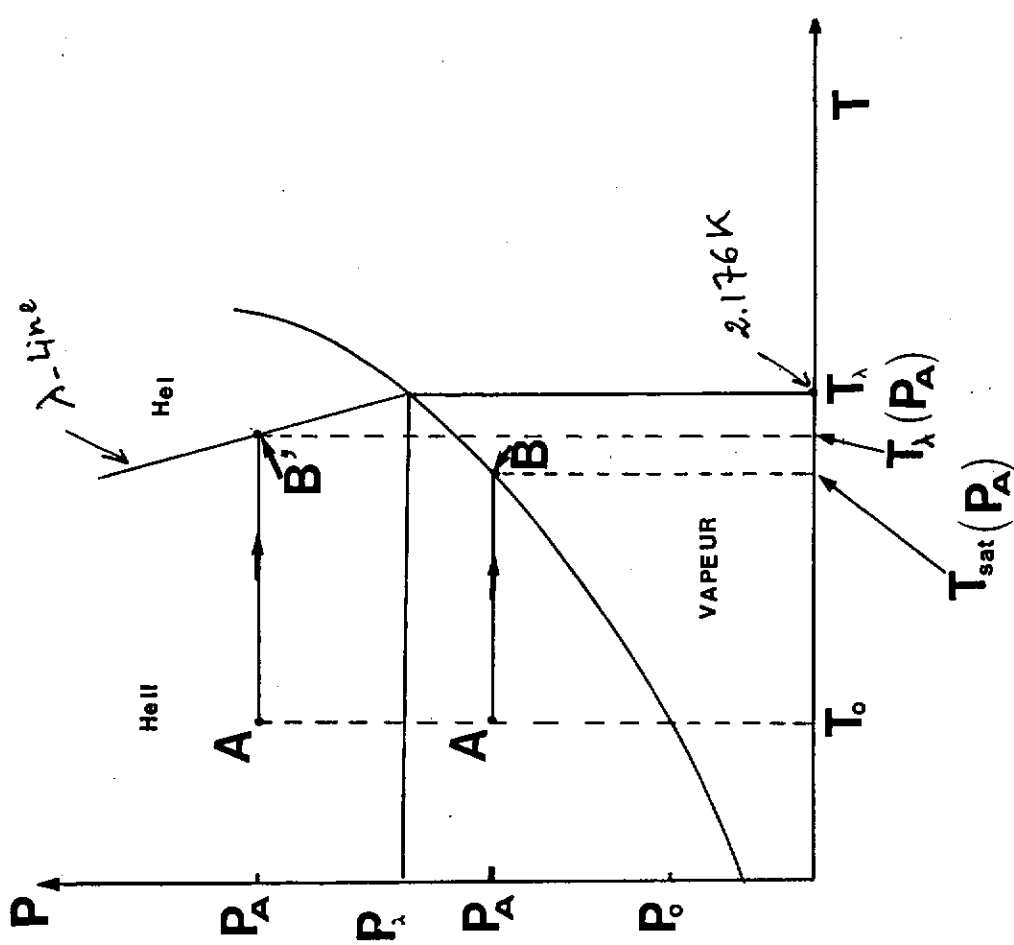
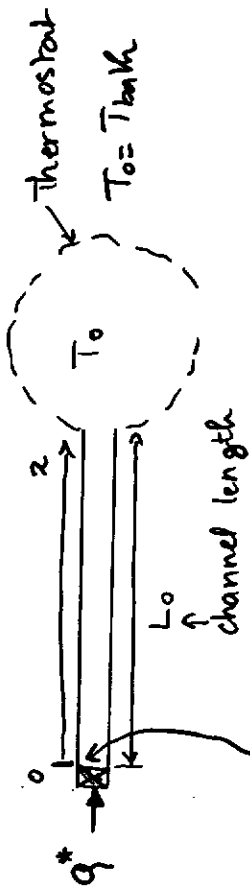


Fig. 2.16.b : Schéma des états thermodynamiques suivis par le "fluide A" adjacent à la paroi chauffée.

Thermodynamic path of the HeII layer adjacent to the heat source.

LIMITING HEAT FLUX (INDUCING PHASE CHANGE) IN HE II CONFINED TO A CHANNEL



T_L = temperature of the fluid layer adjacent to the cooled solid.

The limiting heat flux is determined by the limiting temperature on the Helium phase diagram:

$$T_L = T_{sat}(P_A) \quad \text{if } P_A < P_\lambda$$

$$T_L = T_\lambda(P_A) \approx T_\lambda^{SVP} \quad \text{if } P_A > P_\lambda$$

P_A is the local pressure of the liquid in front of the cooled solid

$$P_A = P_{sat}(T_{bath}) + \rho \cdot g \cdot H$$

↑ immersion depth
Hydrostatic pressure heads

Limiting Heat Flux

$$Eq \text{ (GHI)} \quad q_L = q^* = \left(\frac{1}{L_0} \int_{T_L}^{T_0} \frac{dT}{\rho(T)} \right)^{1/3} \quad \text{(Gorter-Tellink relation)}$$

with $m = 3$ heat conductivity function see the curve.

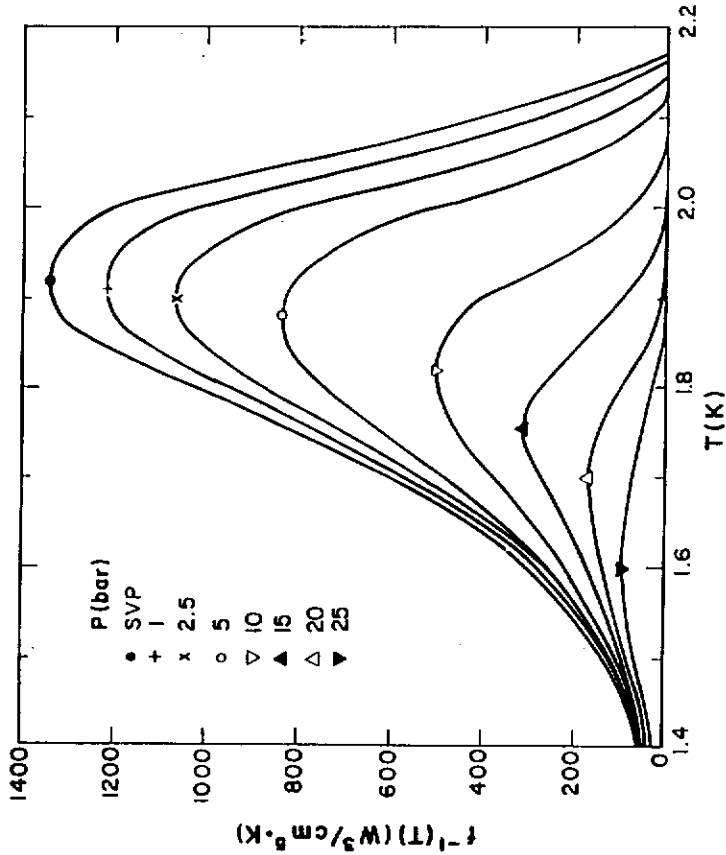


Fig. 5.3. Heat conductivity function for turbulent He II. Symbols indicate the location of the peak value.

10

H. FOUAIDY
PhD Thesis Paris VI
Univ., January 1989

$T_0 = 2,005K$ (Thgk)
• Théorie → Theory (GM equation)
• Expérience → experimental data

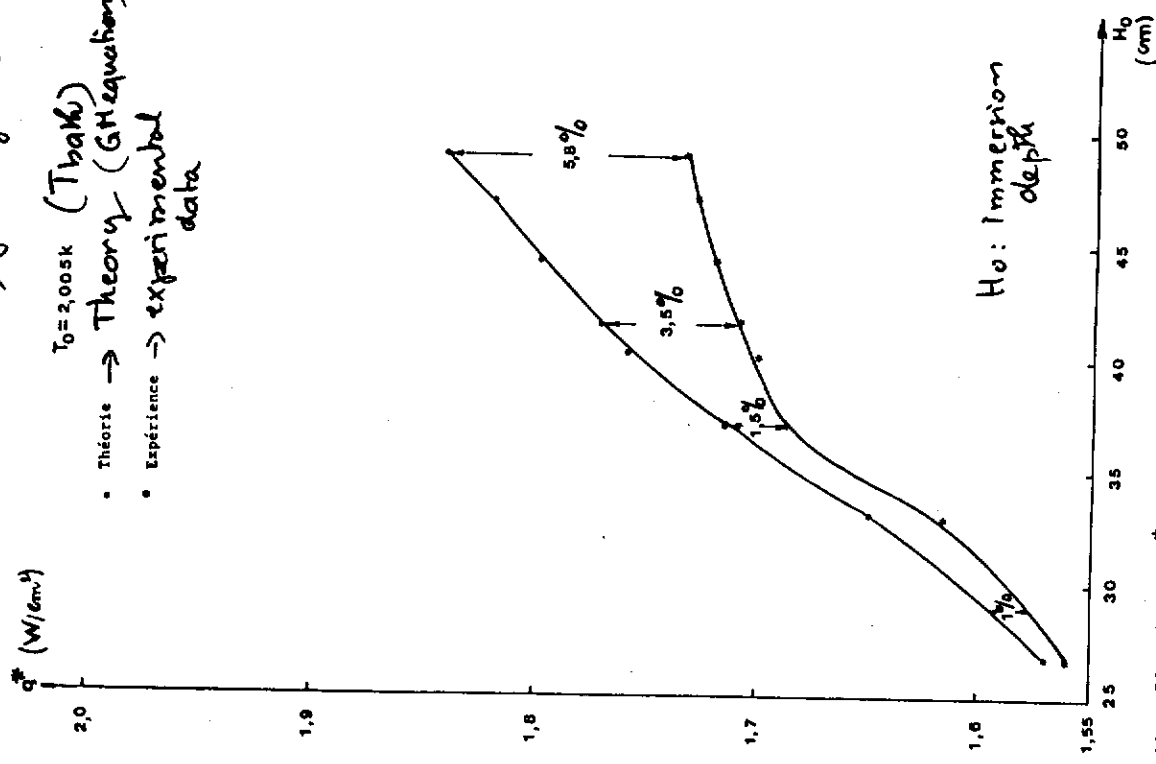


Fig. 5.44 : Flux limite q^* à la transition He II → vapeur en fonction de la profondeur d'immersion H_0 de la paroi chauffée par rapport à la surface libre du bain.

Critical Heat Flux in He II confined to a vertical channel (diameter: 10mm length = 150mm)

H. FOUAIDY (17)
PhD Thesis Paris VI Univ
January 1989

$T_0 = 1,9 K$ (Thgk)

GM equation
Sec
• Théorie → Theory
• Expérience → experimental data

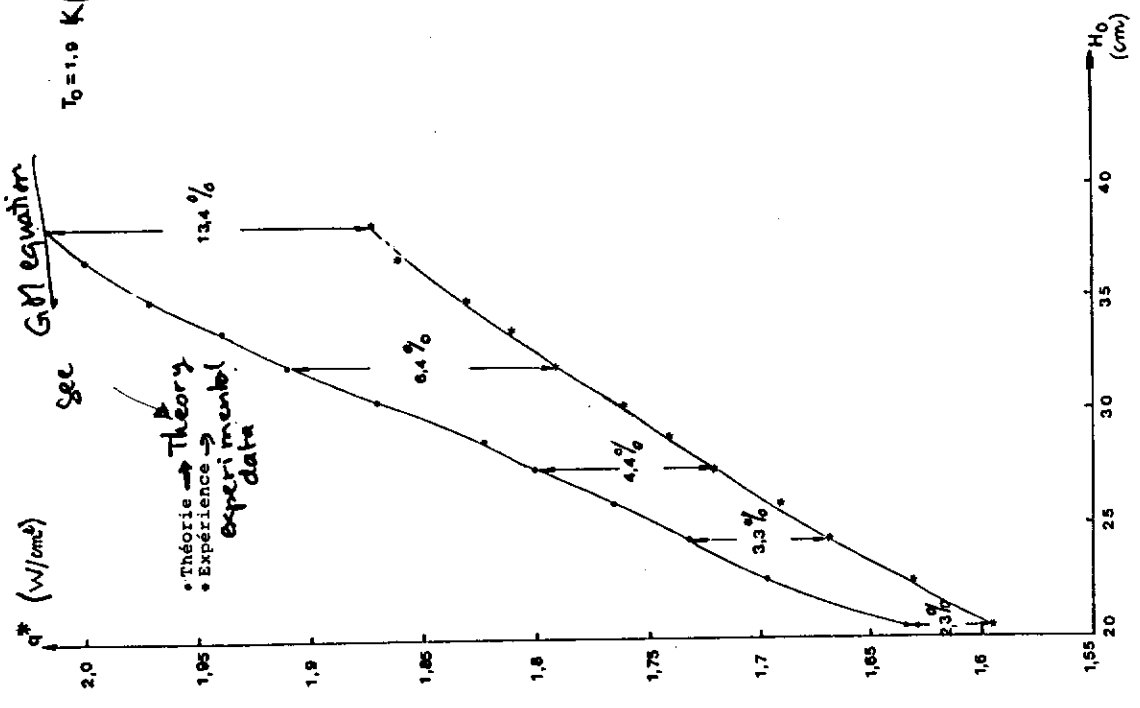


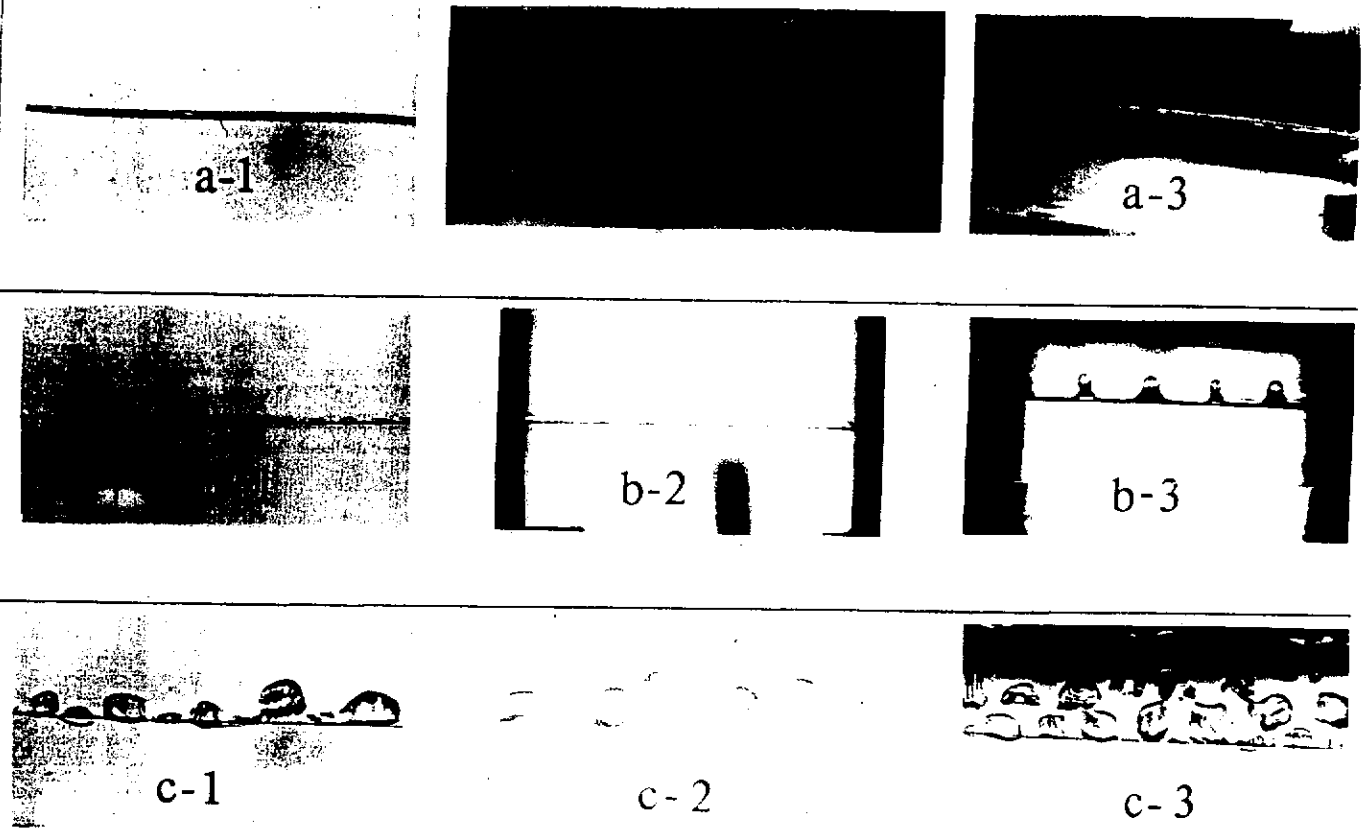
Fig. 5.43 : Flux limite q^* à la transition He II → vapeur en fonction de la profondeur d'immersion H_0 de la paroi chauffée par rapport à la surface libre du bain.

Critical Heat Flux in He II confined to a vertical channel (diameter: 10mm, length = 150mm)

19

Fakki Jehali JERBZ (PhD Thesis oct. 1991)
 b-Régime II
 a-Régime I

c-Régime III



FIL HORIZONTAL

(18)
 Fakki JEGALI JERRI
 Ph D Thesis Oct 28, 1991
 Univ. Paris VI (LTF → LIMSI/CNRS
 Lab6)

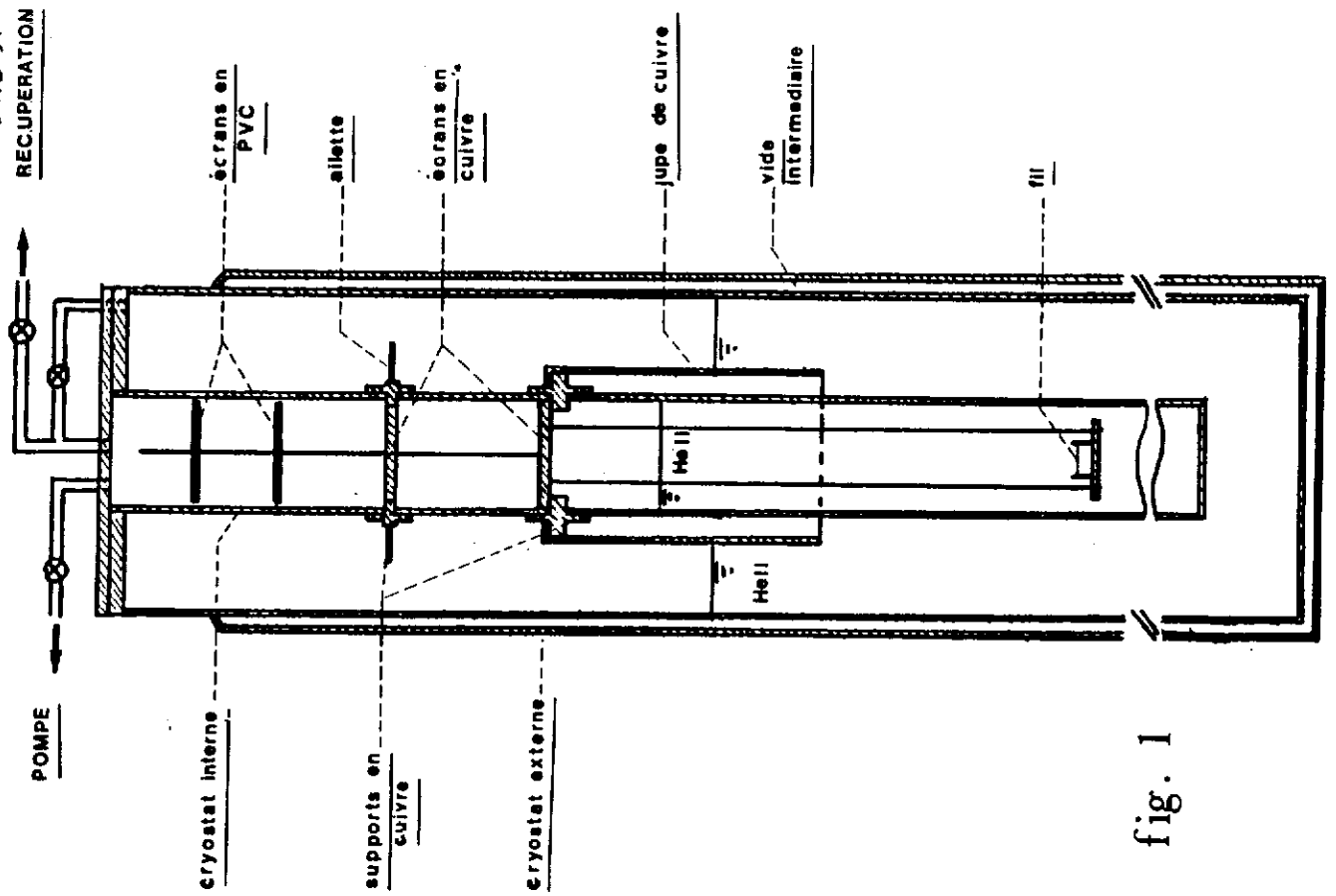


fig. 1

W.-D. Möller
29.2.96

Quench limitations vs. RRR

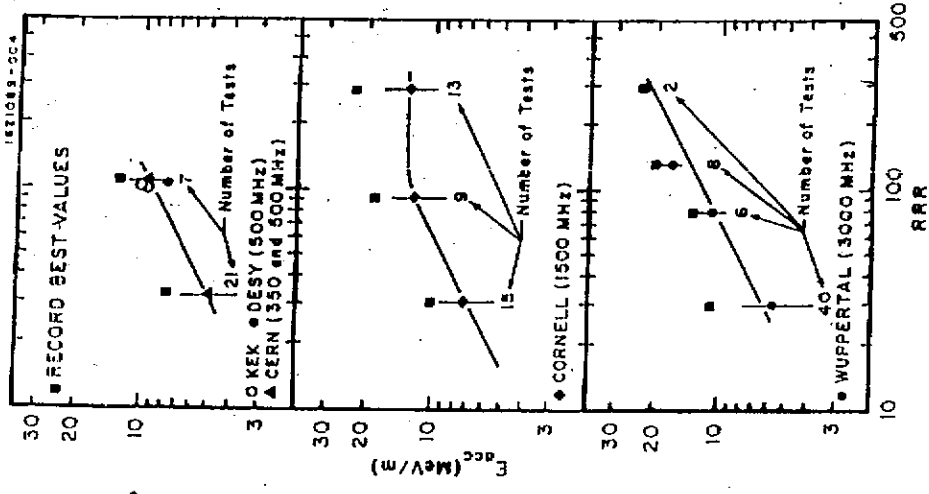
Measured Results

Does higher RRR lead to higher fields?

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②

Masan Ardounsee

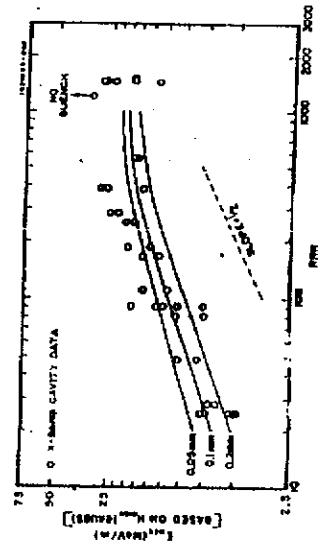


28 tests

37 tests

56 tests

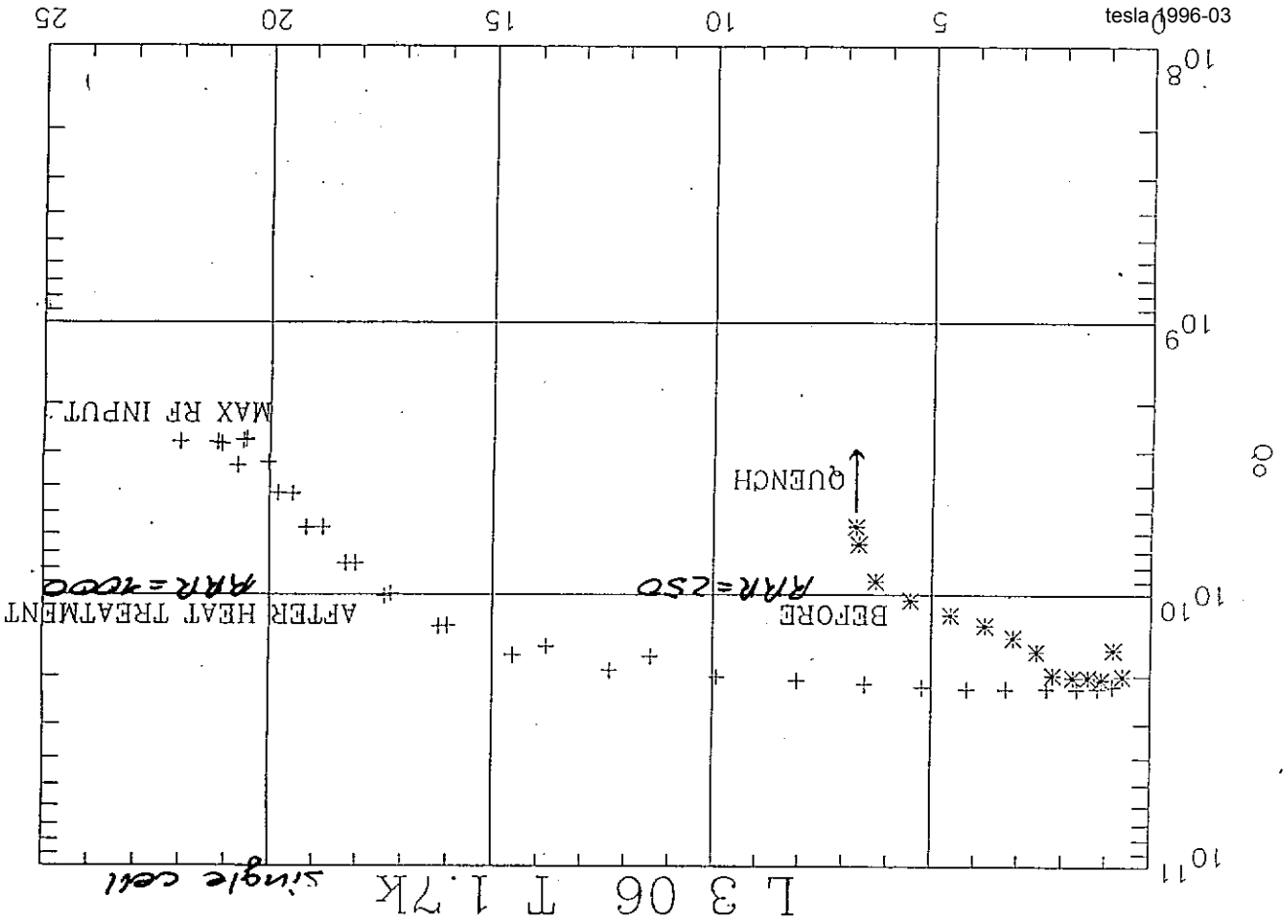
40 tests



tesla 1996-03

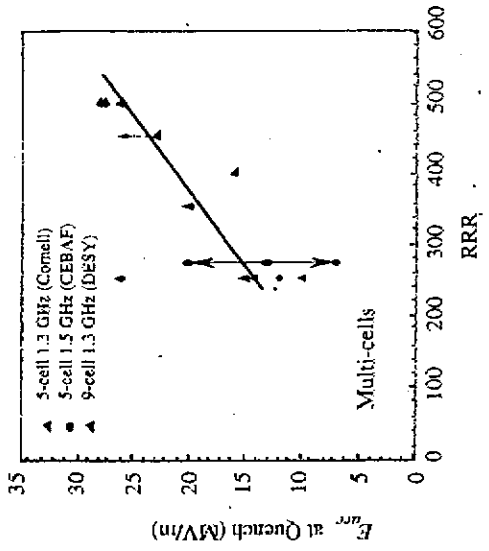
quench fields of 7-cell cavities

there is a correlation between



(4)

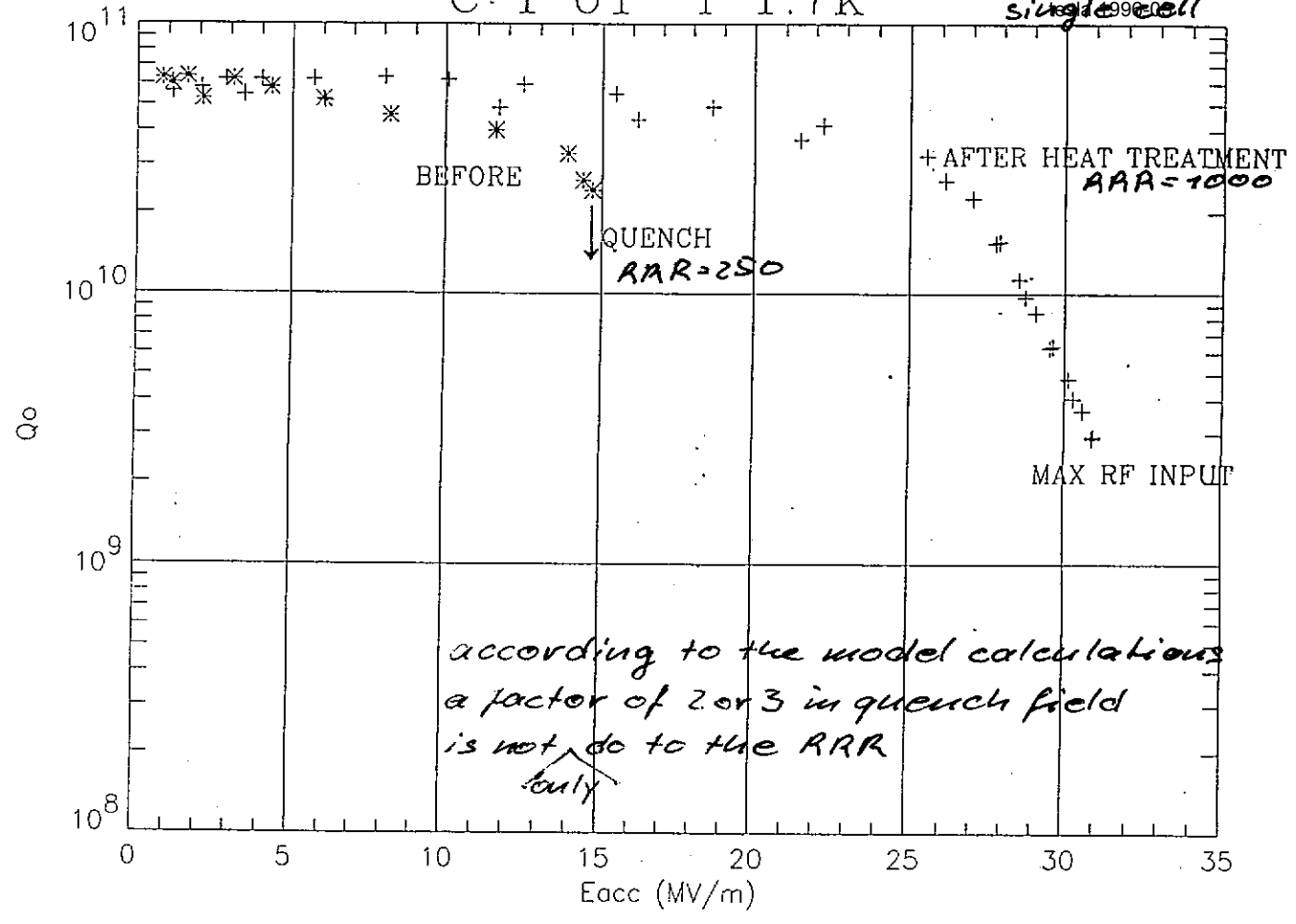
B. Bonin
1995



quench fields of multicell cavities

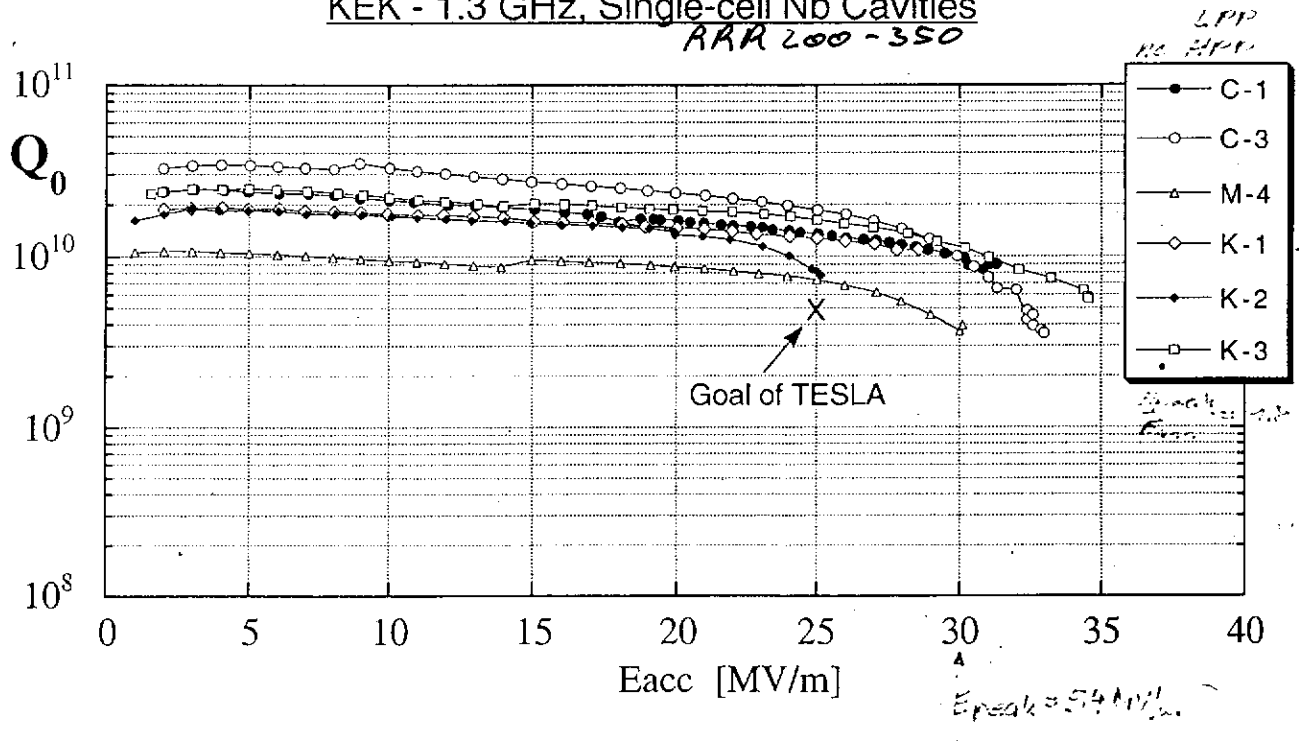
C-1 01 T 1.7k

single cell



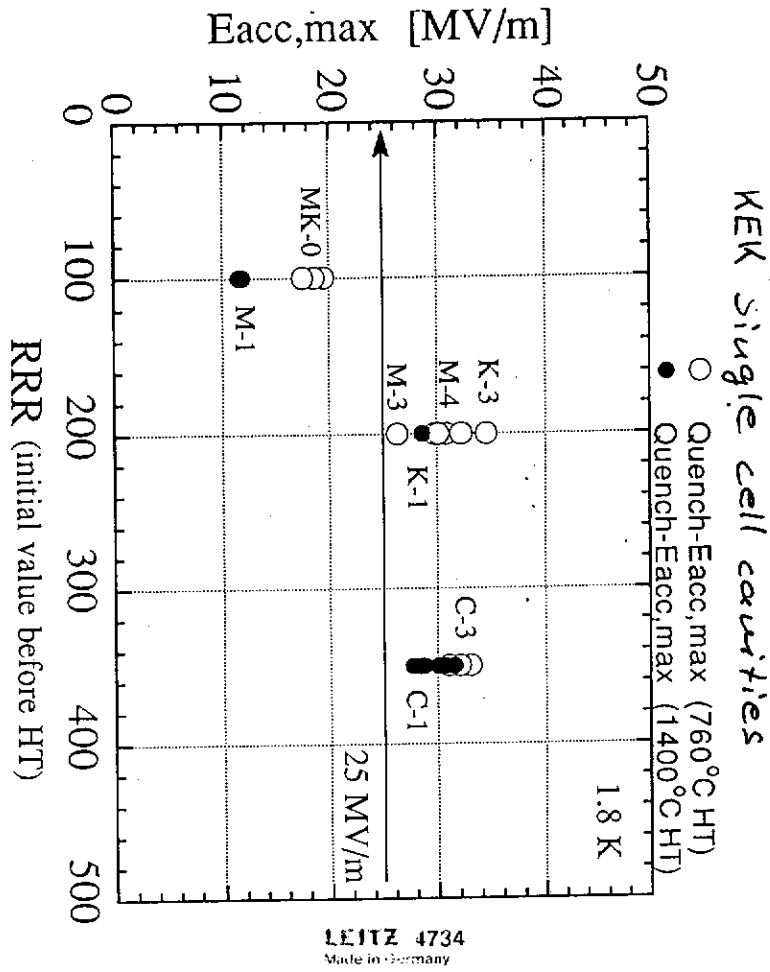
E. Kako
1995

KEK - 1.3 GHz, Single-cell Nb Cavities RRR 200 - 350



use relatively low RRR gives very high quench fields

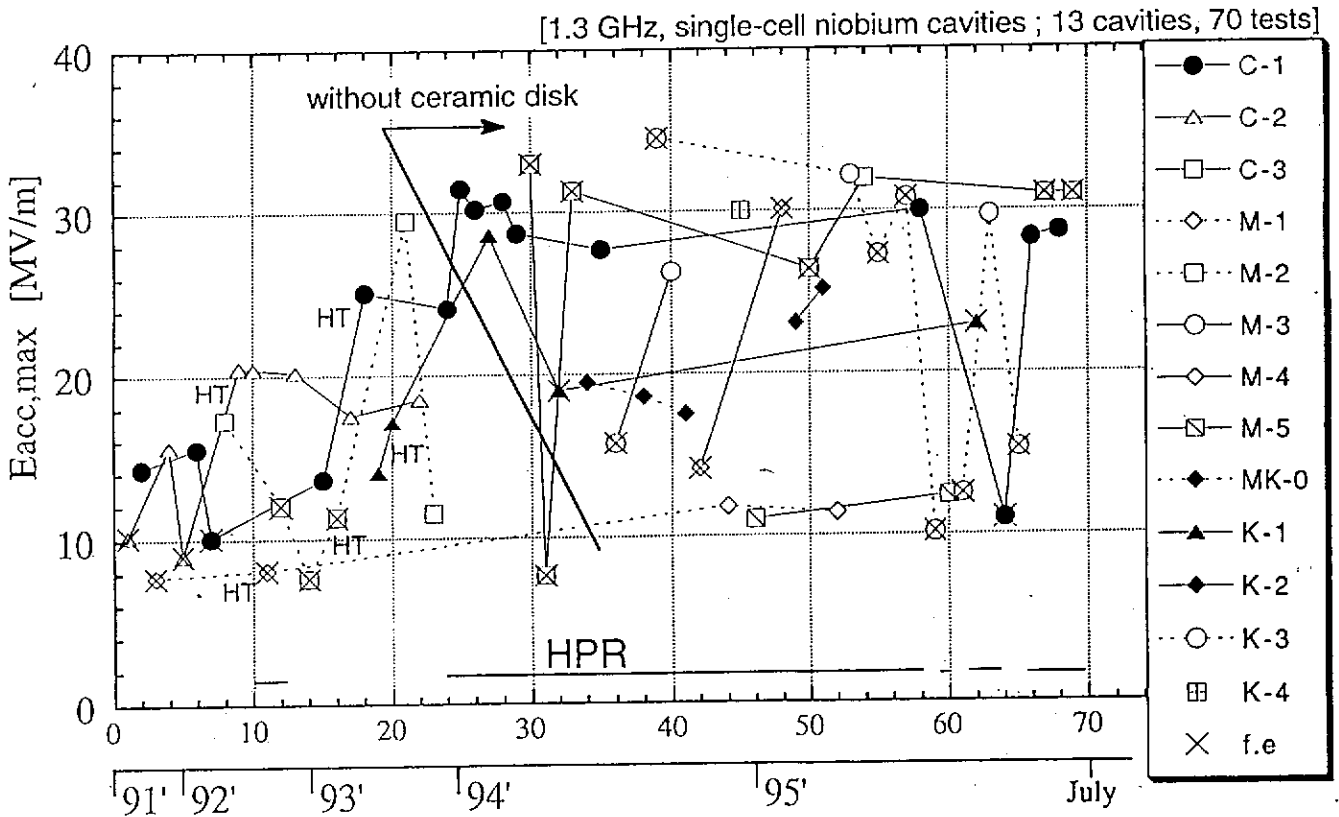
for RRR > 200 - no increase of field/unit



E. KAKO
1995

E. KAKO
1995

History of Cavity Tests



8

①

Summary

- ① there is a strong evidence for an improvement of quenchfield with RRR at least for RRR < 300 (multicells < 500)
- ② also low RRR cavities can show high fields > 30 MV/m
- ③ cavities made out of high RRR Russian Nb showed not a great field improvement (not enough data yet)
- ④ model calculations show:
 - big defects → big improvement by RRR
 - small defects → small

do to improved - Nb material

 - fabrication methodes
 - clean treatment,

we have smaller defects

→ less influence of RRR
- ⑤ Ti heat treatment improves RRR
 - + cures quench limitations by more than calculations can explain.
 - evidence for material homogenisation?

400

... im Medium v. ...
for TTF

W. Singer
DESY - MHF

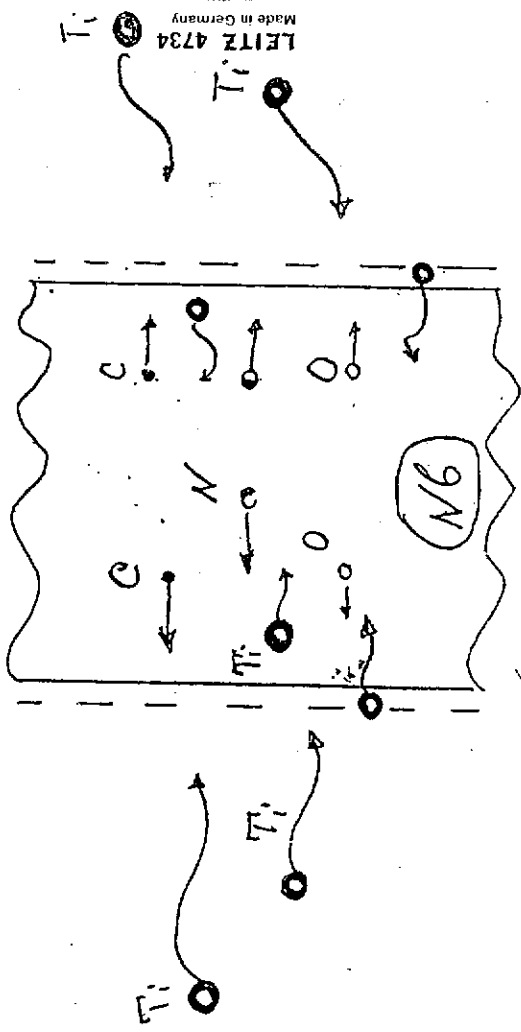


Fig. 1
Scheme of the Nb-refining by high temperature treatments

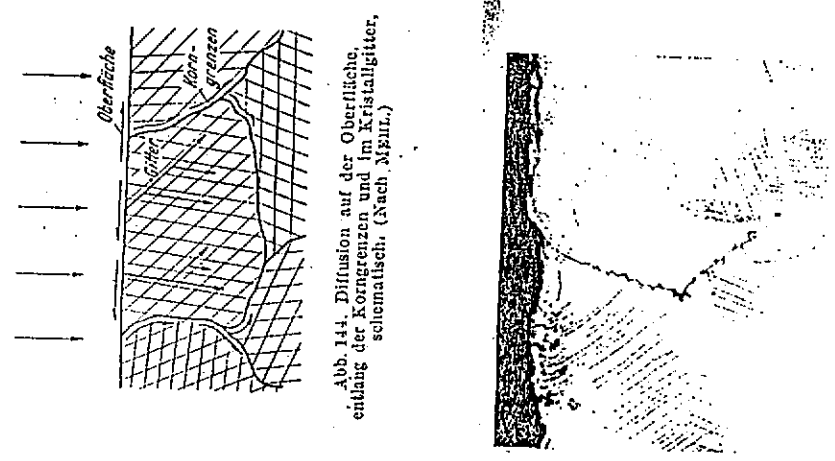


Abb. 144. Diffusion auf der Oberfläche, entlang der Korngrenzen und im Kristallgitter, schematisch. (Nach NEUR.)

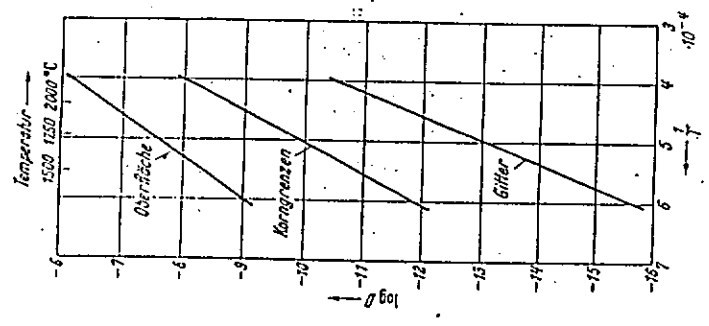


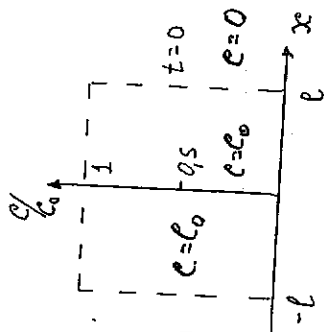
Abb. 145. Diffusion von Th in W.

Plane sheet

O, N, C in Nb

$$\frac{\partial c}{\partial t} = D \frac{\partial^2 c}{\partial x^2} \quad (1)$$

$$t=0 \begin{cases} c=0 & x < -l \\ c=0 & x > l \\ c=c_0 & -l \leq x \leq l \end{cases}$$



SO Solution

$$c/c_0 = \frac{4}{\sqrt{\pi}} \sum_{n=0}^{\infty} \frac{(-1)^n}{2n+1} \cdot e^{-\frac{D(2n+1)^2 \pi^2 t}{4l^2}} \cdot \cos \frac{(2n+1)\pi x}{2l} \quad (2)$$

$$M/M_0 = 1 - \sum_{n=0}^{\infty} \frac{8}{(2n+1)^2 \pi^2} \cdot e^{-\frac{D(2n+1)^2 \pi^2 t}{4l^2}} \quad (3)$$

sheet thickness: $2l = 2,8 \text{ mm}$

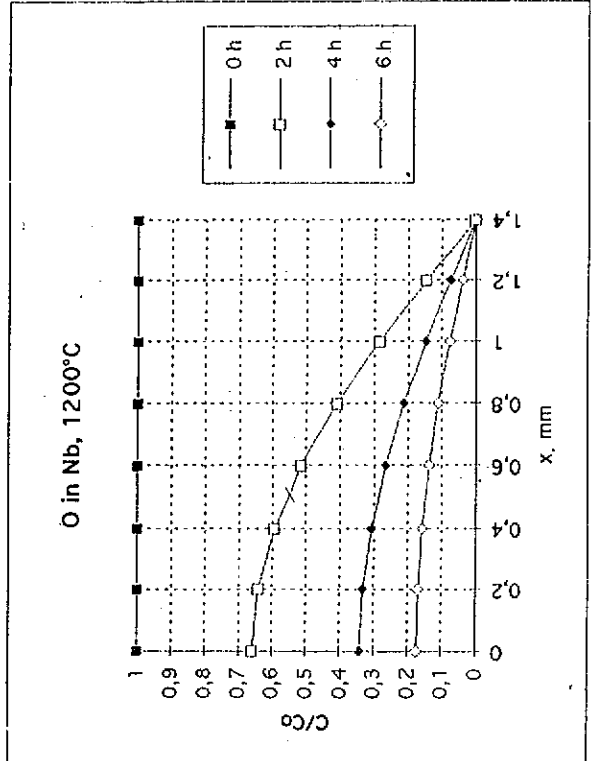
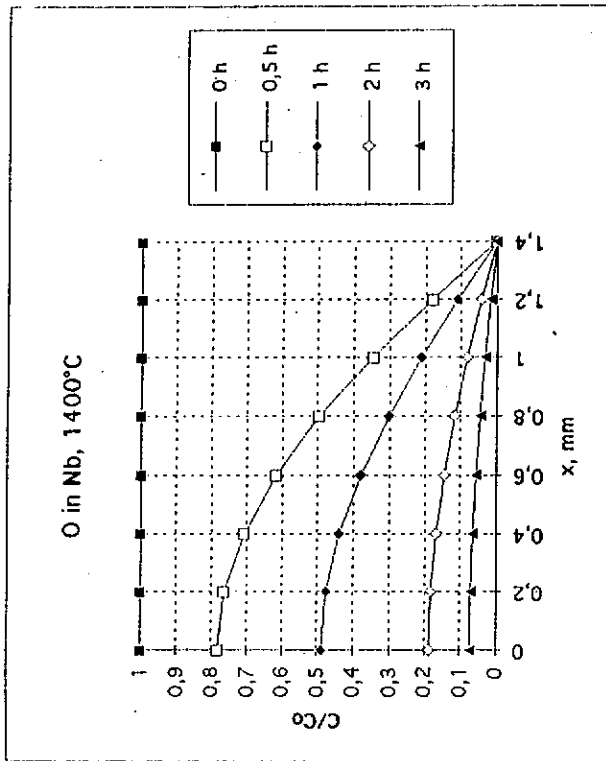
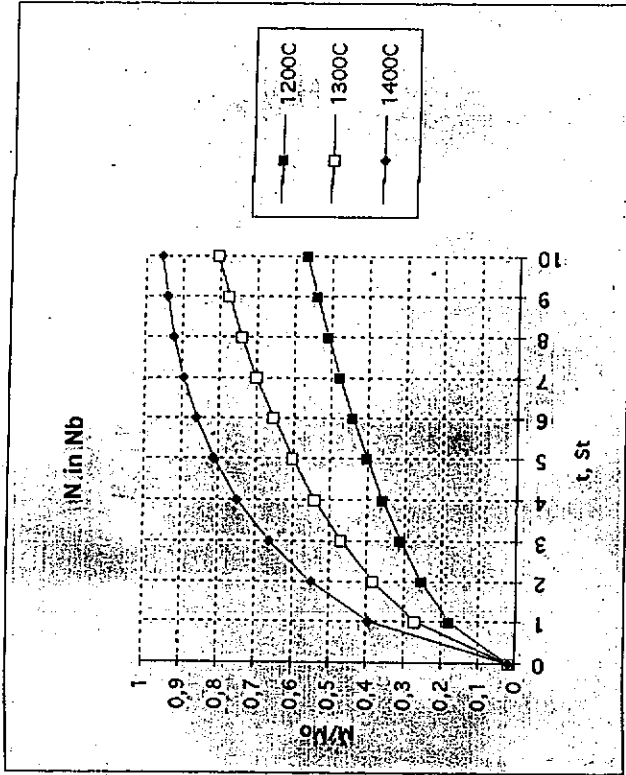
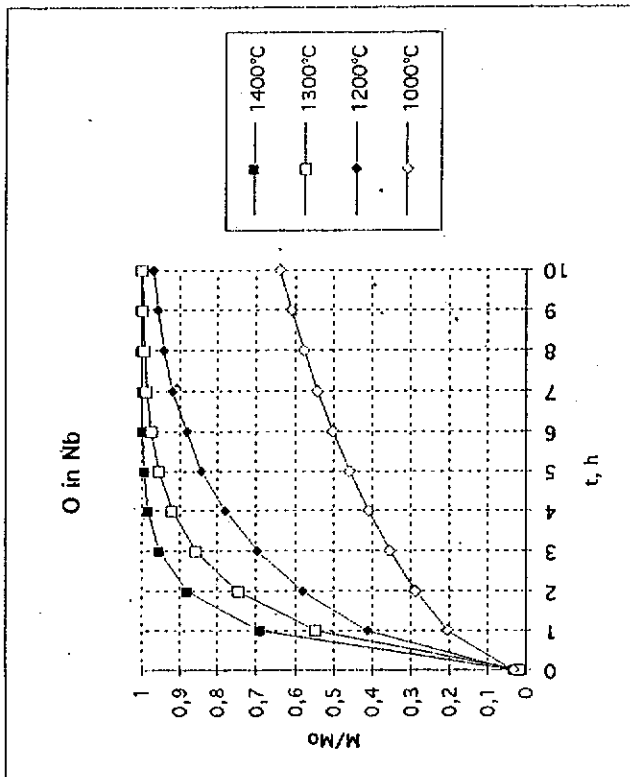


Fig. 2 The oxygen distribution in Nb sheet after refining

M, C (N in Nb)



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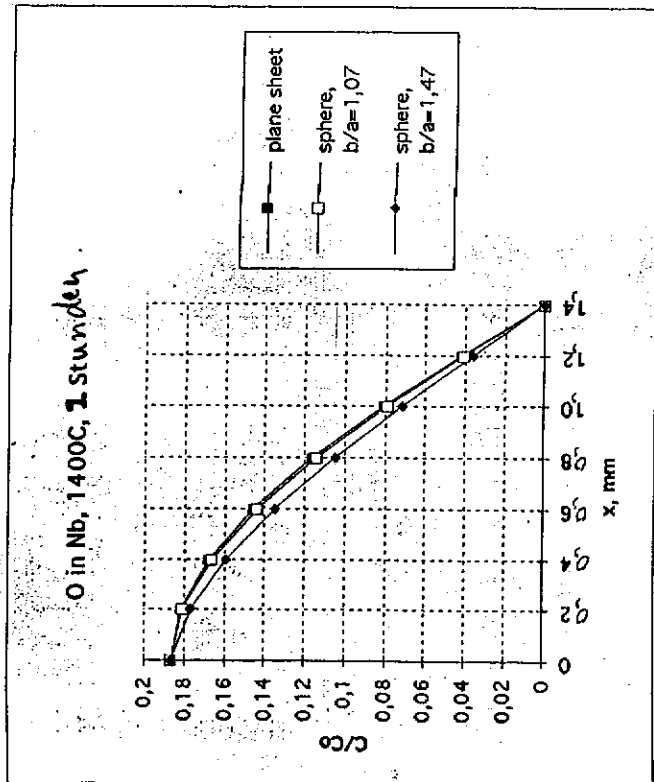


$$RRR = \int_0^{c_0} \frac{1}{c} \left[\int_0^c \frac{1}{c} \left(\frac{c_0}{c} + \frac{1}{\Delta c} \right) \left(\frac{\Delta c}{c} + \frac{1}{\Delta c} \right) \left(\frac{c_0}{c} + \frac{1}{\Delta c} \right) \right] dc$$

DESY Furnace				Cornell Furnace			
Before Solid State Getting				Before Solid State Getting			
sample with car. D3				sample with car. D3			
O, µg/g	N, µg/g	C, µg/g	RRR(cal.)	RRR(exp.)	O, µg/g	N, µg/g	C, µg/g
4	6	3	285	288	3	2	2
After Solid State Getting				After Solid State Getting			
0,08	1,8	0,9	750	525	0,6	0,6	0,6
1030	1070						

Calculation of RRR Increase by Solid State Getting

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52

M₂C (O in Nb)

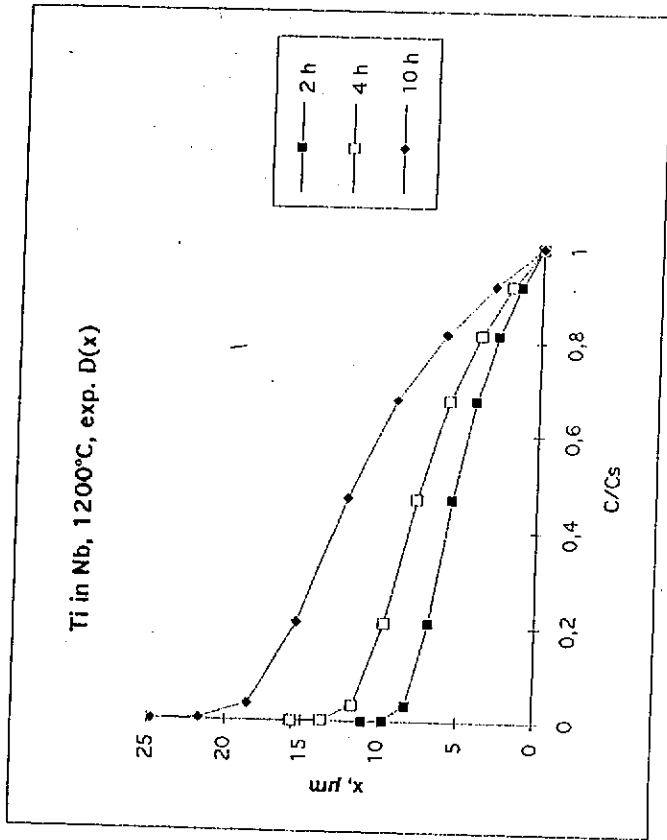


Fig 13-14 Penetration's depth of Ti in Nb

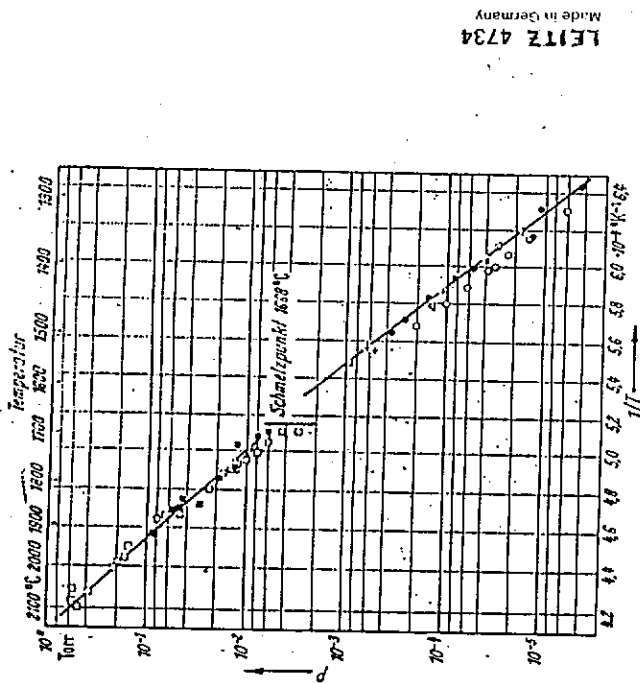


Abb. 1.22 Dampfdruck des Titans. Δ [B 48]; \pm [C 13]; \circ [E 1]; \bullet [S 14a]; \square [K 49a]; \blacksquare [K 49a].

Concentration dependent diffusion

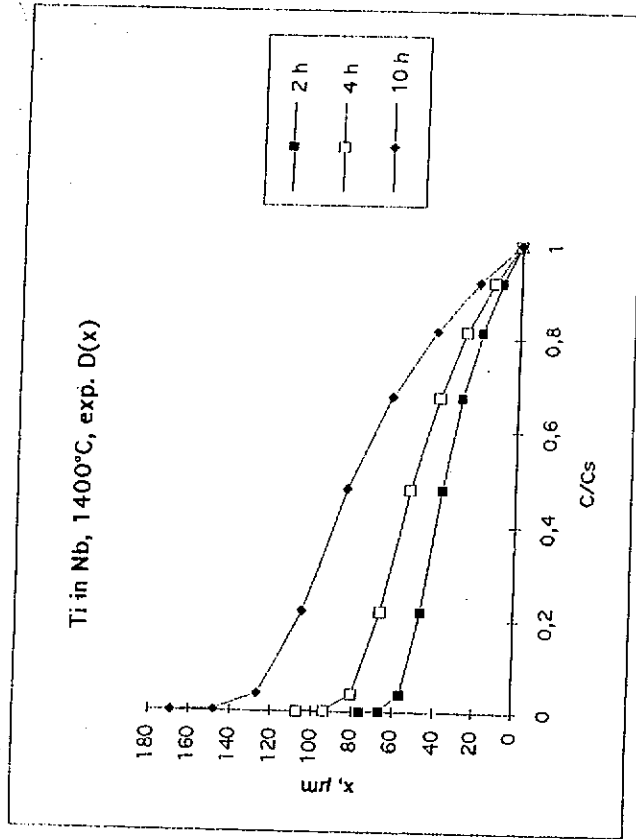
$$D = D(x)$$

$$\frac{\partial c}{\partial t} = \frac{\partial}{\partial x} \left(D \frac{\partial c}{\partial x} \right)$$

$$\begin{cases} c = c_s, & x = 0, t > 0 \\ c = 0, & x > 0, t = 0 \end{cases}$$

$$D = D_0 e^{\beta(c-c_0)} ; \exp D(x)$$

Numerical solution



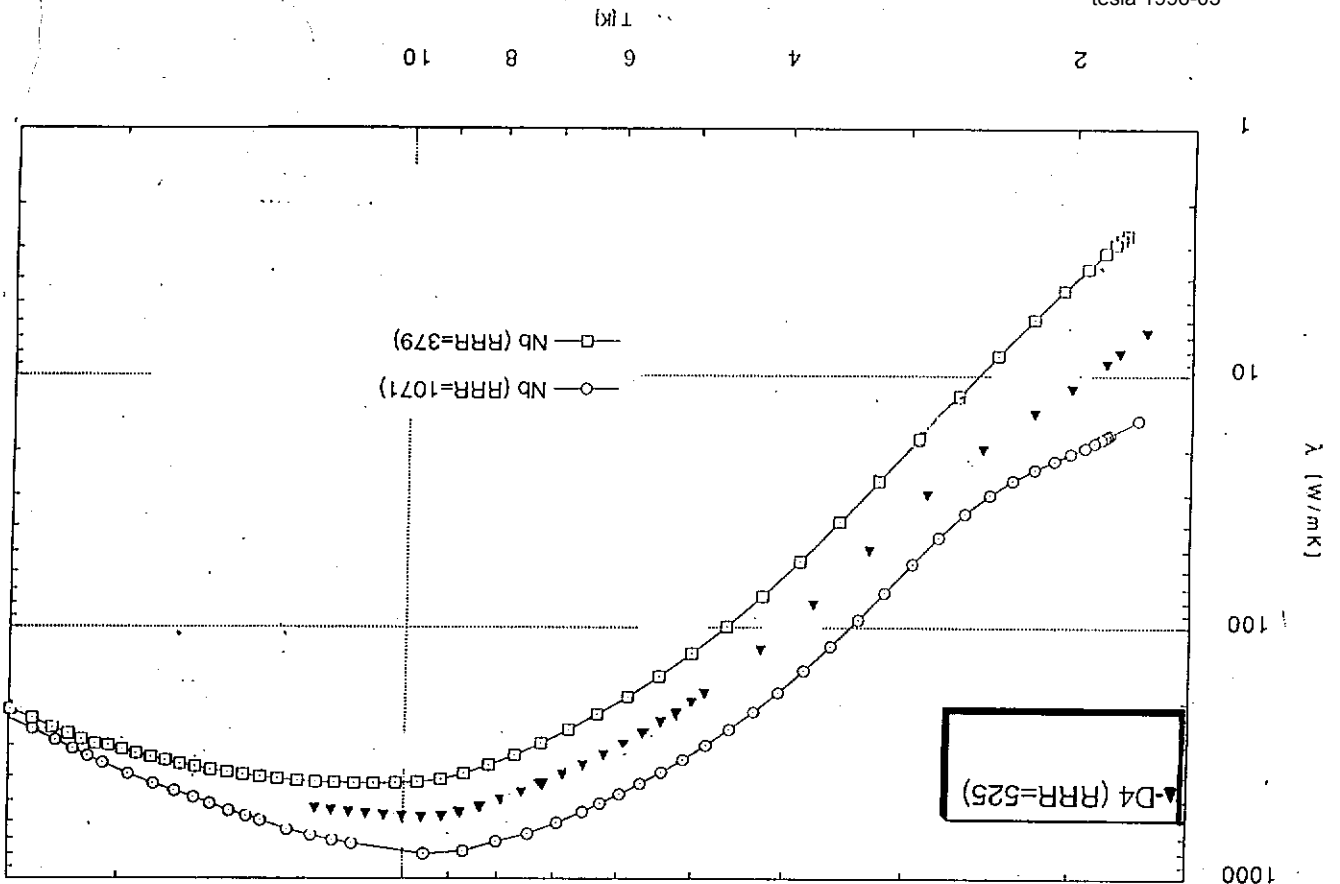
Cavities - Titanisation (DESY Furnace)

Sample	Note	RRR(dc,samp.)	RRR(ec,cav.)	treatment	tot. time
Nb	Ref. for P2, D2, D4, D6	265		as receiv.	
Nb -2Ti/1	Cav. P2	388		1400°C, 4St, Ti	30 h
Nb -2Ti/2	Cav. P2	384		1400°C, 4St, Ti	30 h
Nb 23/95/1	Cav. D2	348		1400°C, 4St, Ti	82 h
Nb 27/95/2	Cav. D4	525		1400°C, 4St, Ti	cycle
Nb 37/95/1	Cav. D6	521		1400°C, 4St, Ti	cycle
Nb 37/95/2	Cav. D6	534		1400°C, 4St, Ti	cycle
Nb	Ref. for D3	288		as received	
D3-II	Cav. D3	529 (520)		1400°C, 4St, Ti	cycle
Nb	Ref. for D1	281		as received	
Nb	Ref. for D5	289		as received	
Nb 61/95	Cav. D1	535 (521)	575±50	1400°C, 4St, Ti	cycle
	Cav. D5		200±20	without Ti treatment	
Nb 3/96	Cav. D5 (middle)	494		1400°C, 1St; 1250°C, 3St	
Nb 2/96	Cav. D5 (top)	498		1400°C, 1St; 1250°C, 3St	

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T. Schickler

thermal conductivity of niobium



Cavities - Titanisation (DESY Furnace)

Sample	Note	RRR(dc)	treatment
Nb 1/96	sample (top)	464	HT* - 1400°C, 1h; 1250°C, 3h
Nb 4/96	sample (bottom)	524	HT* - 1400°C, 1h; 1250°C, 3h
Nb 2/96	Cav. D5 (top)	500	HT* - 1400°C, 1h; 1250°C, 3h
Nb 3/96	Cav. D5 (middle)	494	HT* - 1400°C, 1h; 1250°C, 3h

Kennzeichnung der Nb Proben

Numer	RRR	see	RRR	see	Behandlung	Komments	Gr-t	Herst
0/0	300		114		1400 C 4 h ohne Zusatz Grundzustand des Ofens Leasen	Vorbereitung des Ofens T=1200-1410 C Zeit 4h	27.1 HNH 10.2 Singer	Herst 4.2 HNH 10.2 Singer
2/1	300		392.5		Referenz zu 2/2 RRR Messung	Probe RRR geprüft		
2/2	300		236		1400 C 2 h mit Restei Zeichnung Master in	Vorbereitung Entfalten 10 zu 200°C T= 1400-1410 C Zeit 4 h	27.1 HNH 23.2 Markstedt	
3/0	300		282		as delivered by Haegeue Grundpotential für 4.0 ff	Grprüft aus Probe 3.0	10.3 Singer	
4/	300		530 (546)		Ti Behandlung mit 0.2mm Blech Aufbau wie in Ofen DESY Einsatz	Vorbereit. wie Probe 1 T = 1400 C Zeit 4 h		
5/	300		374		Ti Behandlung mit 0.2 mm Blech Aufbau wie in Ofen DESY Einsatz	Vorbereitung wie Probe 1 T = 1300 C Zeit 2h		LEITZ 4734 Made in Germany
6/	300		293		Ti Behandlung mit 0.2 mm Blech Aufbau wie in Ofen	Vorbereitung wie Probe 1 T = 1100 C Zeit 6 h		
7/	300		661		— " — " —	T=1400°C, 4h		
8/	300		(343) 345		— " — " —	T=1300°C, 4h		
9/	300		523		— " — " —	T=1400°C, 4h		
10/								
11/								
12/								
13/								

Conclusions

1. The solid state gettering in the DESY furnace increase the RRR of Nb300 to $RRR_{exp} > 500$, nevertheless $RRR_{exp} < RRR_{calc}$ ($RRR_{calc} \approx 750$)
2. Decreasing of the purification temperature to 1200-1300°C is not limited by the diffusion of the interstitial impurities
3. The purification at temperatures below 1200°C reduces the penetration depth of Ti in Nb significant but it is limited by Ti vapor pressure
4. Solid state gettering procedure which contains:
 - a) creating of sufficient Ti vapor pressure in initial stage of purification (for example 1400°C, 1h)
 - b) purification at reduced temperatures (for example 1250°C, 3h)can be promising

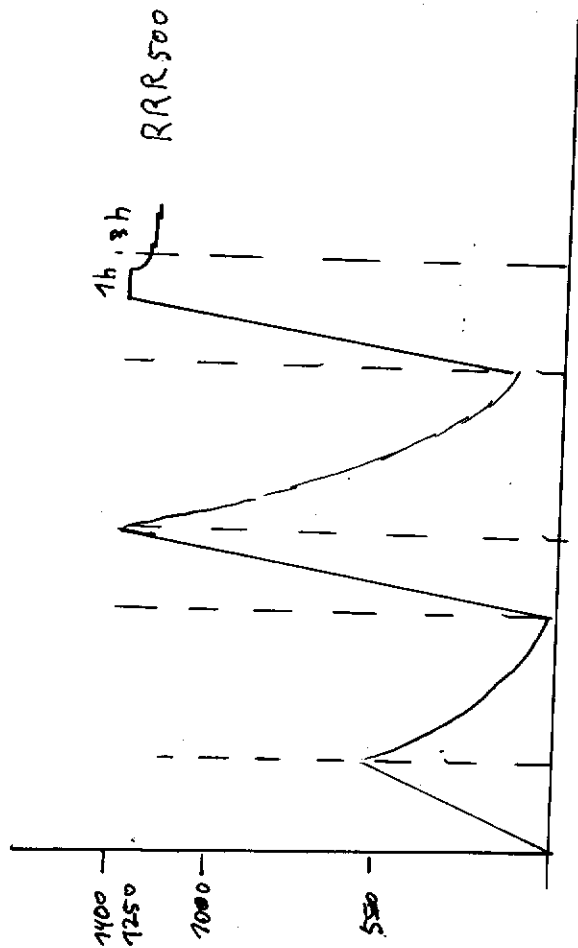
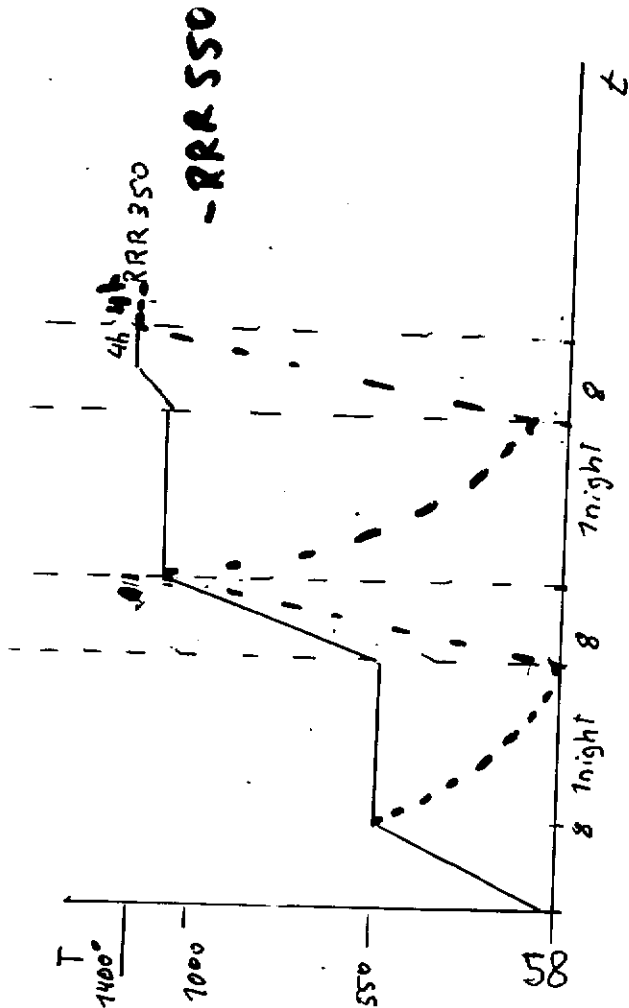
Ti treatment

- pre-cleaning of furnace + Ti carrier
- two side Titanification
- control of masses (mass spectrum)
- control of total pressure
- control of temperature (heater + infrared on cavity)

temperature gradient \uparrow $^{\circ}$ /min

0.1kg but + man pour
from PVAC

Ti postpurification at DESY
start from RRR 250 - 280



Time and stop depending on total vacuum pressure!!

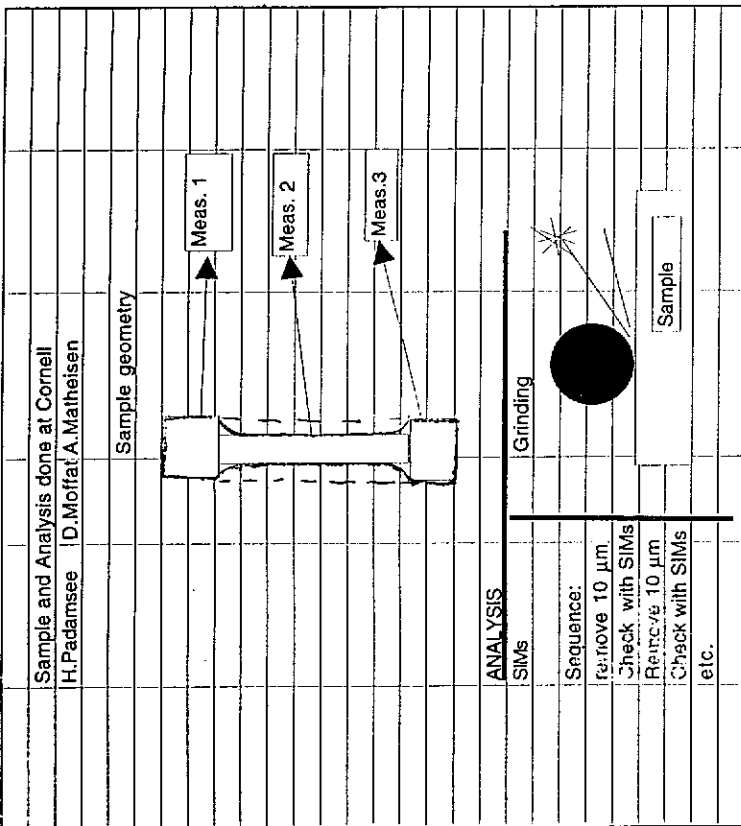
Plot 5.10.6

Sample No	Ti concent >10%	Ti local >1%	Ti concent <1%
1	<50µm	50-80	>=90
2	<40 µm	50-70	>=70
3	<50µm	50-75	>=80
4	<40	40-60	>=70
5	<40	40-65	>=70
6	<50	50-70	>=80
7	long	30-50	>=60
8	long	30-50	>=60
9	long	30-50	>=60
10	long	40-60	>=70
11	<50	50-70	>=80
12	<40	40-60	>=80
13	<50	50-80	>=90

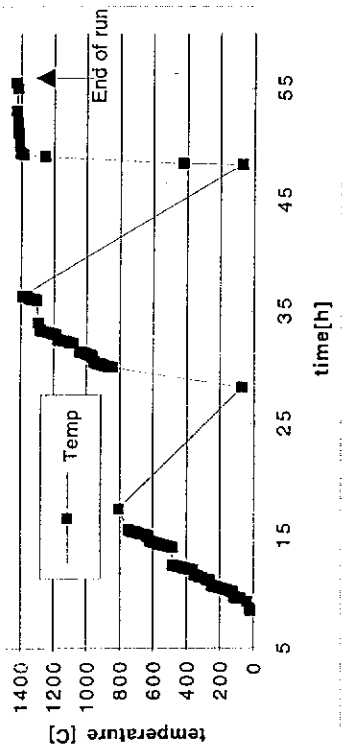
Numbers are averages out of the 3 measurement points on each sample

Results of Samples

FRR 1000



saclay 1.3 Ghz Temperature-Time



Untersuchungsbericht

Nr. 95/0225
Blatt 3/6
Datum: 09.02.95



Bearbeiter: Hengst/Dietrich

Untersuchungsbericht

Nr. 95/0225a
Blatt 1
Datum: 09.02.95

Messung und Darstellung der Titan-Schichtdicke an Niob-Probe nach Vorgabe
Auftraggeber: Deutsches Elektronen-Synchrotron DESY
Auftrags-Nr. 004966/H.36.051.1/673/MKV

Werk-Nr. 2 720 899

Probe D4 (27/95/1) am 22.03.95 durch Herrn Hubert übergeben.

Ergebnis:

Mikrogefügeschliff mit Darstellung der titanisierten Randzone, Vergrößerung 500 : 1:



Abb. 1

Probe-Nr.: 1

Nb-Blech,
nicht titanisiert

100 : 1
II/ 21 509

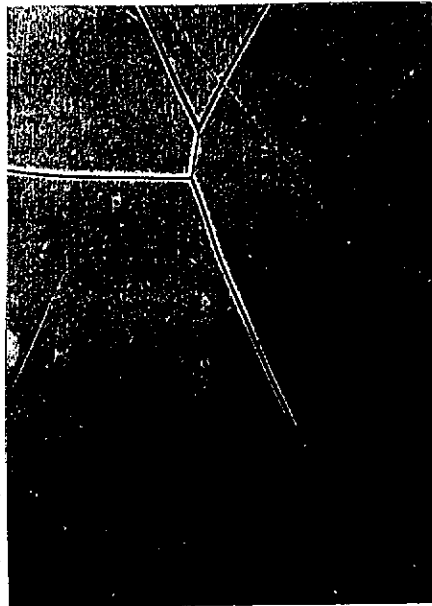


Abb. 2

Probe-Nr.: 2

Nb-Blech,
titanisiert
1400 °C/4h

100 : 1
II/ 21 510

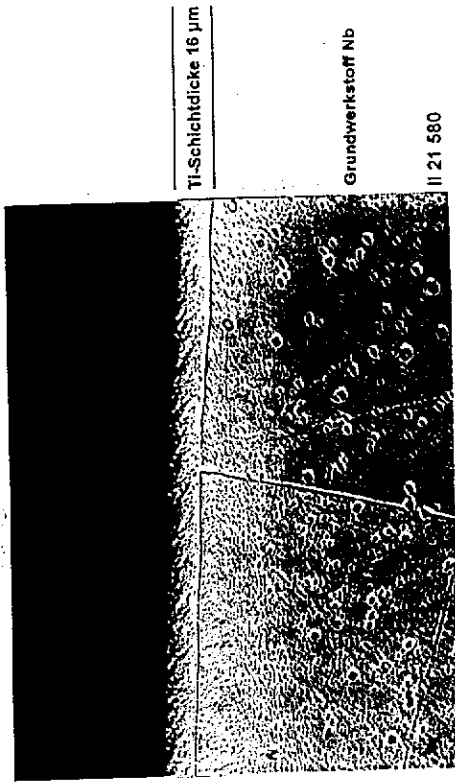
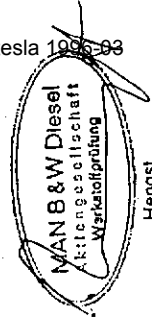


Abb.: 1

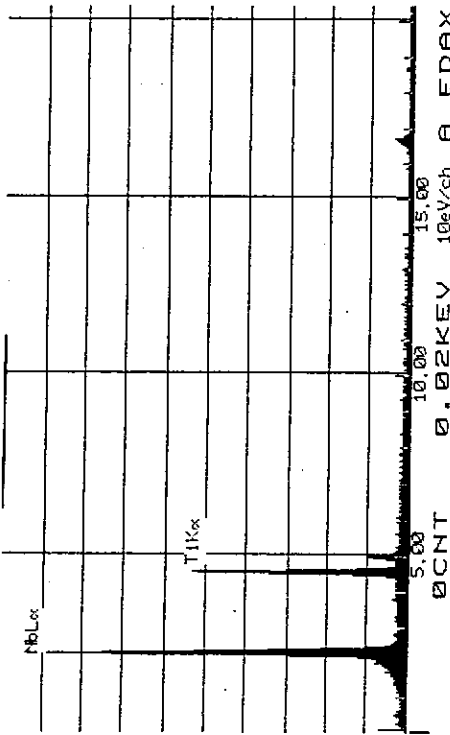
Vert.:
DESY
MBD/SRQ

tesla 1996-93



Hengst

28-MAR-95 16:49:20 EDAX READY
 RATE= 1124CPS TIME= 49LSEC
 FS= 169BCNT PRST= OFF
 A = 24795 DIAG. 1



Nr. 95/0225a
 Blatt 2
 Datum: 03.04.95

Untersuchungsbericht

Bearbeiter: Hengst/Dietrich

Messung und Darstellung der Titan-Schichtdicke
 an Niob-Probe nach Vorgabe

Nachtrag REM-Untersuchung:

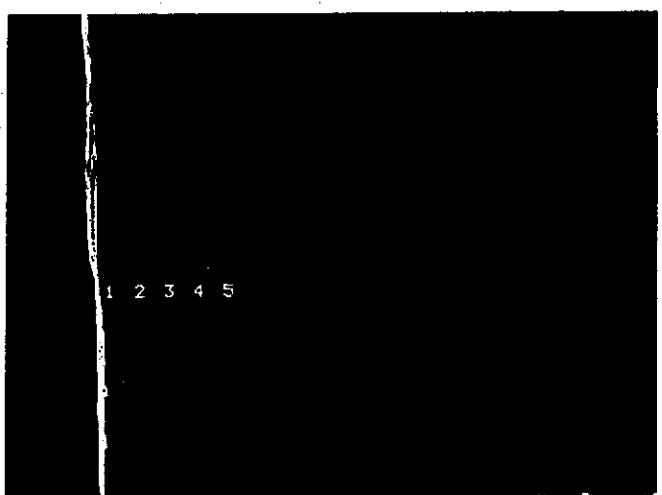
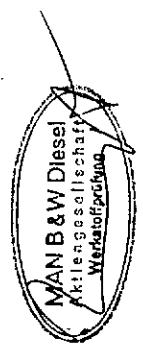
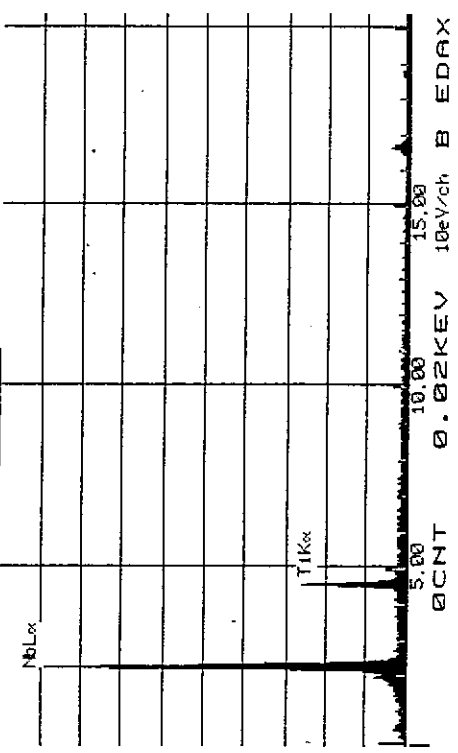


Abbildung der Ti-Schicht mittels Raster-Elektronenmikroskop (ca. 1300 : 1) mit den Maßpunkten der Spotanalysen, dargestellt in den nachfolgenden Diagrammen 1 - 5, Seite 3 - 7.
 Ein Ti-Nachweis unterhalb der optisch sichtbaren Schicht ist nicht gegeben.

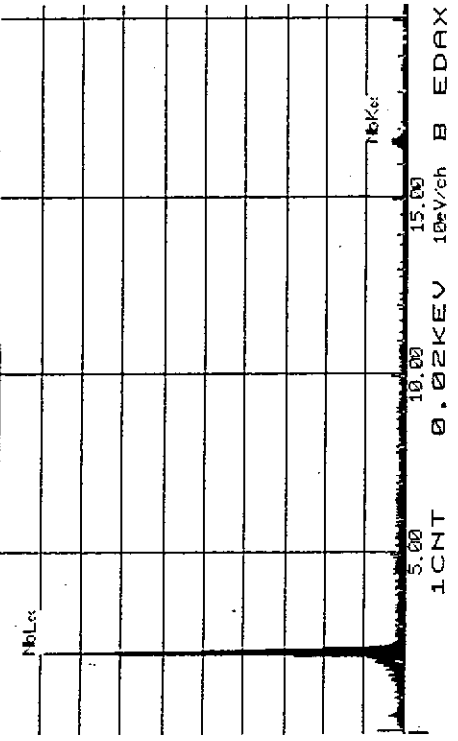


28-MAR-95 18:00:31 EDAX READY
RATE= 1170CPS TIME= 49LSEC
FS= 2028CNT PRST= OFF
B =24795 Diag.4



62

28-MAR-95 18:07:30 EDAX READY
RATE= 1030CPS TIME= 49LSEC
FS= 1328CNT PRST= OFF
B =24795 Diag.5



Untersuchungsbericht

Nr. 95/0225
Blatt 5/6
Datum: 09.02.95

comparison of Analysis
Methode
grinding
SIMs
EDX (EMA)
L-SYRF

for 4 h at 1400 C
heating, step heating

Probe: 40-80 µm
70-<90 µm
0-3 µm
80 µm

← Ti-Schicht
← "Schlagschatten"

← Grundgestübe

Titan-Schichtdicke 4 µm

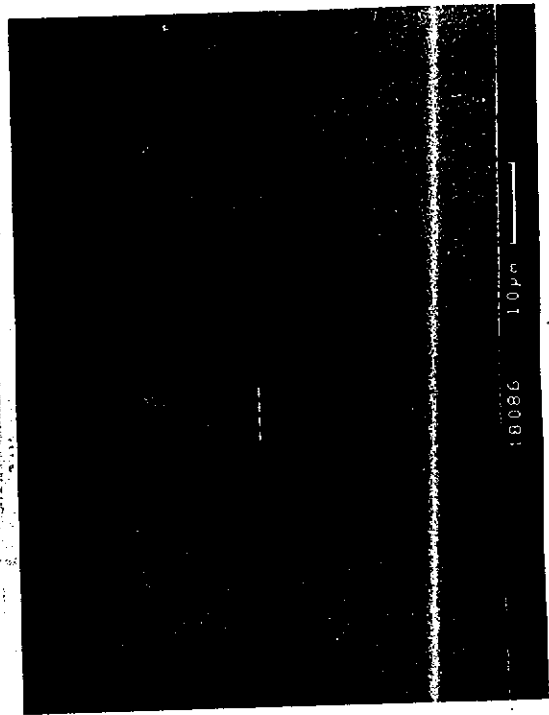
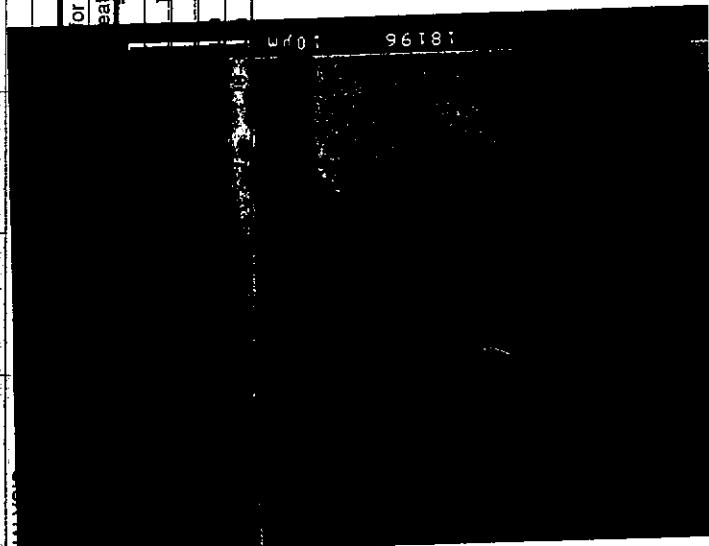


Abb. 7

Probe-Nr.: 3

Titan-Schichtdicke
ca. 5 µm

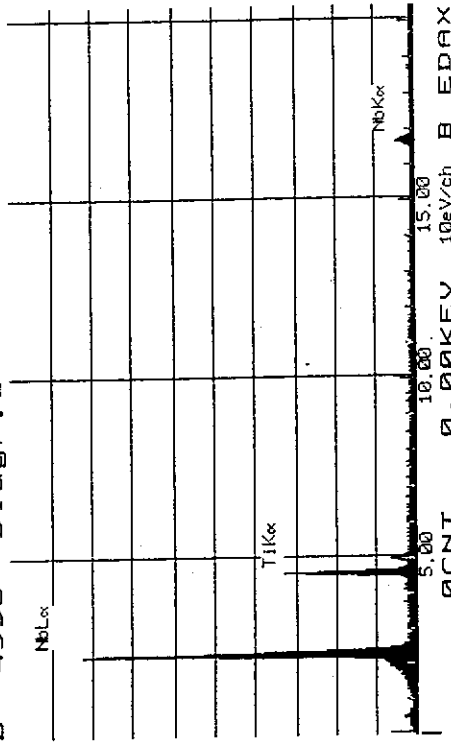
Untersuchungsbericht

Nr. 95/0225
Blatt 6/6
Datum: 09.02.95

Abb. 9

Elektronenstrahl-Mikroanalyse der titanisierten Oberfläche
(Probe 2)

18-JAN-95 11:09:59 EDAX READY
RATE= 747CPS TIME= 84LSEC
FS= 1762CNT PRST= OFF
B=4995 Diagr. 1

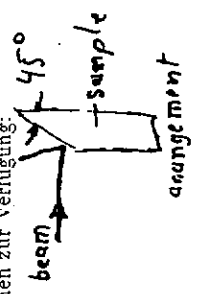


Analyse von Titan in Nioblech

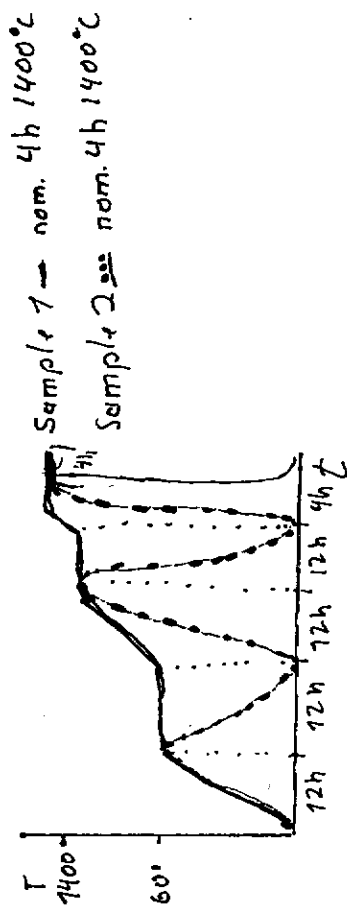
Im nachfolgenden Experiment wurde die Diffusion von Titan in Niob hinein untersucht.

Der Meßplatz für hochauflösende Röntgenfluoreszenzanalyse (μ -SYXRF) am Hasylab wurde am Ablenk magnetenstrahl L aufgebaut. Die weiße Strahlung wird durch eine Glaskapillare von $10\mu\text{m}$ Innendurchmesser kollimiert. Damit stehen folgende experimentellen Konditionen zur Verfügung:

- Anregungsspektrum: $\delta - 100\text{keV}$
- Strahlquerschnitt: kreisförmig $10\mu\text{m}$
- Ortsauflösung: besser als $10\mu\text{m}$
- Detektionssystem: HPGe der Firma DSG, Mainz (155 eV nominal)
- Nachweisempfindlichkeit für Titan: besser als 1%



Die Probe, welche schnell erhitzt wurde, wurde entlang der Schichtstruktur geschliffen und mit einer Rauhigkeit von weniger als $1\mu\text{m}$ poliert. Die andere Probe wurde nur gesägt und besitzt daher eine wesentlich rauhere Oberfläche. Während der Messungen steht die Probe unter 45° zum Strahl, damit der Detektor in der rechtwinkligen Geometrie wenig Streustrahlung bekommt.



heattreatment on samples
to qualifie furnace

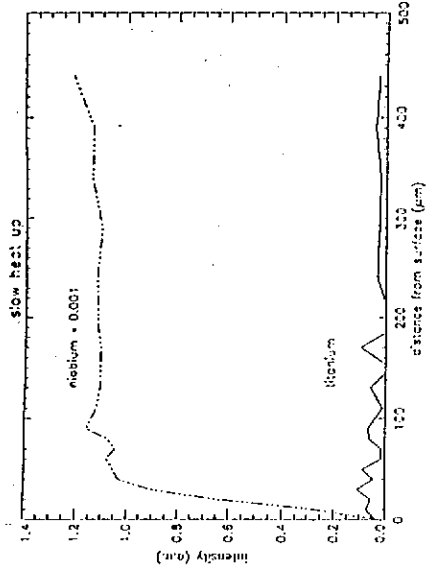


Abbildung 1:

Die Abb. 1 zeigt die Verteilung von Titan und Niob in der Probe. In den obersten $100\mu\text{m}$ erreicht das Titansignal wahrscheinlich gerade nicht aus, um mit drei Sigma Sicherheit (95%) nachgewiesen werden zu können. In tieferen Schichten ist der Rauschpegel zu hoch, um Titan nachweisen zu können.

$Ti < 95\%$ of Sigma probability

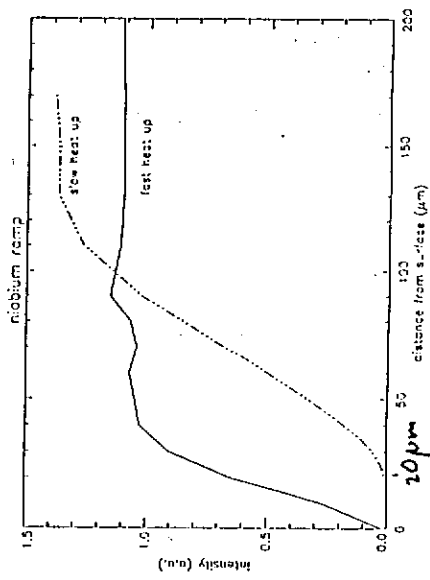


Abbildung 3:

Die Abb. 3 zeigt die beiden Niobsignale im Vergleich. Die Probe mit der langen Aufheizzeit zeigt eine Flanke von etwa $20\mu\text{m}$. Aus dem Strahlquerschnitt und einer in diesem Fall rauheren Oberfläche kann diese Anstiegsflanke leicht erklärt werden. Im Falle schneller Aufheizung hat die Flanke etwa $80\mu\text{m}$ Breite. Dieses Ergebnis ist völlig konform mit der gemessenen Titanschichtdicke von $70\mu\text{m}$.

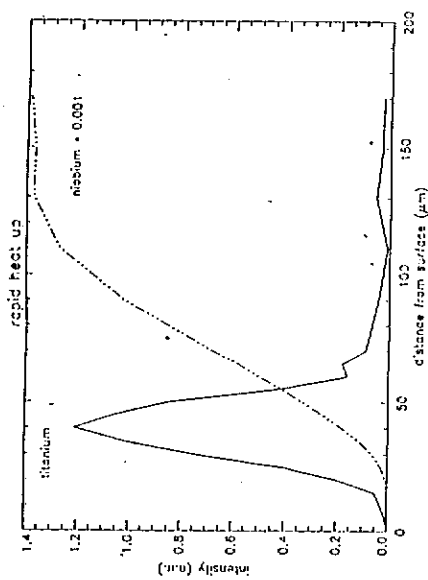


Abbildung 2:

Die Abb. 2 zeigt die Verteilung von Titan in Niob. Die oberste Schicht besteht aus nahezu reinem Titan. Die Titankonzentration nimmt mit zunehmender Schichttiefe ab und zeigt den typischen Verlauf eines Diffusionsprofils mit Poissonantiling. Das Niobsignal steigt erst langsam mit zunehmender Tiefe an.

Creep in TTF Resonators

H. Kaiser

1.3.96

- creep measurements
on 1-D samples

66

- creep of sag of
resonators

- problems due to
low strength of fired
niobium

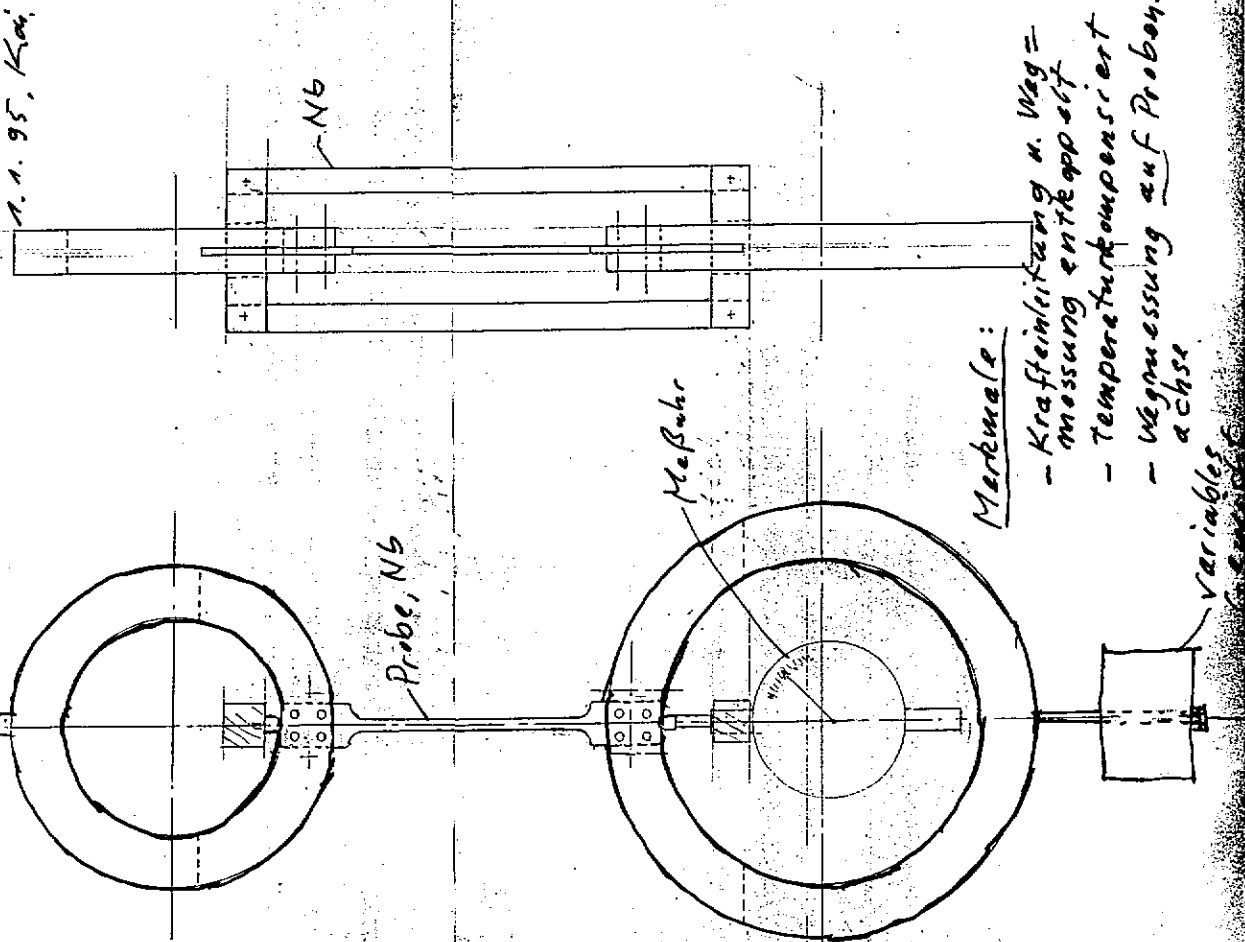
"Creep" is slow plastic
deformation from
prolonged exposure
to stress.

$$\text{creep} = \epsilon(\sigma, t)$$

method: \uparrow change in steps,

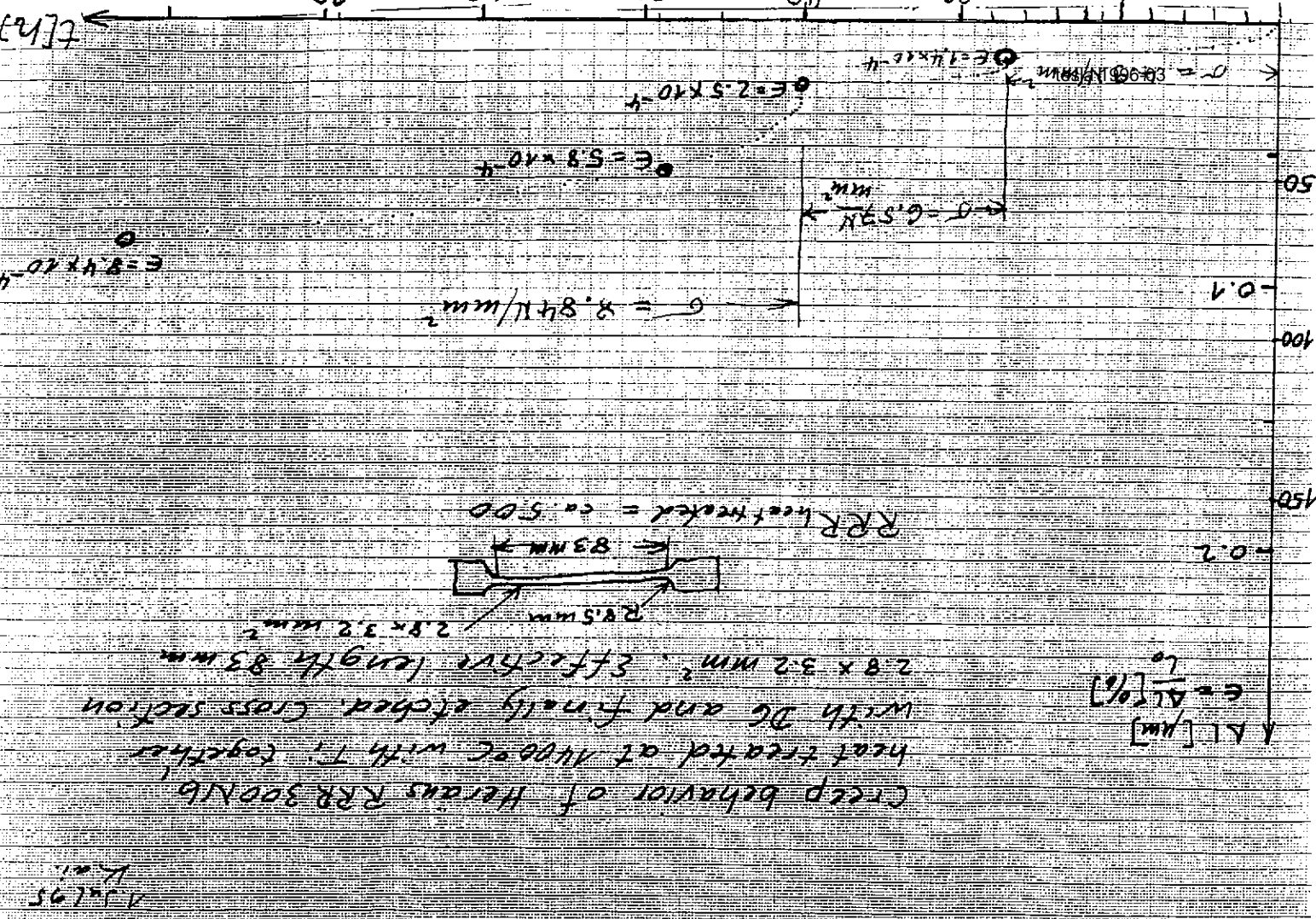
then wait for plastic
strain to occur

Meßvorrichtung, Kriechversuch
 1.1.95, Kai



Merkmale:

- Kraftmessung u. Wegmessung entkoppelt
- Temperaturkompensiert
- Wegmessung auf Probenachse

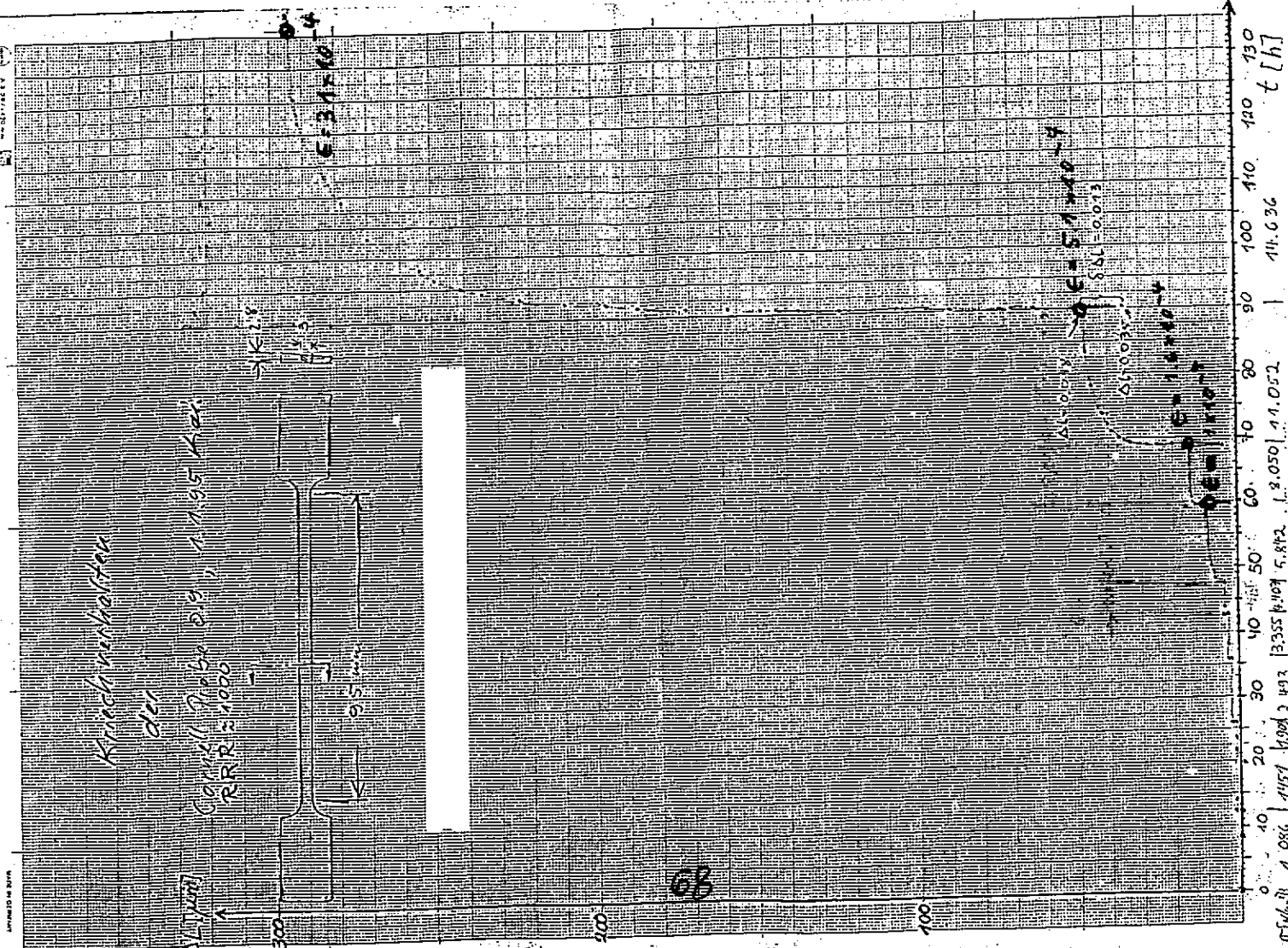


1.1.93 17.00

Problems due to low strength of Nb

- cavity shows plastic sagging
- needs for main coupler need a brace
- cavity flanges of cavity are deformed (up to 0.2 mm) by "Helicoflex" metal gaskets. \rightarrow frequent leaks
- handling of fired cavity can lead to deformation
- operation of tuner not fool-proof: Warming up fully compressed cavity will bend it.

tesla 1996-03



21.8.95 K_{res}

Max Spannung im
TTF-Resonator

Resonator im He Tank:

~~σ_{max} = 9.93 N/mm²~~
 $\sigma_{max} = 9.93 \text{ N/mm}^2$

Resonator an Endflanschen unterstützt:

~~σ_{max} = 14.2 N/mm²~~
 $\sigma_{max} = 14.2 \text{ N/mm}^2$

Resonator an Stützerungen unterstützt:

~~σ_{max} = 11.7 N/mm²~~
 $\sigma_{max} = 11.7 \text{ N/mm}^2$

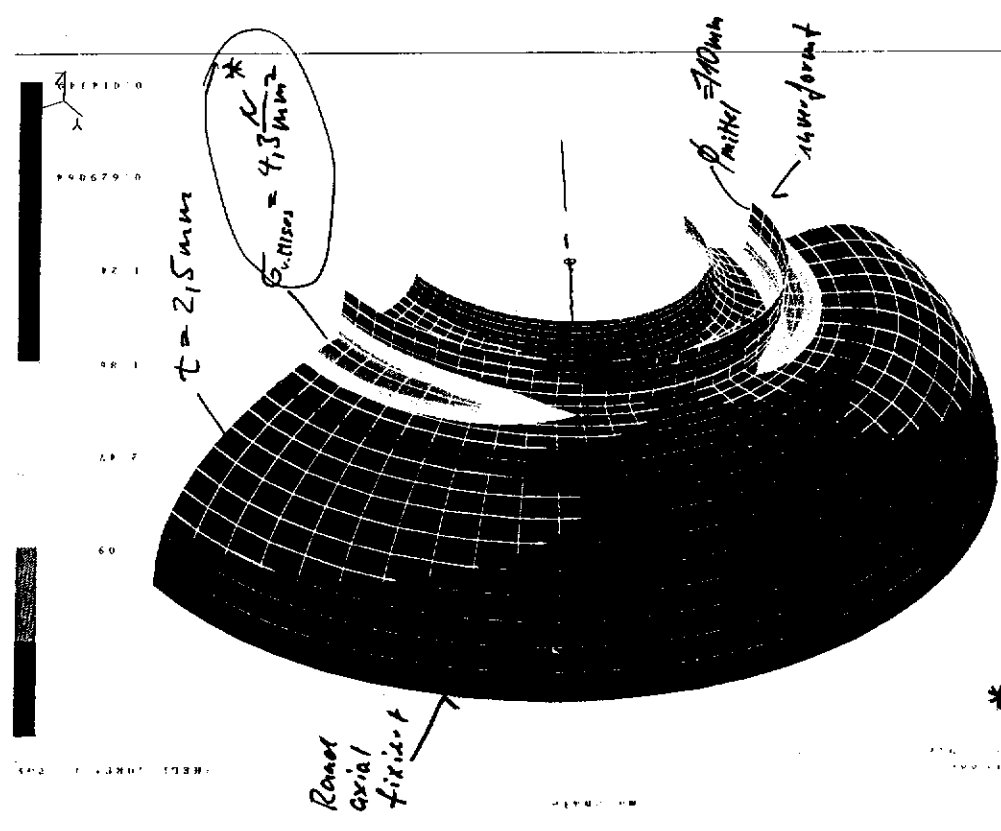
tesla 1996-03

Nach Ofenbehandlung:

$\sigma_{prop} \approx 5 \text{ N/mm}^2$

H.B. Pabel
14.9.94

Mittelha/Selle



* Spannungslinien für Zwangskriechen der bis-Ebene gegenüber dem Äquator. um 90 Grad. Hierfür erforderlich Biegemoment: 9986 Nm (Vollquerschnitt)

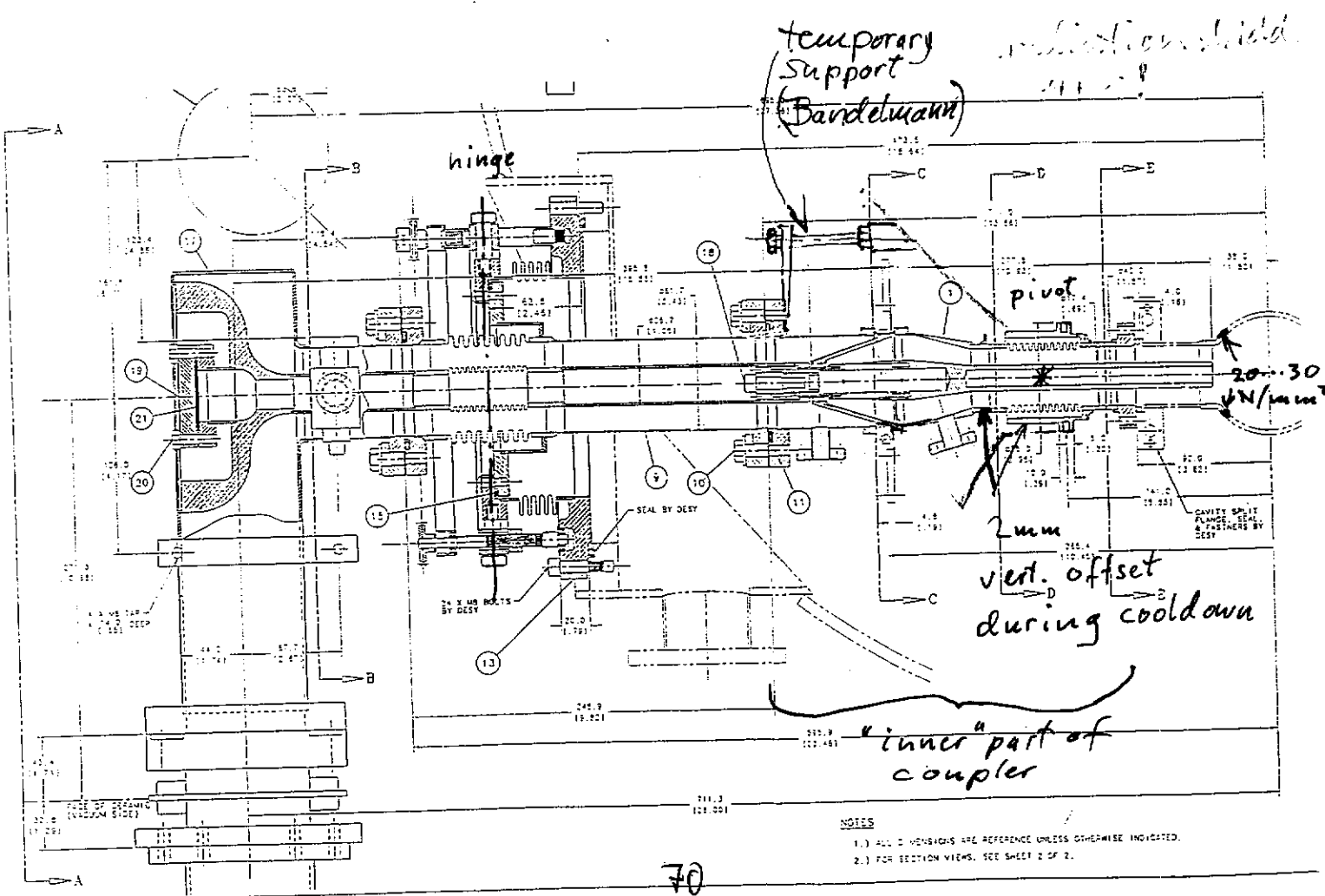
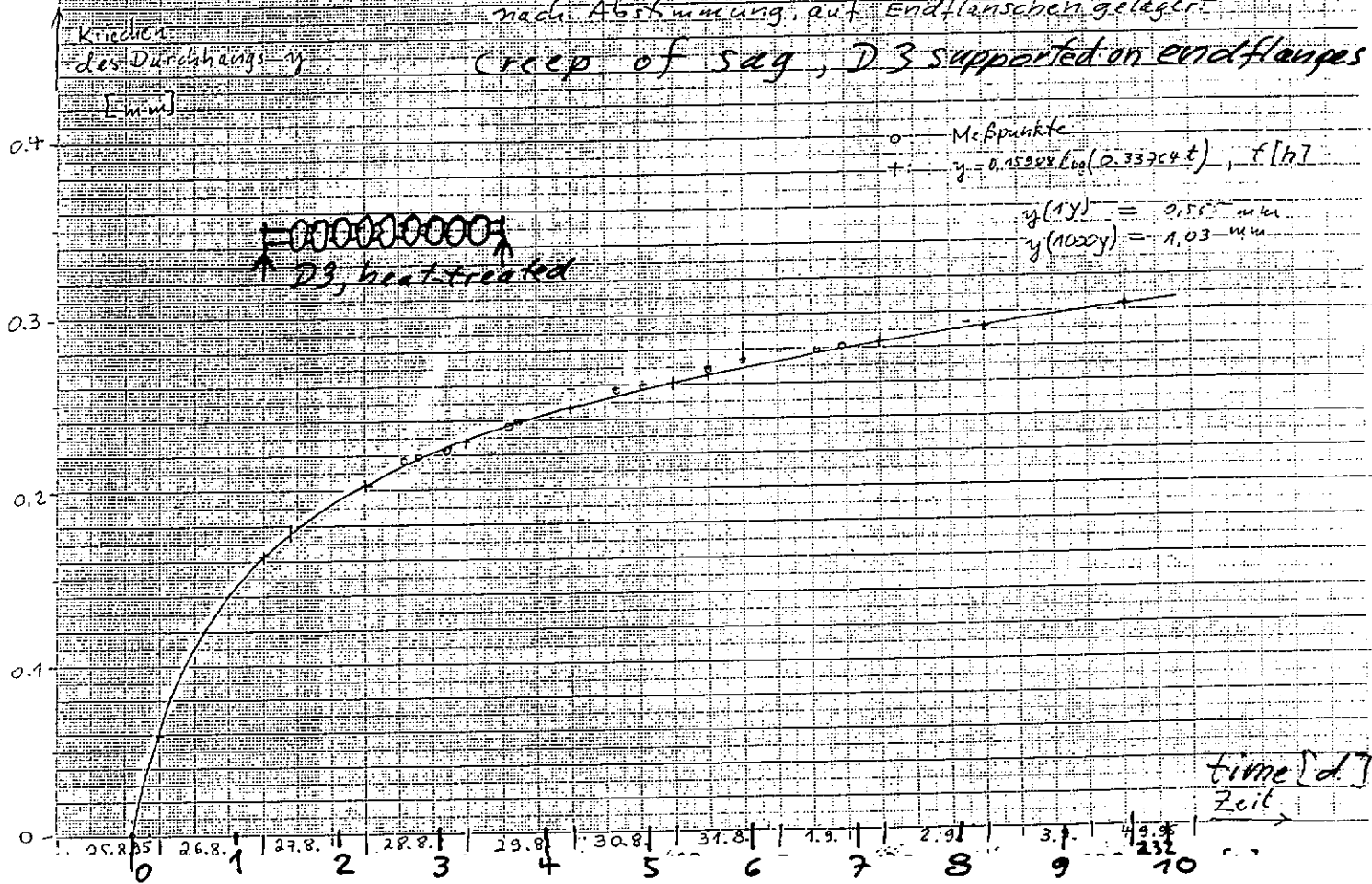
~~σ_{max}~~ σ_{max}

$M_{b,max} = 23072 \text{ Nm} \rightarrow \sigma_{max} = 9.9 \text{ N/mm}^2$

Kriechen des Durchhangs von D-3
nach Abstimmung auf Endflanschen gelagert

tesla:1996-03

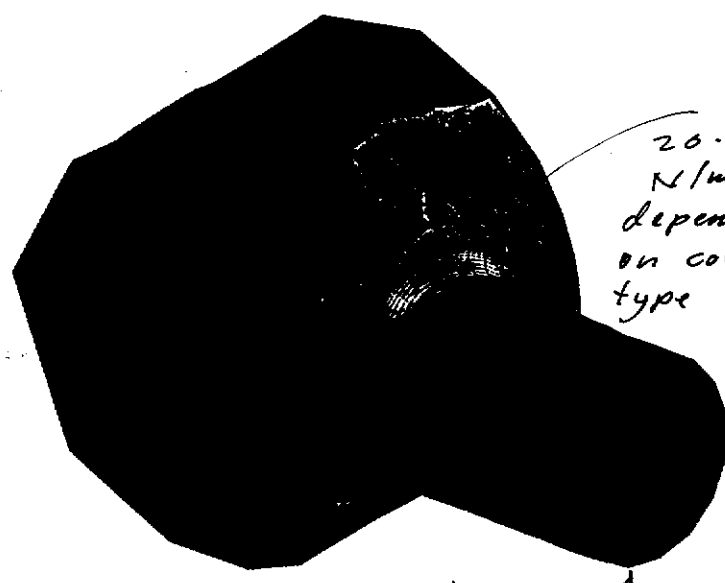
Creep of sag, D3 supported on endflanges



NOTES
 1.) ALL DIMENSIONS ARE REFERENCE UNLESS OTHERWISE INDICATED.
 2.) FOR SECTION VIEWS, SEE SHEET 2 OF 2.

R Bandelmann

ANSYS 5.0
SEP 25 1995
12:28:47
PLOT NO. 1
ELEMENT SOLUTION
tesla 1996-03

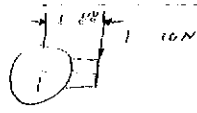


20...30
N/mm²
depending
on coupler
type

↑
brace

SUB =1
TIME=1
SEQV (NOAVG)
TOP
DMX = .001051
SMN = .001811
SMNB = -.386671
SMX = 1.16
SMXB = 1.703
■ .001811
■ .130447
■ .259082
■ .387718
■ .516353
■ .644988
■ .773624
■ .902259
■ 1.031
■ 1.16

Koppert lansch 22.9.95



Understanding of Q degradation

Michael Pekeler

II. Institut für Experimentalphysik der Universität Hamburg

29 Feb 1996

Observation of Q degradation during:

- CWP (continuous wave processing)
- HPP (high power processing)

In principle there is no difference in the processing mechanism between CWP and HPP. Two mechanisms are considered:

- Current I through emitting site heats up the emitter

$$I \sim \exp\left(-\frac{c}{\beta E}\right).$$

Strong heating \Rightarrow Material evaporation

- Electric field causes Pressure P on emitting site

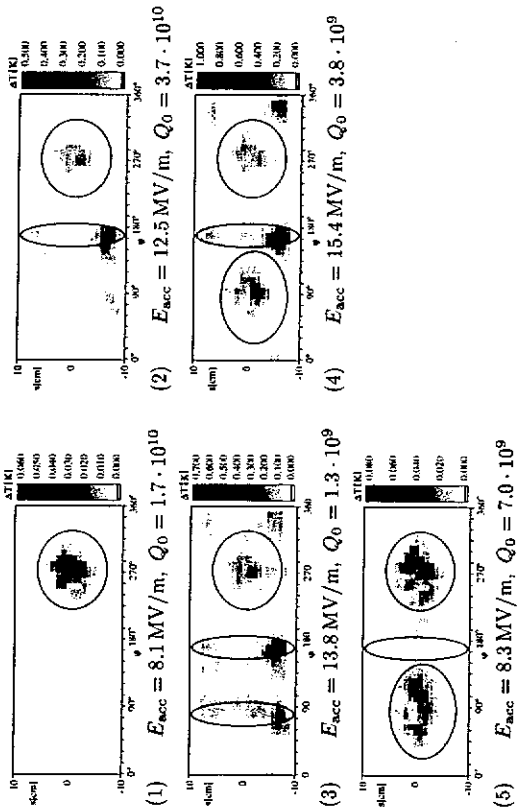
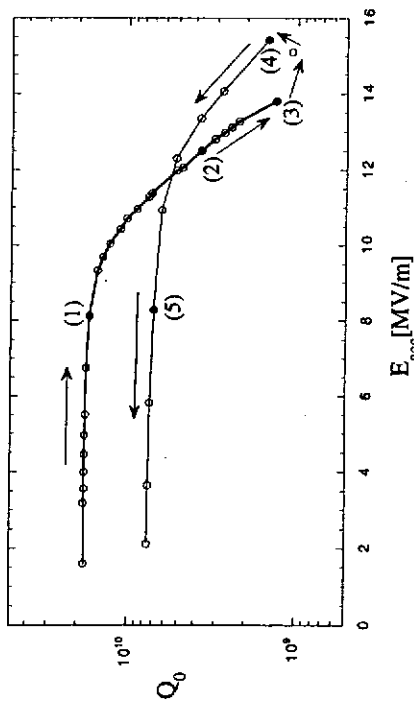
$$P = \frac{1}{2} \epsilon_0 (\beta E)^2$$

$$P = 10^2 \text{ N}/(\text{mm})^2 \quad \text{for } \beta E = 7 \text{ GV/m}$$

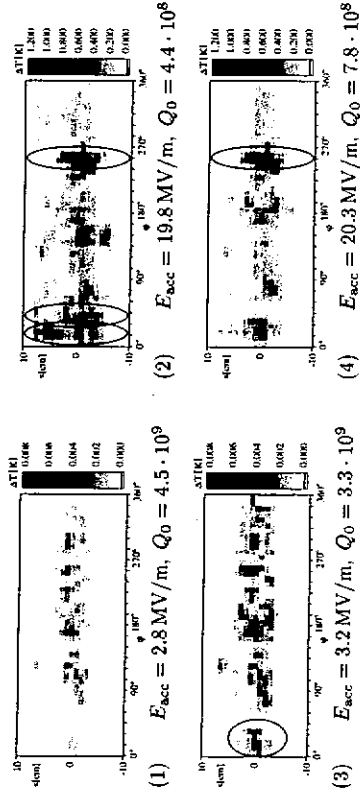
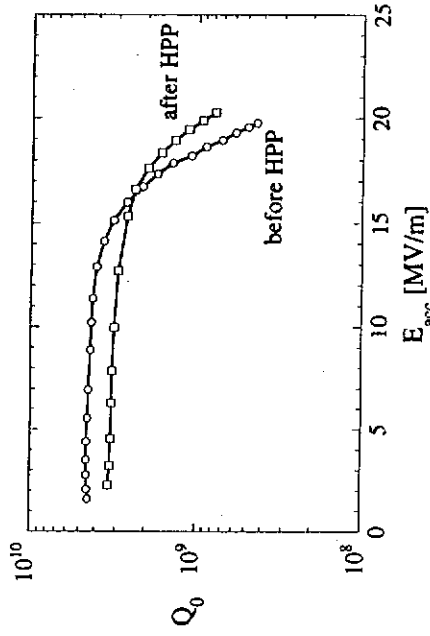
If stress gets too high \Rightarrow Material explosion

42

Example of Q-degradation during CW processing



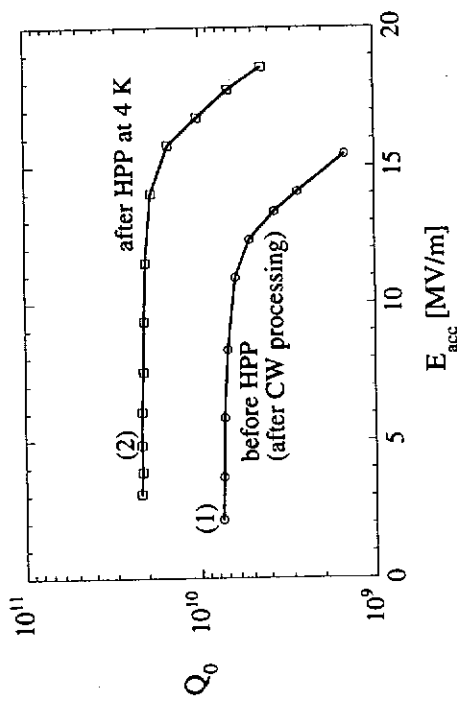
Example of Q-degradation during HPP



Recovering of the $Q \Rightarrow$ thermal cycle

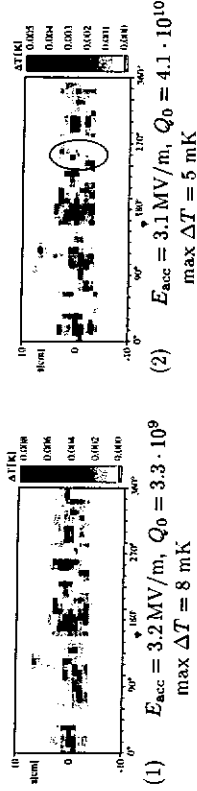
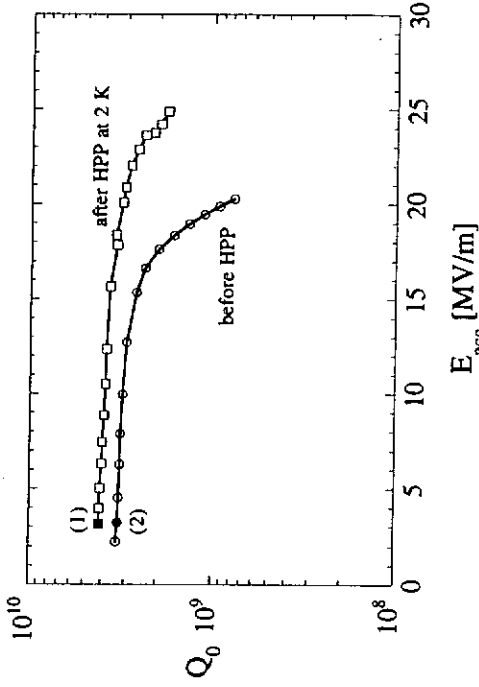
- It is often observed, that thermal cycling to room temperature recovers Q
- sometimes HPP heats up the Cavity strong enough (Cavity in thermal breakdown), that the surface contamination changes, especially, when HPP was performed at 4 K

Example for Q -recovery with HPP at 4K:



Example of Q -recovery with HPP at 2 K

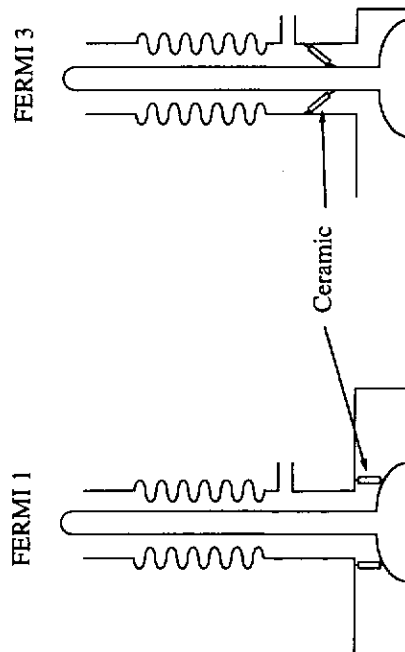
(note: Starting Q very low)



Danger of HPP:

- A lot of power has to go through coupler and especially through the ceramic and may produce outgassing which can influence the Q as well
 - Field emission electrons hitting the ceramic may produce contaminants which can act as new emitters.
- Japanese Q degradation (E. Kako et al.)

⇒ Design of coupler Fermi 1 safer than Fermi 3, electrons do not see the ceramic in the case of Coupler Fermi 1.

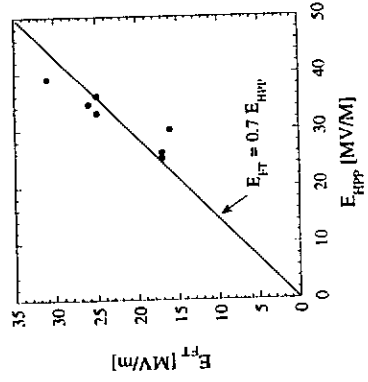
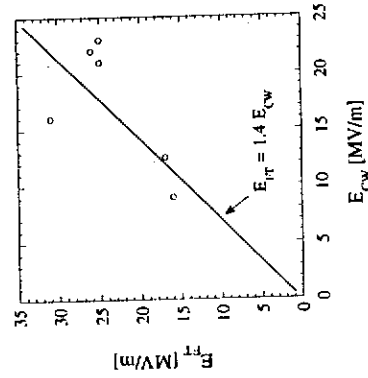


75

Do we need HPP?

What did we learn from the 9-cell tests so far?

- If the cavity is not absolutely clean, only HPP can show the real potential of the cavity
- It is difficult to decide from the CW measurements, how good the flat-top-performance of the cavity is



Field Emission (FE) Issues in TTF Superconducting RF Cavities (Production Series D1,...,D6, C19)

Field Emission (FE), when present, is a serious factor limiting performance of superconducting RF cavity

FE signature:

- dramatic degradation of Q_0 during cavity excitation accompanied by intense X-rays (dose of $> 1\text{Gy/min}$ were measured)
- Can be sometimes (?) cured in situ by High Power Processing (HPP). Example: D2_T2

Table 1 summarizes presently available data of TTF superconducting RF cavities from production series (D1,...,D6 and C19)

Performed tests suggests that FE presently is not a major concern because of careful cavities treatment and intense (triple) High Pressure Water (HPW) rinsing.

However it can be a problem if procedures are not strictly followed. Examples:

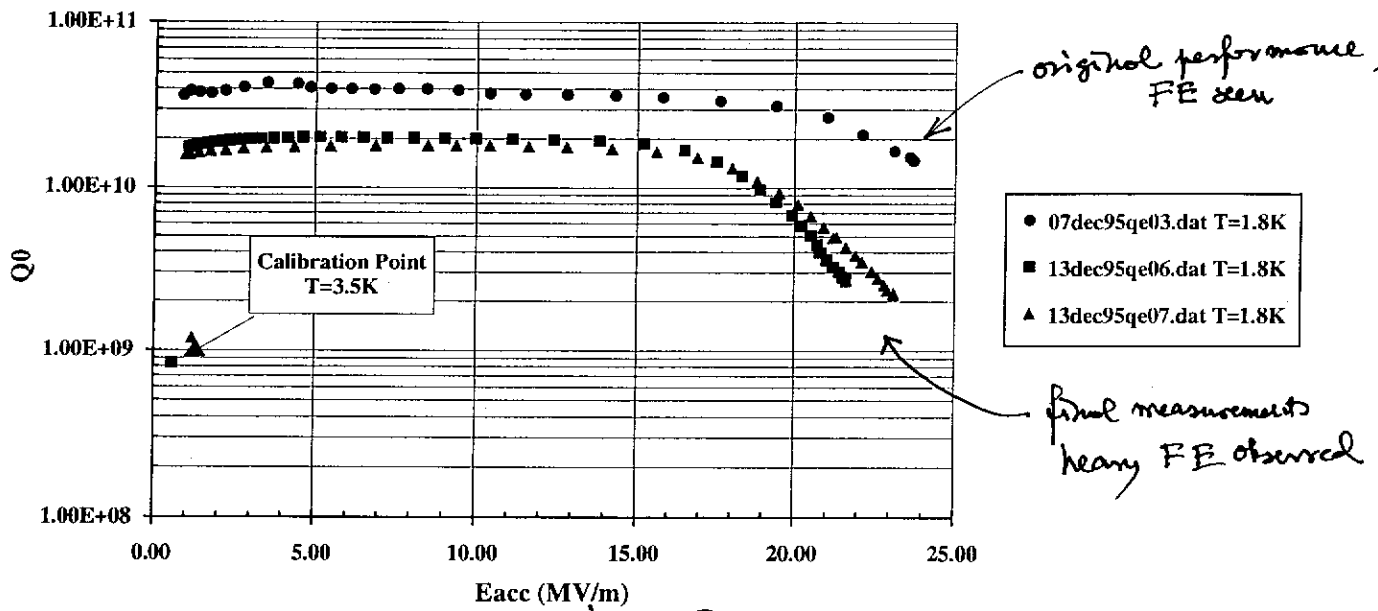
- "dirty" assembly - C19, D3
- "accidents" during testing D1

Jozef Kuzminski
DESY/MHF-SL

Presented at R&D Meeting on 29-Feb-96 at DESY

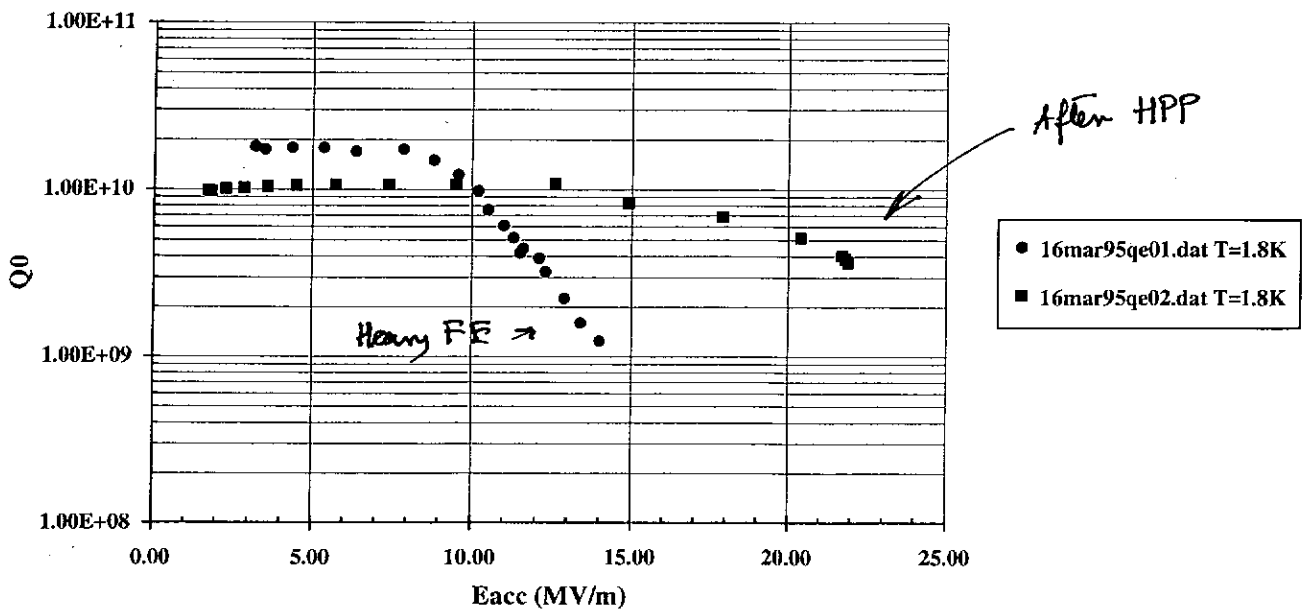
Cavity ID	Total Material Removed (μm)	HPW Rinsing	Initial RRR	Max. Oven Temp. (C)	Oven Time (min)	Final RRR	Low Eacc (MV/m)	Q_0 (10^9) at Low Eacc	Max. Eacc (MV/m)	Q_0 (10^9) at Max. Eacc	Max. Eacc Limited by	HPP (MV/m)	File	Comment
D1	155	3	281	1400	240	535	0.86	34.40	23.70	14.70	TB		07dec95qe03	No FE seen. Very flat excitation function.
D1							1.04	17.60	21.60	2.65	AP		13dec96qe06	Heavy FE observed for Eacc > 15 MV/m as a result of FNAL coupler processing
D2	135	1	289	1400	240	348	3.18	18.10	14.00	1.24	TB		16mar95qe01	Heavy FE observed for Eacc > 7 MV/m
D2							1.72	9.91	21.90	3.68	TB 35(HPP)		16mar95qe02	FE cured by HPP
D3	100	3	288	1400	60	520	1.53	25.20	11.50	2.20	TB		23jan96qe01	High FE. Cavity assembling problems.
D4	300	3	265	1400	240	525	0.90	28.90	13.50	15.60	TB		09feb96qe01	No FE seen (Q switch)
D5	130	3	265	1400	60	465	0.70	30.30	8.00	3.70	TB		27feb96qe01	No FE seen (Q switch)
				1250	180									
D6	200	1	265	1400	240	534	1.40	25.80	12.90	11.00	TB		24oct95qe15	FE seen in mode 8/9 π Q switch. Hot spot seen in cell #5 (T-map, grinding.)
C19	150	1	250	1300	960	590	1.14	38.40	13.30	1.70	TB		02jun95qe01	Heave FE.
C19		1					1.07	19.20	21.60	1.75	TB 22(HPP)		12jun95qe08	FE Cured by HPP
C19		1					1.29	28.60	7.88	0.69	AP		07sep95qe01	Heavy FE ("dirty assembly")
C19		1					1.15	27.90	17.90	9.19	TB		06 oct95qe01	FE for Eacc > 15 MV/m

Cavity D1 Test 01



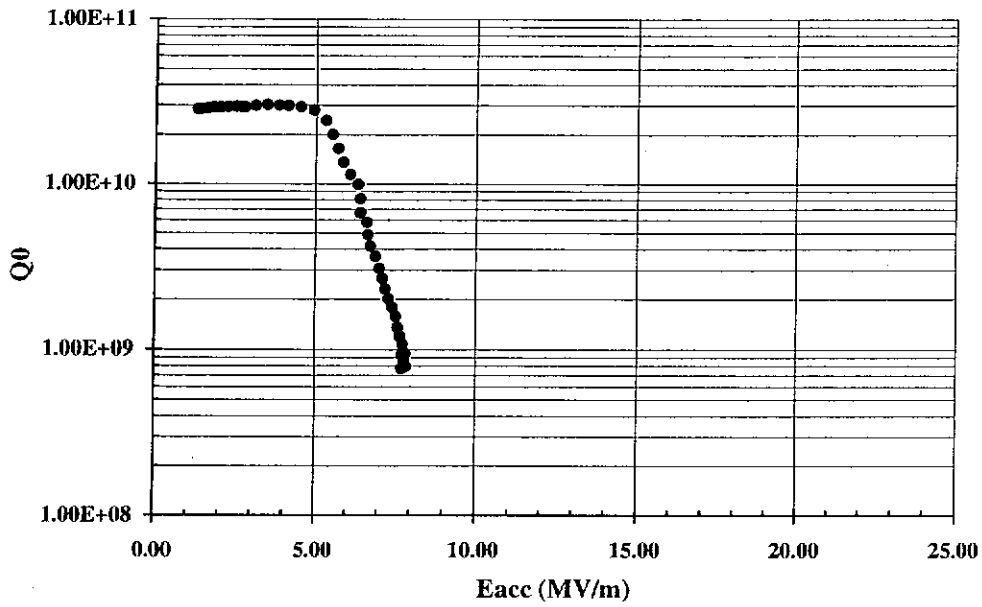
Performance degradation after/during High Power Coupler processing

Cavity D2 Test 02



Example of 'in-situ' recovery by High Power Processing (HPP)

Cavity C19 Test 03

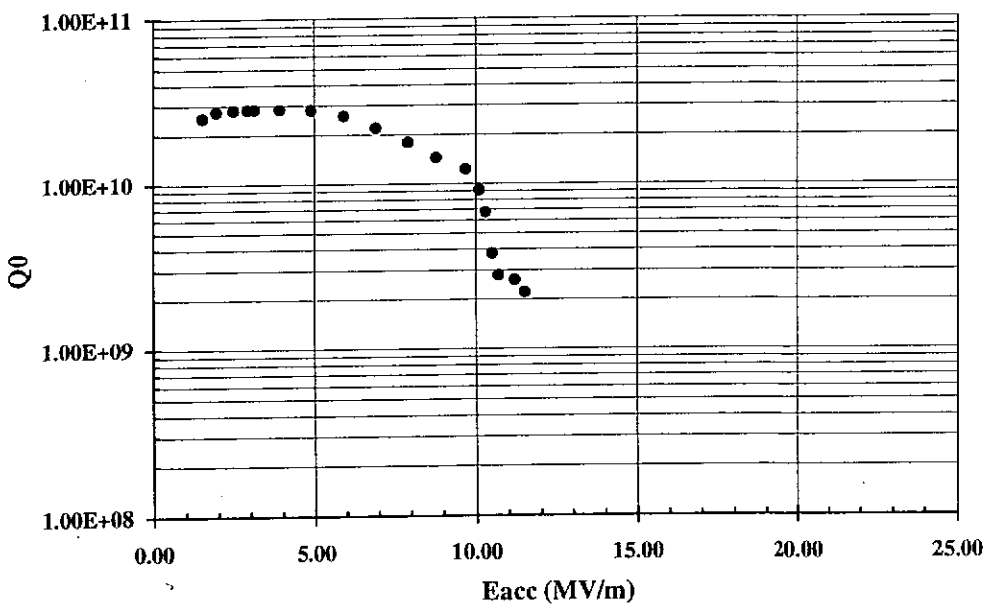


Heavy FE observed

• 07sep95qe01.dat T=1.8K

"Dirty" assembly of C19 in CHECHA (No local Clean Room)

Cavity D3 Test 01



Heavy FE seen

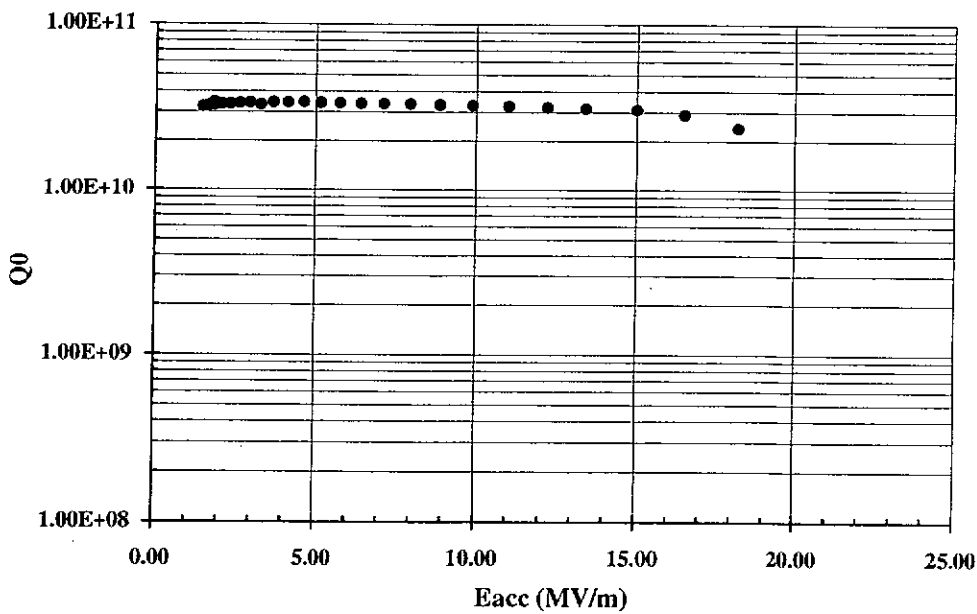
• 23jan96qe01.dat T=1.8K

"Dirty" assembly (leak on HOM coupler flange?)

File: C19_T5_16nov95qe01.plt

Date: 25/2/96 21:52

Cavity C19 Test 05 (CHECHIA)



• 16nov95qe01.dat T=1.7K

FE cured by High Pressure Water (HPW) rinsing

Sample preparation (PK4):

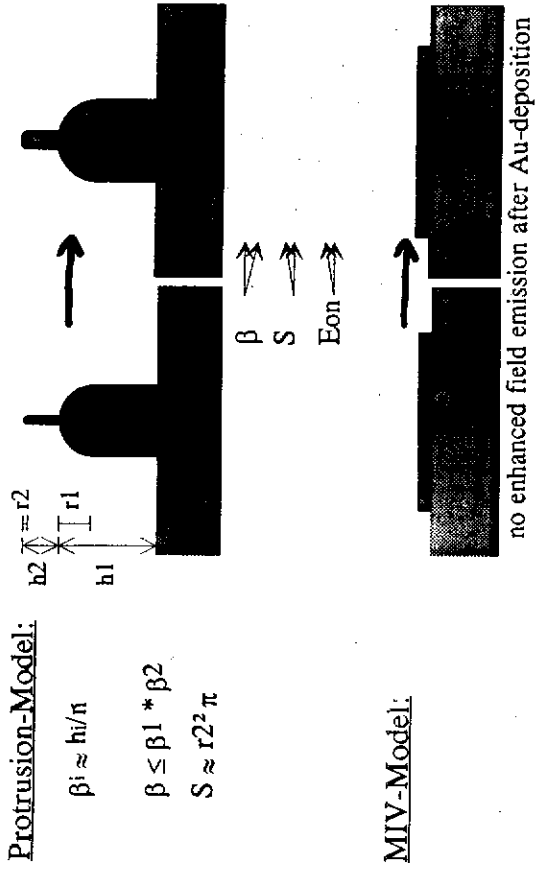
- $\approx 10 \mu\text{m}$ BCP (1:1:1)
- rinsing in a container with deionized, filtered water
- rinsing with a water jet (deionized, filtered water)
- drying in chemistry room (without air-filtration)
- heat treatment at 400°C , 15 min
- FE-scans, emitter-analysis (FN, SEM, AES, EDX)
- 16 nm Au - vapor-deposition
- emitter-analysis (FN, SEM, AES, EDX)

DC Field Emission
from naturally rough
particles

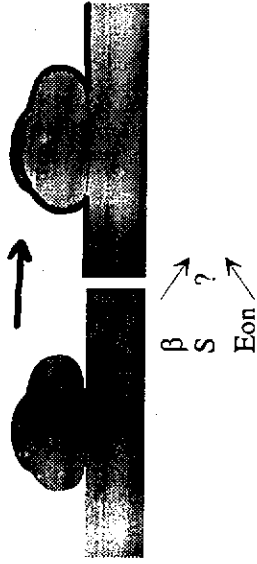
T. Habermann

Univ. Wuppertal

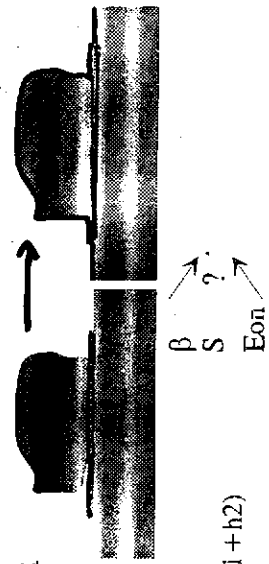
What changes by the Au-deposition?



MIV + geometric field enhancement:

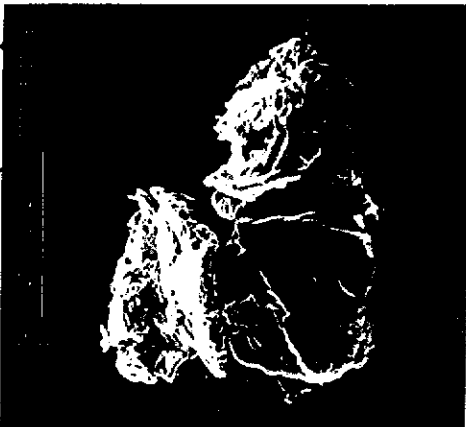


MIM
Antenna-Model (MIM):

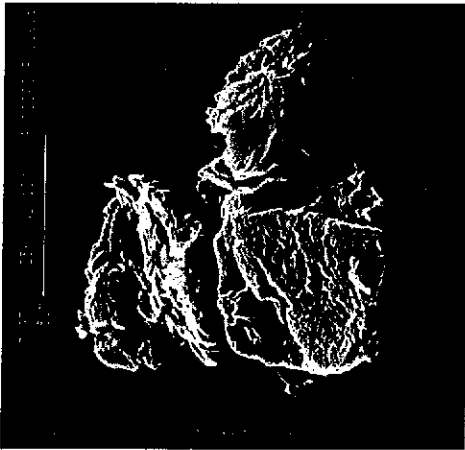


bef. Au-depos: $\beta_{FN} \sim (h_1 + h_2)$

change of electrical surface properties e.g. of secondary electron emission by Au-deposition



before Au deposition

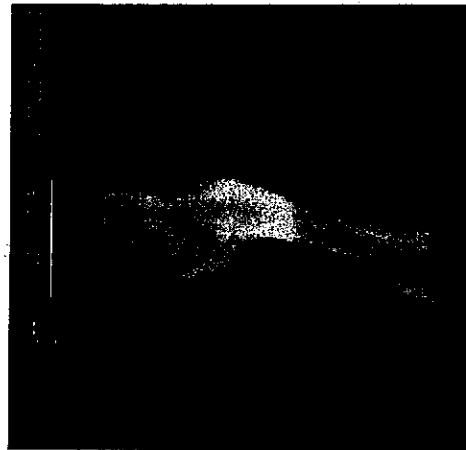


after Au deposition

Proof of uniform deposition thickness

thickness, calculated for $\Delta Au = 16 \text{ nm}$:

//

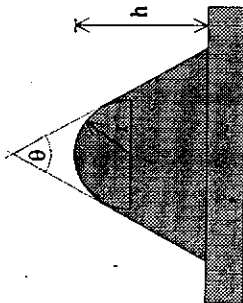


Estimation of β_{geo} from SEM-micrographs according to the "protrusion on protrusion model":

After Au-deposition:
geometrical field enhancement

single protrusion:

$$\beta = h/r + 3 \cos \theta$$

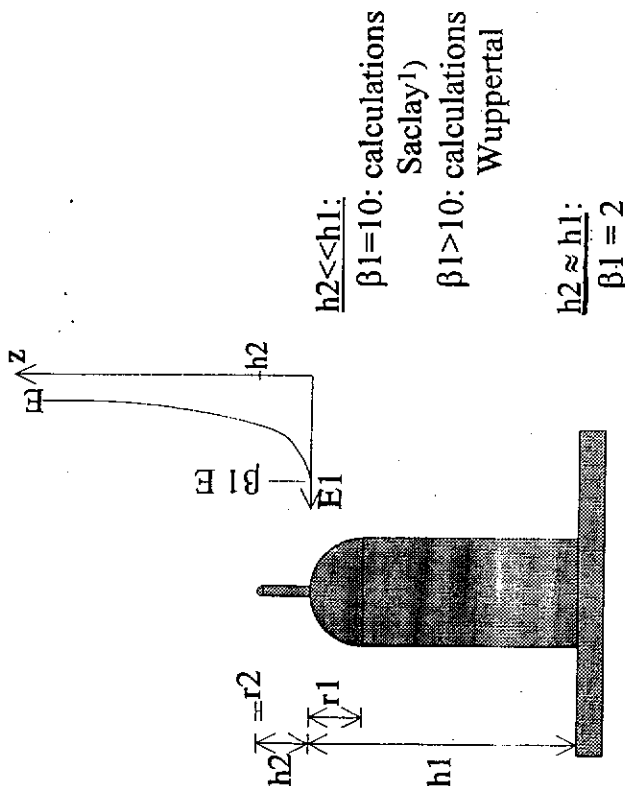


Comparison of β_{FN} and β_{geo} after Au-deposition leads to:
 $\Phi_{\text{Au}} \approx 4.05 \text{ eV}$

in Literature: $\Phi_{\text{Au}} = 4.3 - 4.9 \text{ eV}$

Φ - Variation by adsorbates and geometry

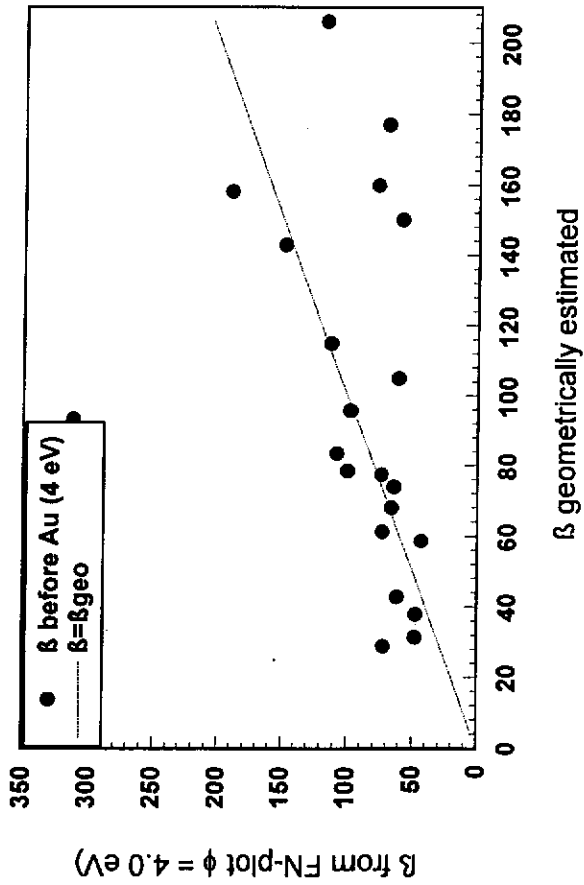
protrusion on protrusion:



$$\Rightarrow \beta_{\text{geo}} = \beta_2 \left\{ 2 + (\beta_1 - 2) \cdot \exp \left[- \left(\beta_1 \cdot \frac{h_2}{h_1} \right)^{1.2367 - 0.0285 \cdot \beta_1} \right] \right\}$$

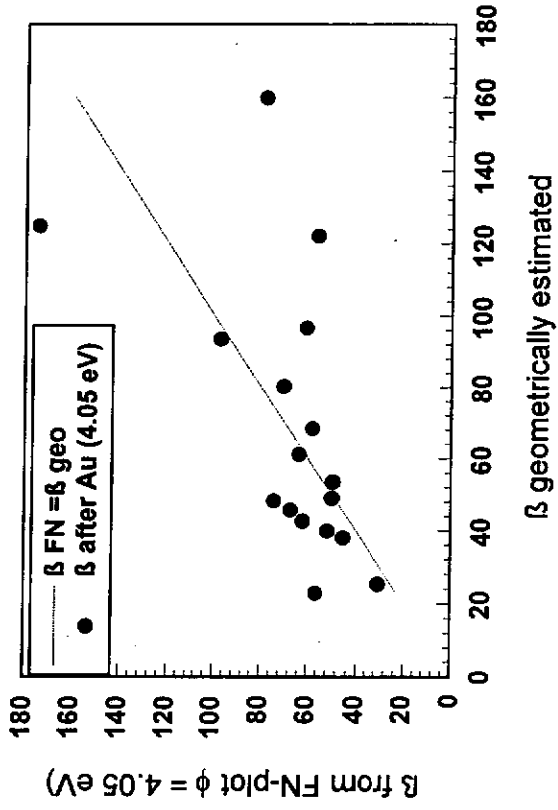
1) M. Jimenez et al., J.Phys.D.: Appl.Phys. 27, 1038 (1994)

Comparison of β_{FN} , $\phi=4.0\text{eV}$ and β_{geo} before Au-deposition

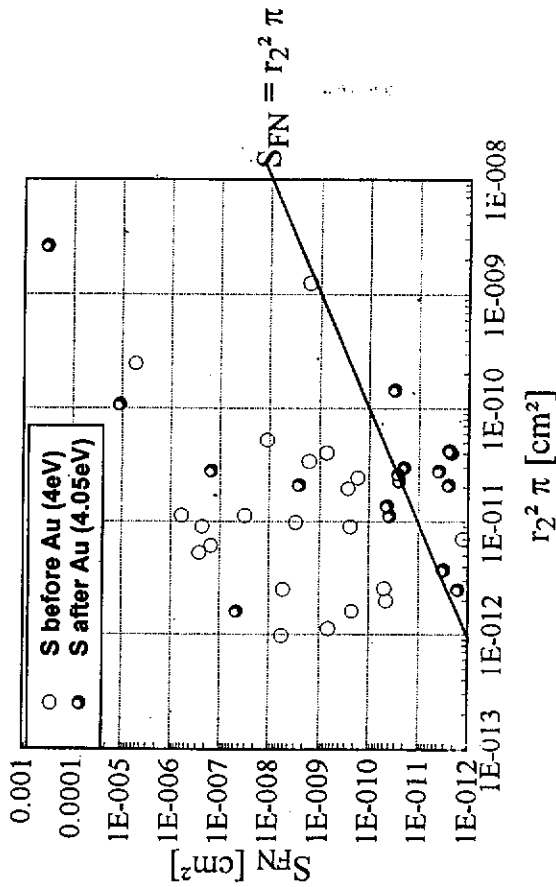


if geometric field enhancement: $\beta_{FN} \approx \beta_{geo}$

Comparison of β_{FN} , $\phi=4.05\text{eV}$ and β_{geo} after Au-deposition



Comparison of the emitting areas from Fowler-Nordheim-analysis and from the geometry



58

Emitters with β_{FN} in good agreement with estimated geometrical β_{geo} :

before Au deposition:

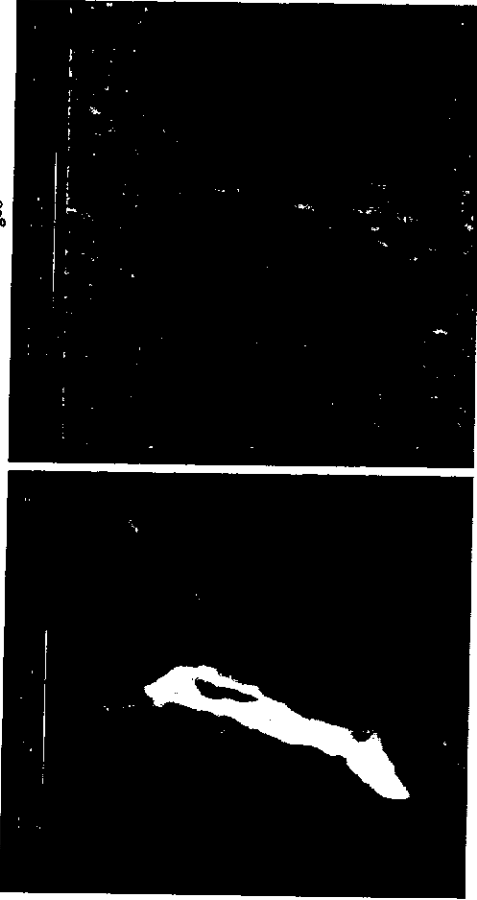
$$\beta_{FN} = 112 = \beta_{geo} = 115$$

$$= 5 \cdot 10^{-11} \text{ cm}^2 \sim S_{geo} = 3 \cdot 10^{-12} \text{ cm}^2$$

after Au deposition

$$\beta_{FN} = 51 \sim \beta_{geo} = 40$$

$$S_{FN} = 3 \cdot 10^{-9} \text{ cm}^2 \neq S_{geo} = 2 \cdot 10^{-11} \text{ cm}^2$$



before Au:

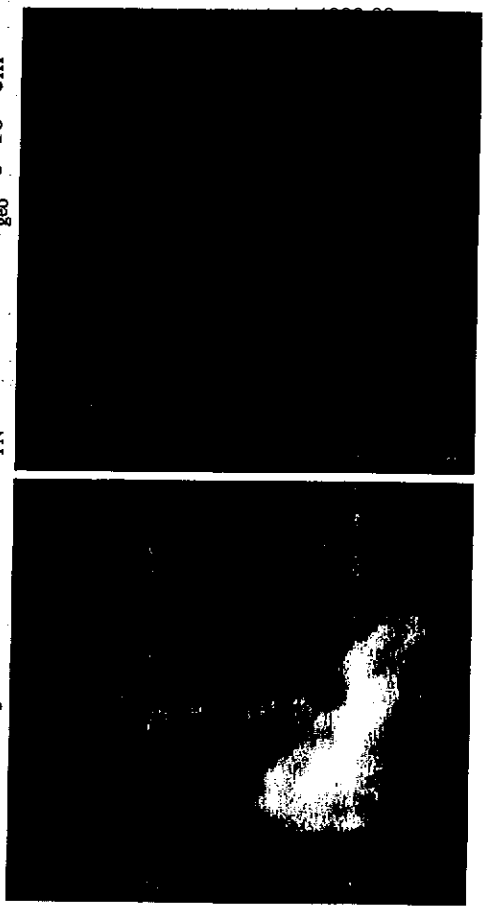
$$\beta_{FN} = 64 \sim \beta_{geo} = 74$$

$$S_{FN} = 6 \cdot 10^{-9} \text{ cm}^2 \neq S_{geo} = 1 \cdot 10^{-12} \text{ cm}^2$$

after Au:

$$\beta_{FN} = 49 = \beta_{geo} = 49$$

$$S_{FN} = 3 \cdot 10^{-11} \text{ cm}^2 \sim S_{geo} = 3 \cdot 10^{-12} \text{ cm}^2$$

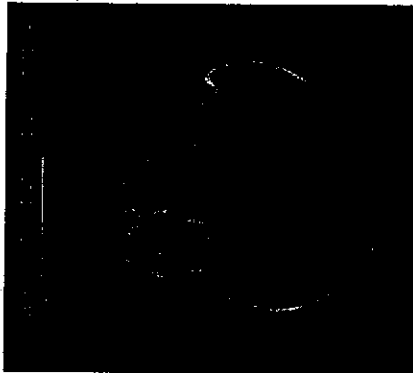


Emitters with β_{FN} strongly different from estimated geometrical β_{geo} :

before Au deposition:

$$\beta_{FN} = 100 \neq \beta_{geo} = 79$$

$$r = 3 \cdot 10^{-10} \text{ cm}^2 \sim S_{geo} = 3 \cdot 10^{-11} \text{ cm}^2$$



after Au deposition

$$\beta_{FN} = 74 \neq \beta_{geo} = 48$$

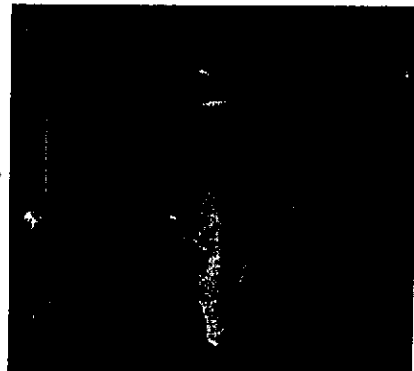
$$S_{FN} = 2 \cdot 10^{-12} \text{ cm}^2 \sim S_{geo} = 4 \cdot 10^{-11} \text{ cm}^2$$



before Au:

$$\beta_{FN} = 61 \neq \beta_{geo} = 105$$

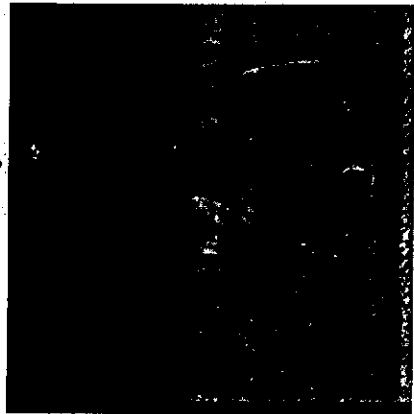
$$S_{FN} = 3 \cdot 10^{-9} \text{ cm}^2 \neq S_{geo} = 1 \cdot 10^{-11} \text{ cm}^2$$



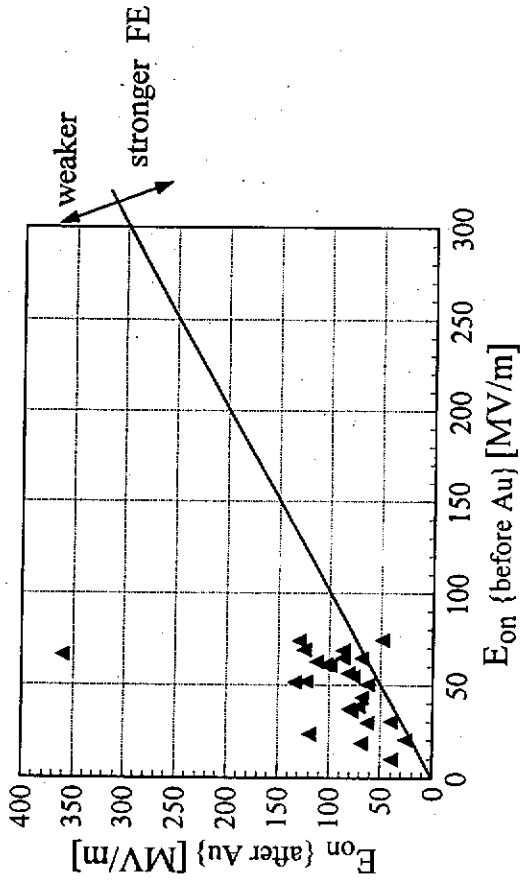
after Au:

$$\beta_{FN} = 58 \neq \beta_{geo} = 68$$

$$S_{FN} = 3 \cdot 10^{-11} \text{ cm}^2 \sim S_{geo} = 1 \cdot 10^{-11} \text{ cm}^2$$

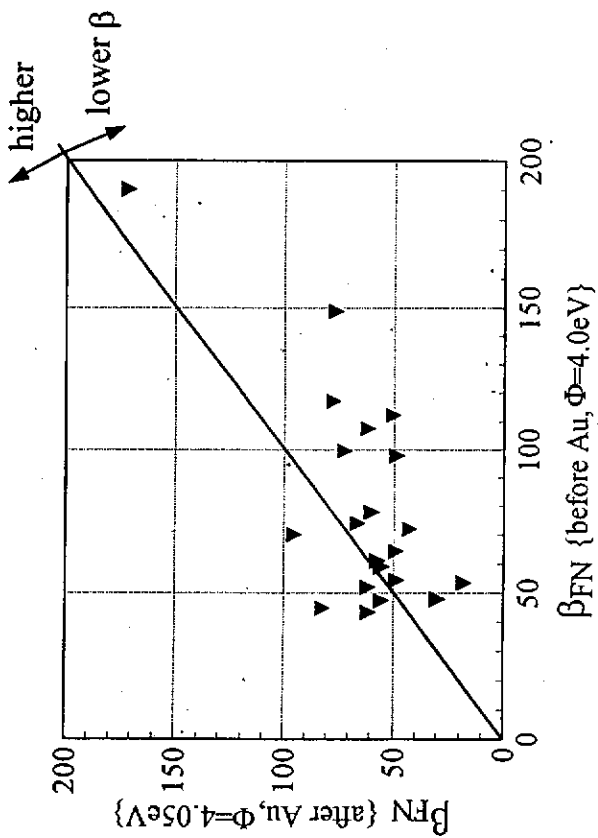


Change of E_{on} by Au-deposition:

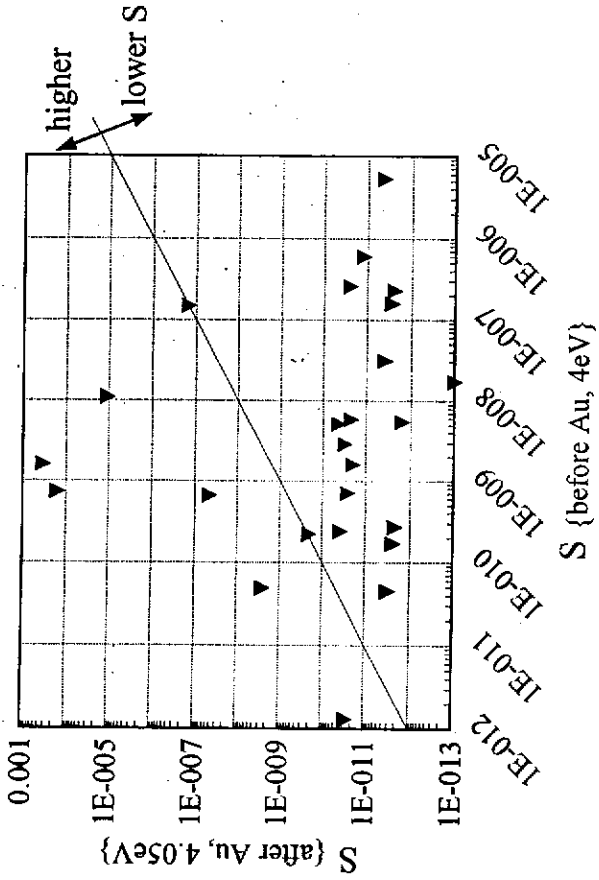


A slight increase of E_{on} by Au-deposition

Change of β_{FN} by Au-deposition:



Change of S_{FN} by Au-deposition:

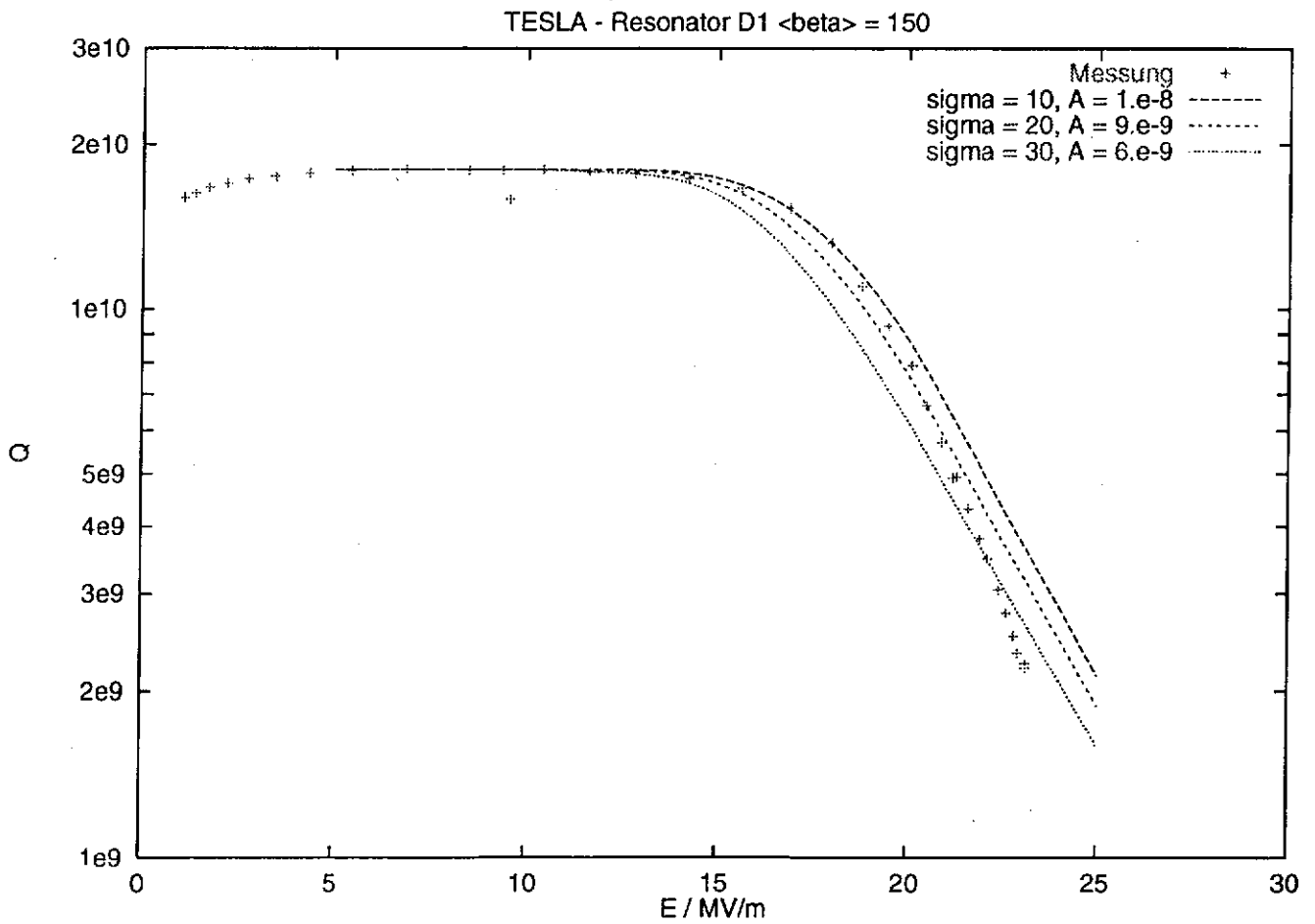
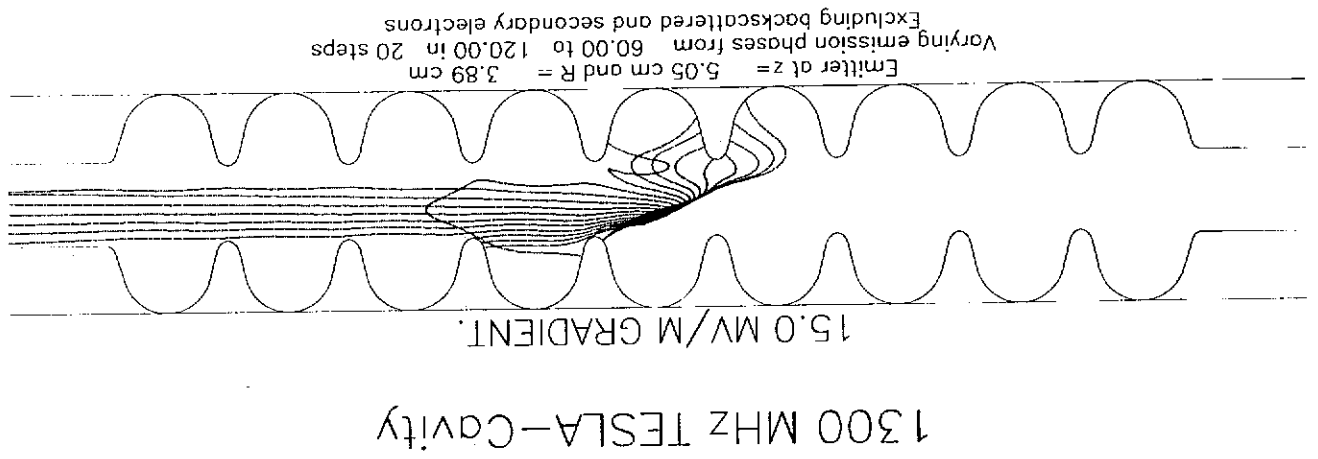


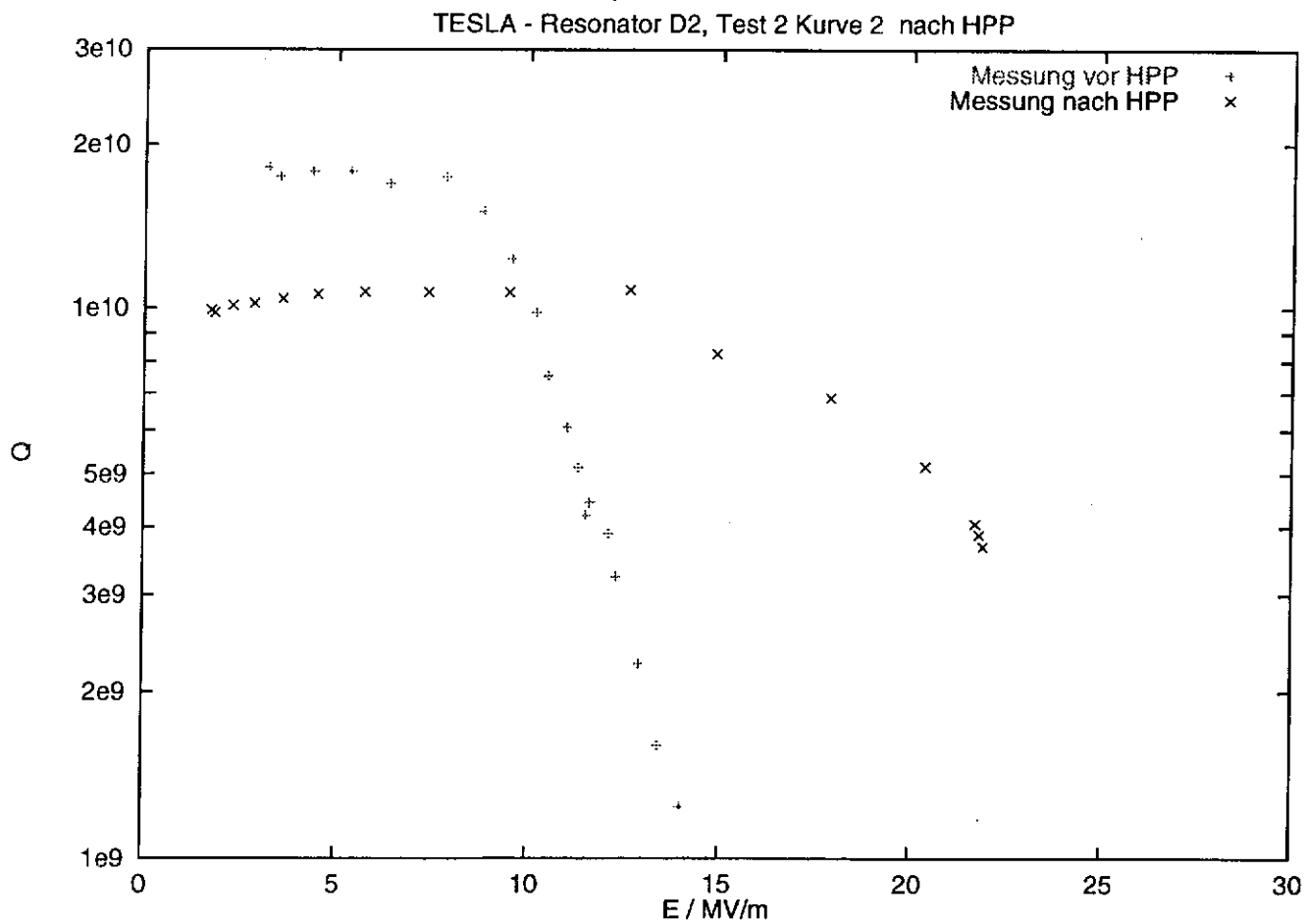
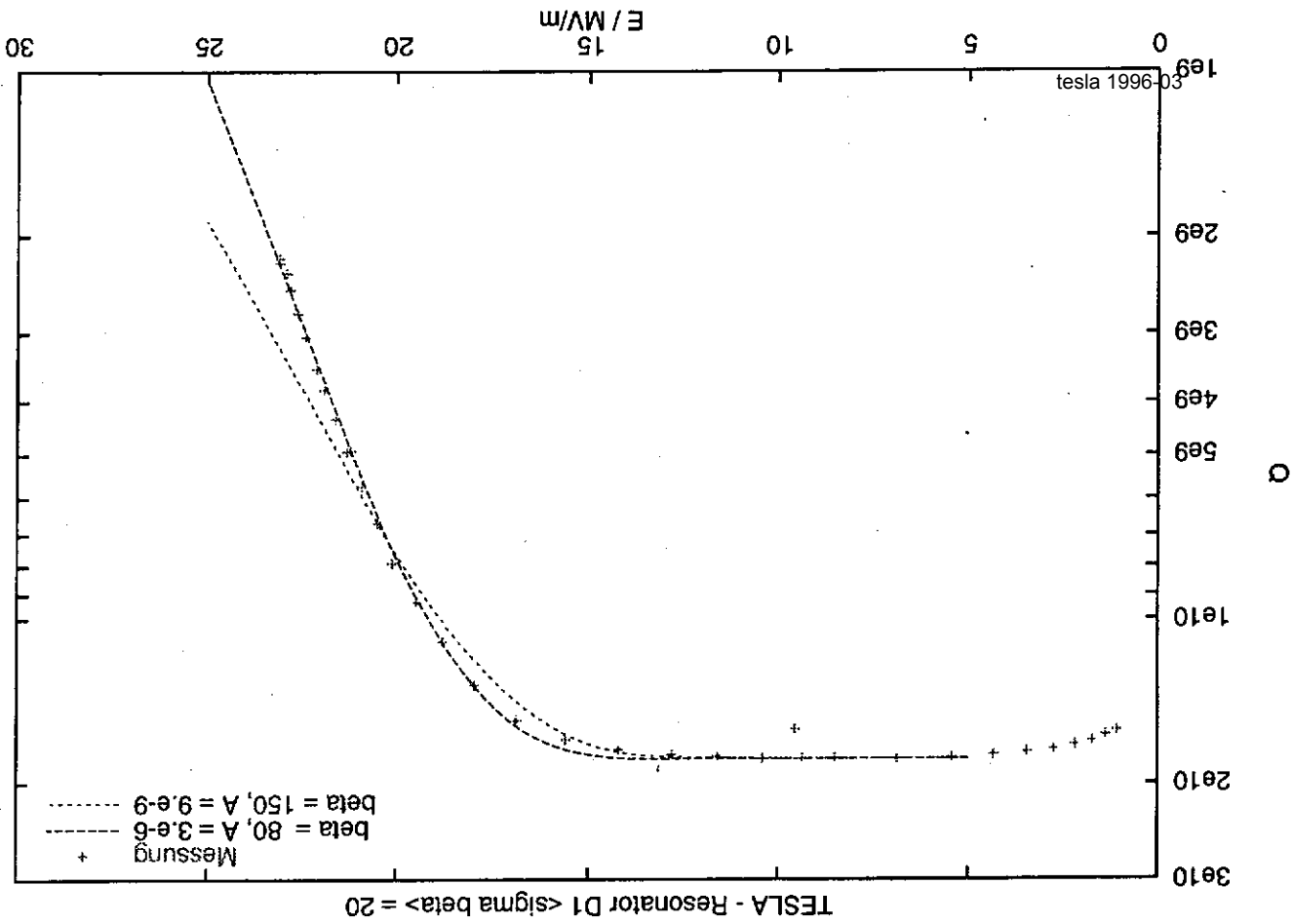
Summary:

- very good agreement between β_{geo} and β_{FN} before gold-deposition
 - *geometric field enhancement sufficient for the observed FE*
- smaller spread of S_{FN} -values after Au-deposition, S_{FN} tend to more realistic values
 - *spread of S_{FN} probably due to adsorbates*
- assuming protrusion-model after Au-deposition the work function is changed
 - *influence of adsorbates and geometry*
- E_{on} rises by Au-deposition
- the average β_{FN} decreases ($\Phi = 4.05\text{eV}$)
- the average S_{FN} also decreases ($\Phi = 4.05\text{eV}$)
- → no pure MIV -model
 - MIM-model possible
 - geometric field enhancement can play a main role as emission mechanism

Outlook:

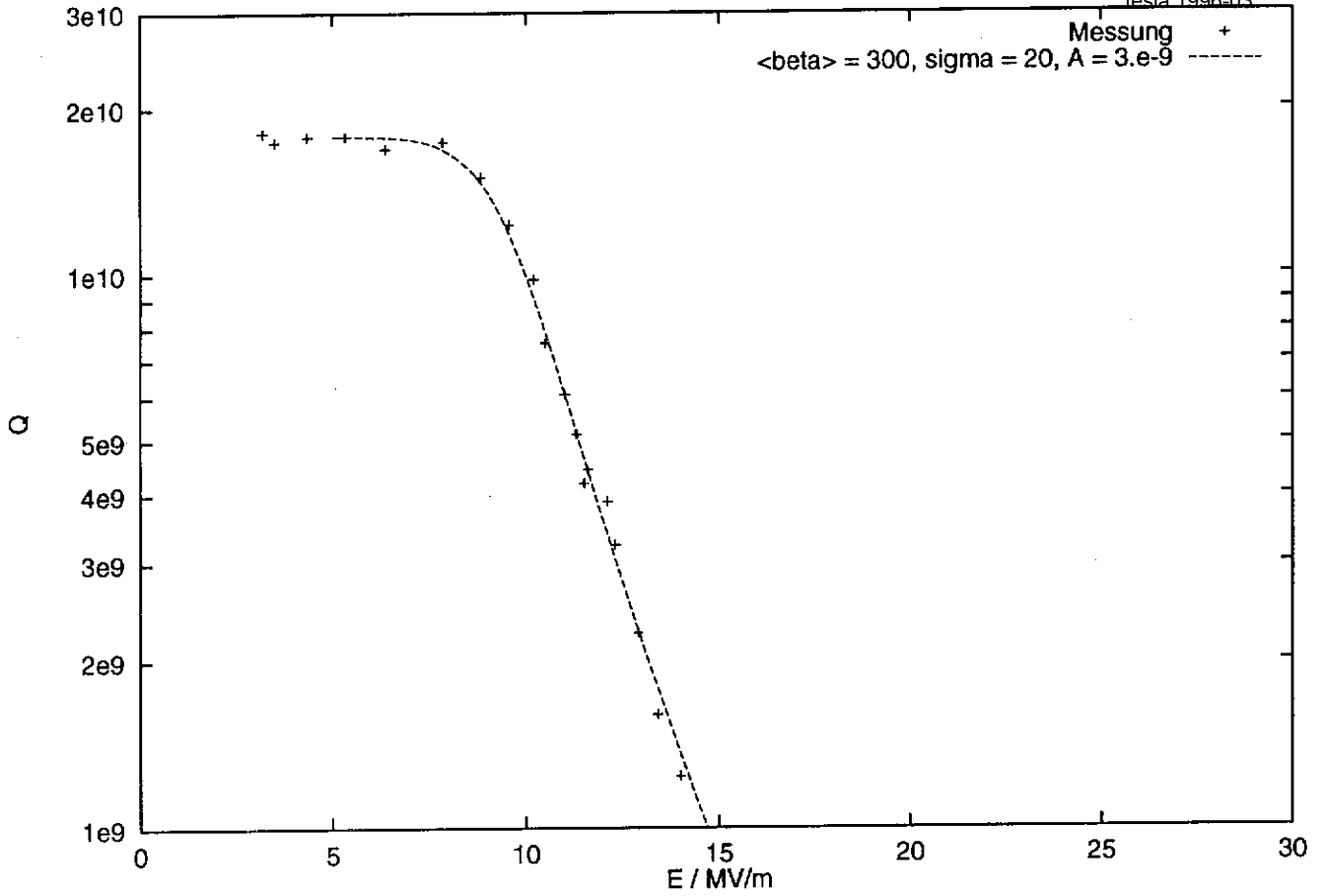
- Preparation of Nb-samples in cavities at TTF
- Influence of current processing on EFE
- Influence of Ion-bombardement on EFE
-
-





TESLA - Resonator D2, Test 2 Kurve 1

tesla 1996-03



TESLA - Resonator D2, Test 2 Kurve 2 nach HPP

